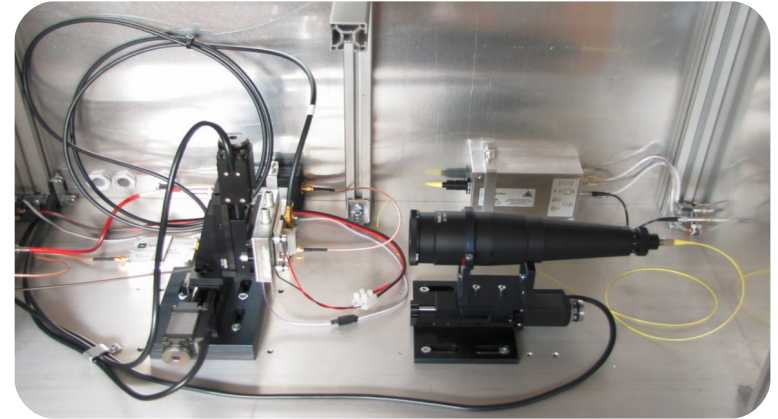


Confronting irradiation damage

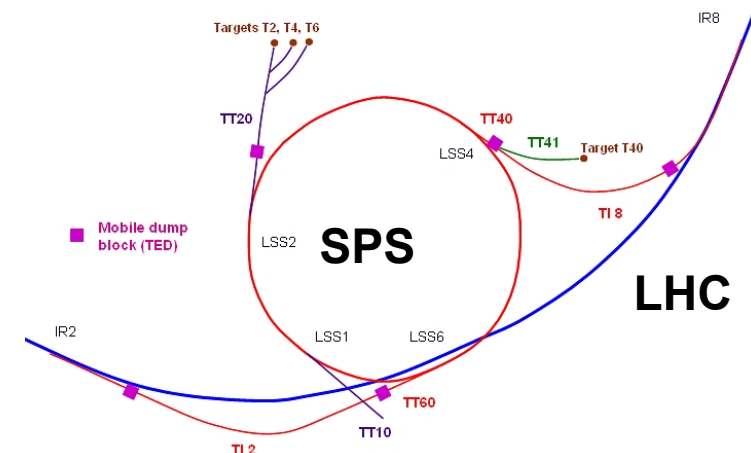
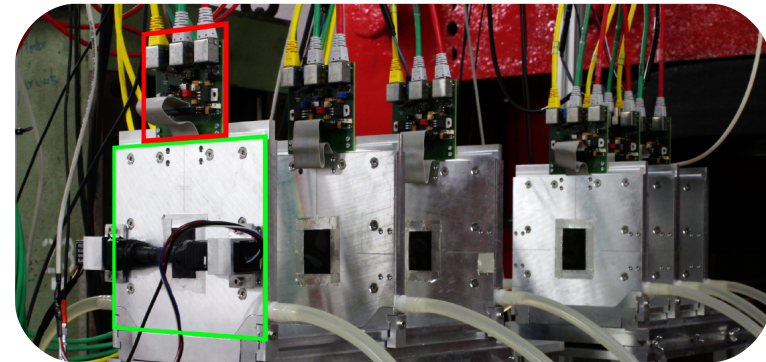
From understanding to actions

Outline

- HEP detector overview
 - what we have
 - why we need to do better
- Radiation damage in semiconductor sensors
- Characterisation techniques
- Clever ideas mitigating radiation damage



<http://particulars.si/>



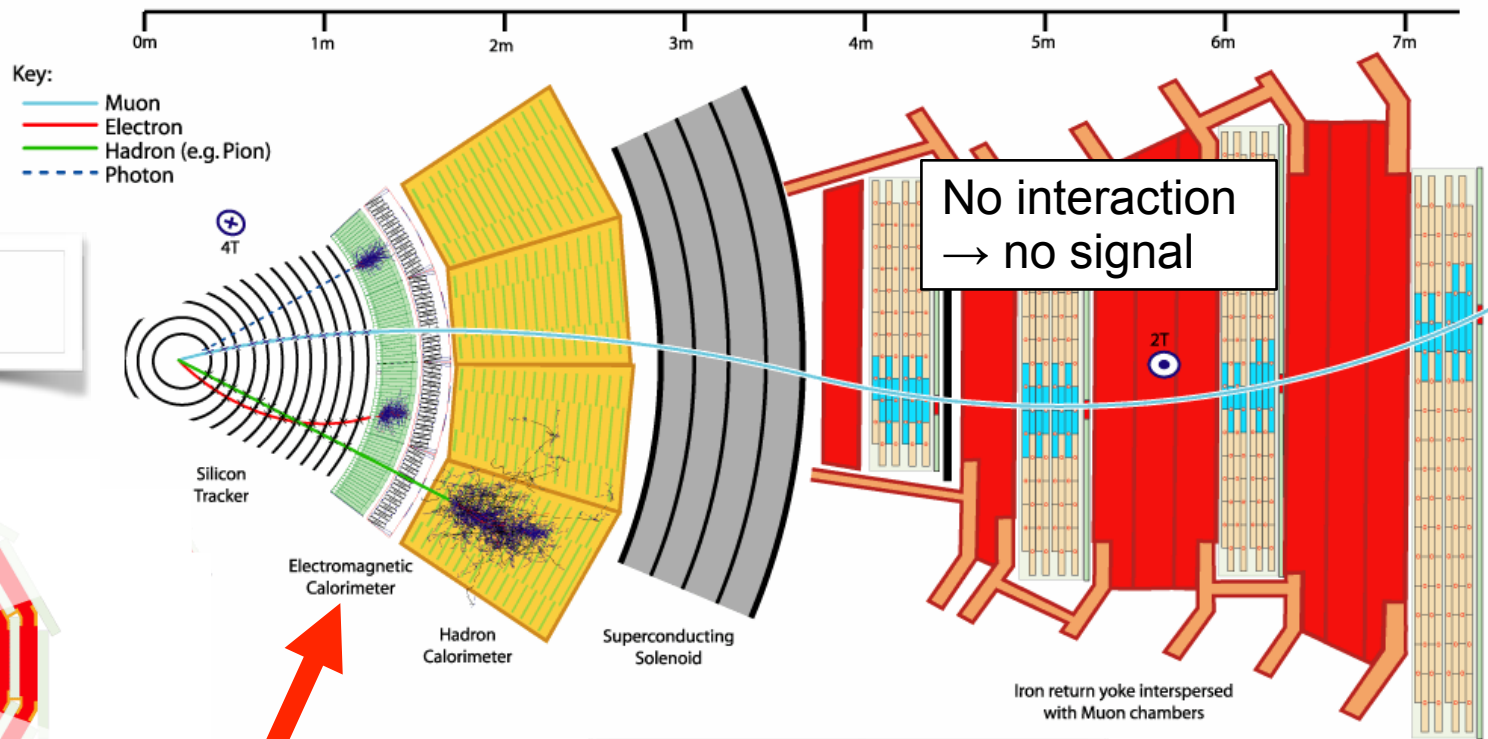
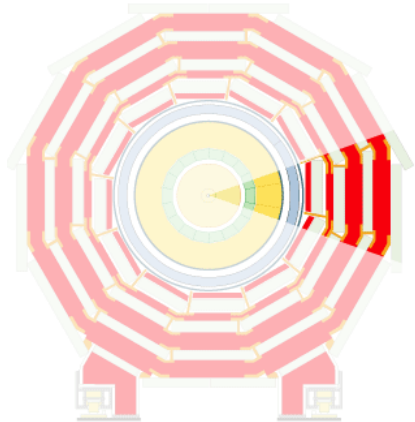
HEP detector: CMS overview

Tracker: Precise measurement of track and momentum of charged particles due to magnetic field.

Calorimeter: Energy measurement of photons, electrons and hadrons through total absorption

Muon-Detectors: Identification and precise momentum measurement of muons outside of the magnet

Vertex: Innermost tracking detector



Good energy resolution up to highest energies

Radiation hard (hadron collider)

picture: CMS@CERN

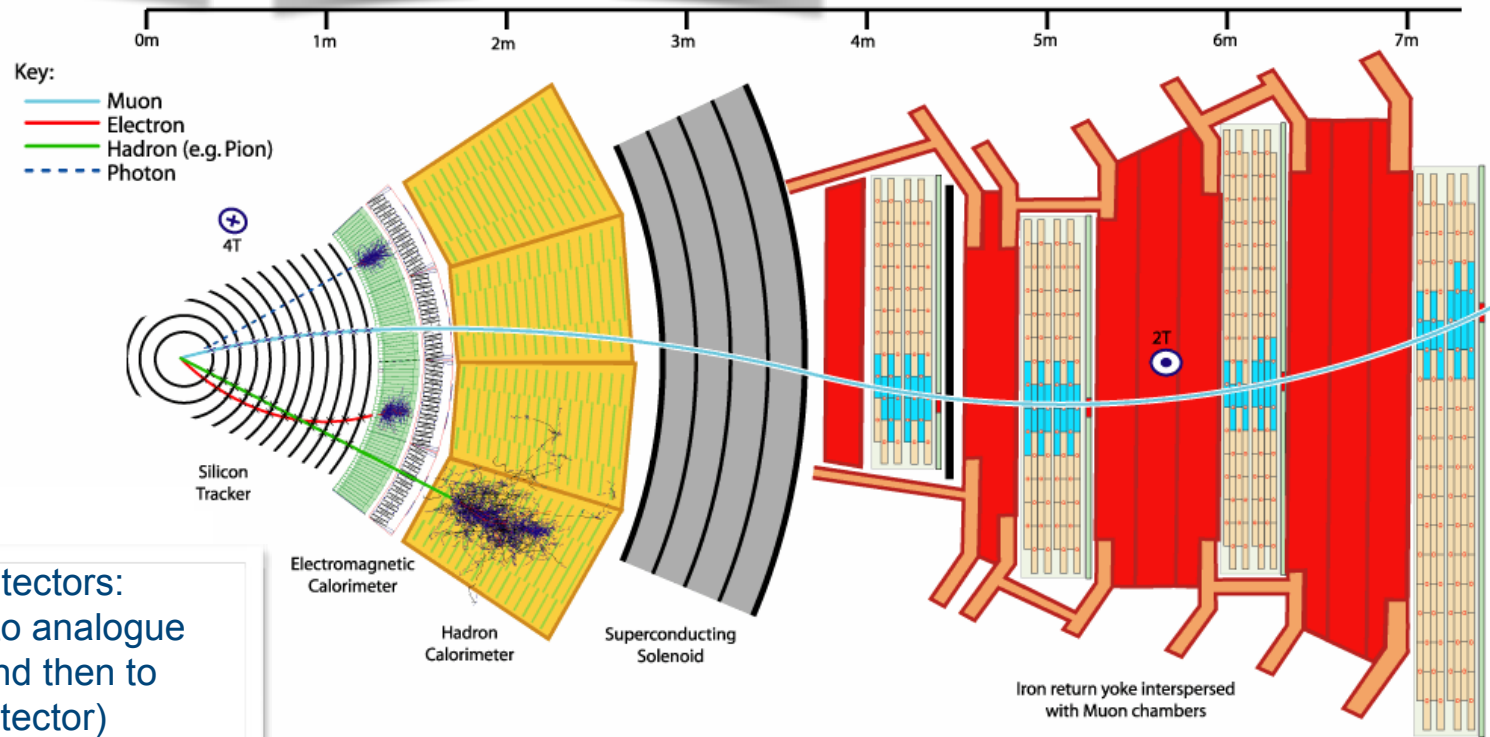
Slide from I. Gregor

HEP detector: signal types

Calorimeter: ionisation
→ charge measurement
→ electrical signal (analogue or digital)

Calorimeter: ionisation
→ light signals from crystals or scintillators converted into electrical signals (analogue or digital)

Muon-Detectors:
charge in gas detected by wires
→ electrical signal converted into digital signals



Tracker: silicon detectors:
charge converted to analogue (amplifier stage) and then to digital (on or off detector)

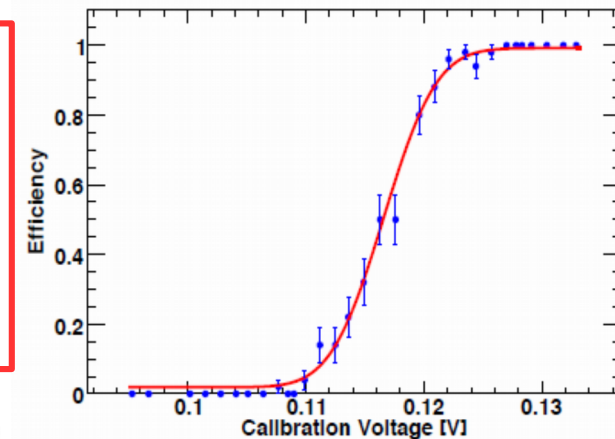
Tracker: gas detectors: charge converted to digital (on detector or off detector)

Slide from I. Gregor

Important figures of merit

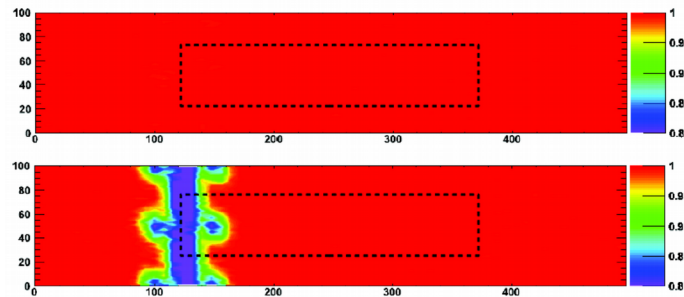
- Tracking detector (systems)

- Signal-to-noise ratio (before/after irradi.)
- Detector resolution
- Efficiency a.f.o. various parameters
- Charge collection efficiency (before/after irradi.)



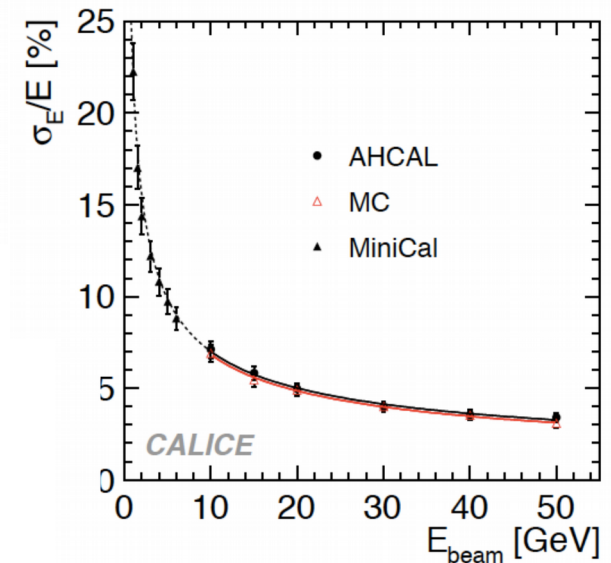
- Calorimeter

- Signal-to-noise ratio
- Energy resolution
- Single photon peak
- Electron/hadron ratio



- Other (new) requirements:

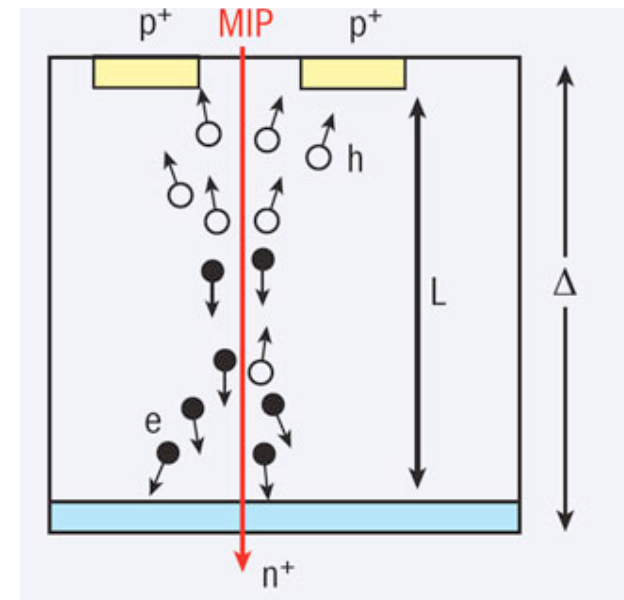
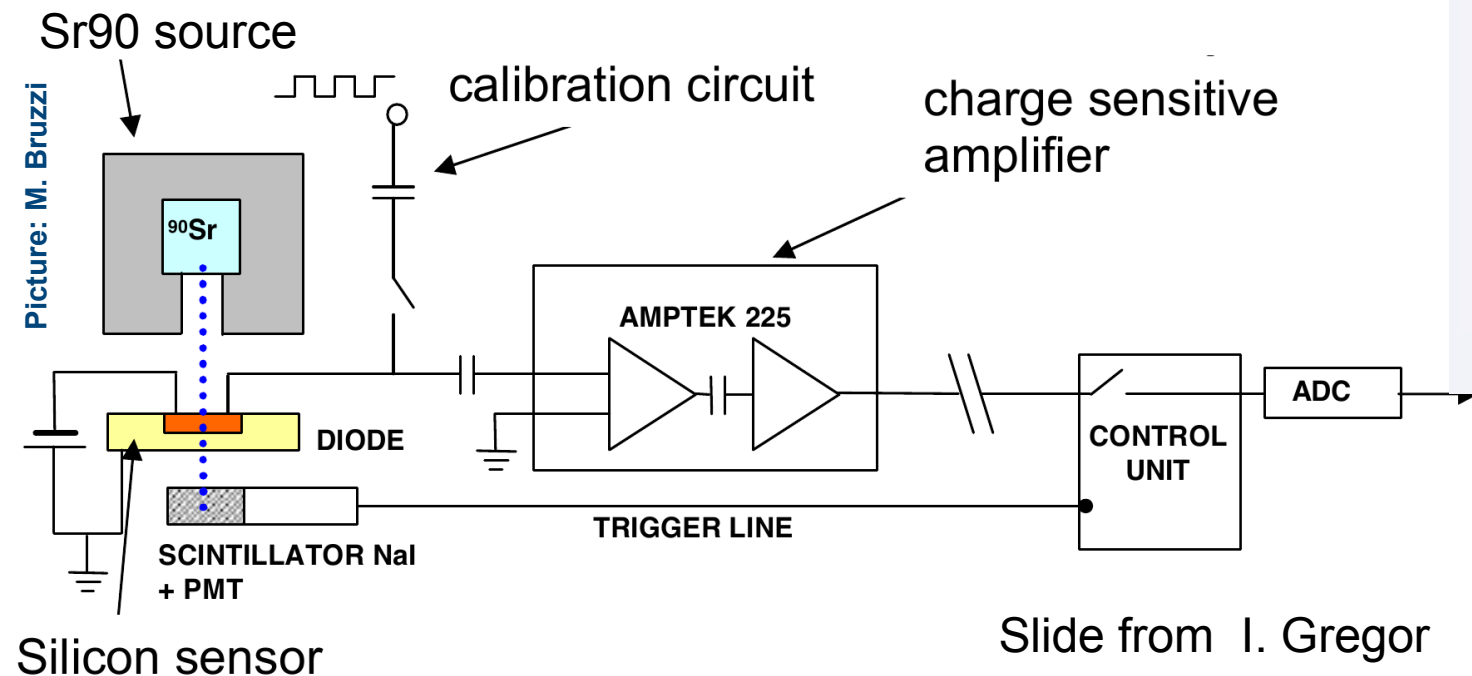
- Timing in tracking and calorimetry
- Environmental challenges (cryogenic detectors)
- Detectors in high-rate experiments



Slide from I. Gregor

Important tracker parameters (1)

- Charge collection (CC): collected charge in sensor volume
 - Important parameter affected by radiation damage and other effects
 - Charge induced by charged particle from radio-active source, laser, beam
 - Measurement of CC normalised to optimal value a.f.o. other parameter (charge collection efficiency CCE)
 - Bias voltage
 - Radiation level



Can be measured with bench top set-up in a laboratory

Important tracker parameters (2)

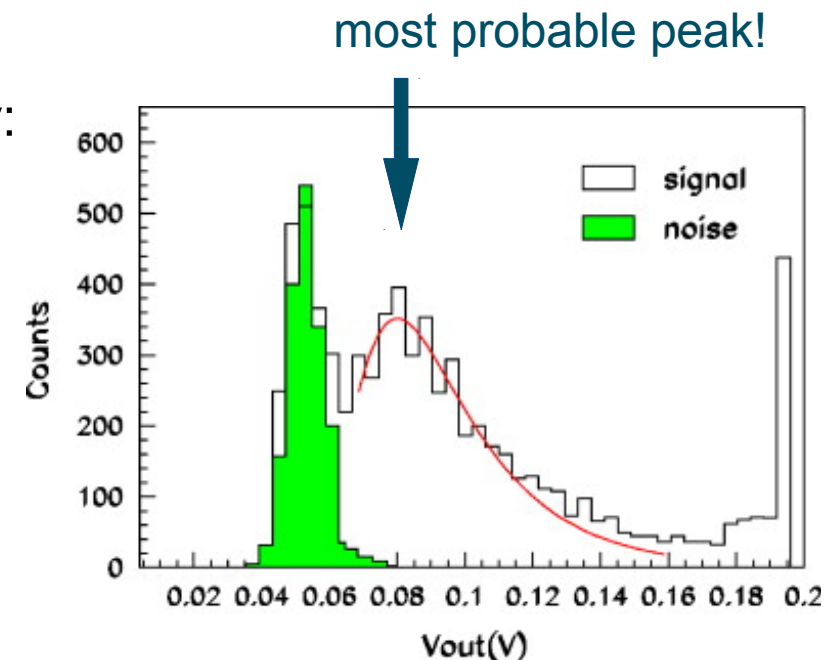
- Signal-to-noise ratio (SNR): signal amplitude over intrinsic noise of the detector
 - Parameter for analogue signal
 - Good understanding of electrical noise needed
 - Noise measurements
 - Noise simulations
 - Signal induced by source, laser, test beam
 - Optimal SNR > 20
 - SNR also important for efficiency vs. purity:

Can be measured with bench top set-up in a laboratory

Detection efficiency is probability to detect particle, typically 99.X% for one layer.

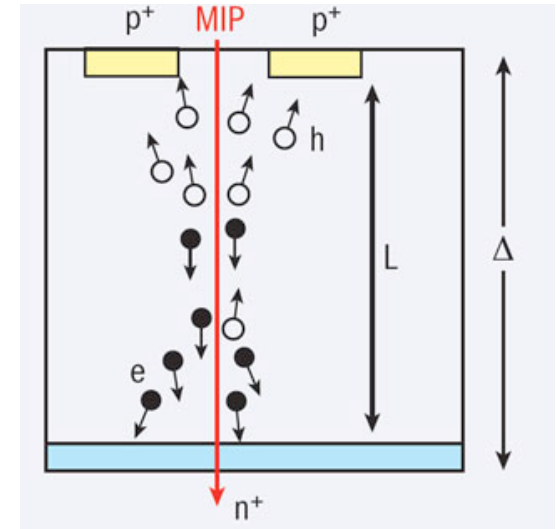
For 7 layers?

$$\begin{aligned} \epsilon &= 0.99 & \epsilon &= 0.98 \\ \epsilon^7 &= 0.93 & \epsilon^7 &= 0.87 \end{aligned}$$

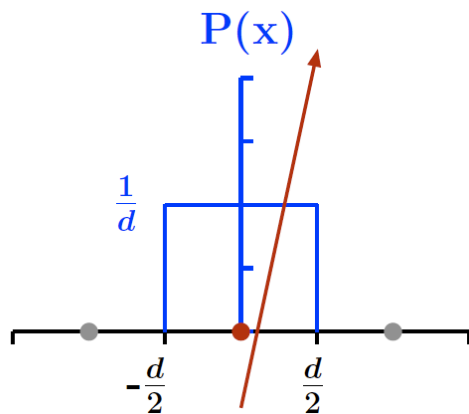


Important tracker parameters (3)

- Spatial resolution of a tracking device
- Depending on detector geometry and charge collection
 - Pitch, i.e. distance b/w channels
 - Charge sharing b/w channels
- Simple case:
 - Traversing particle creates signal below one entity
 - All charge is collected on this entity (strip/pixel)
 - Assume flat distribution over sensor for many particle passages:
 - Unity probability distribution



Picture: U. C. DaVia



$$P(x) = \frac{1}{d} \quad \Rightarrow \quad \int_{-d/2}^{d/2} P(x) dx = 1$$

The **reconstructed** point is always the middle of the strip:

$$\langle x \rangle = \int_{-d/2}^{d/2} x P(x) dx = 0$$

Important tracker parameters (4)

- Calculate the resolution (standard deviation)

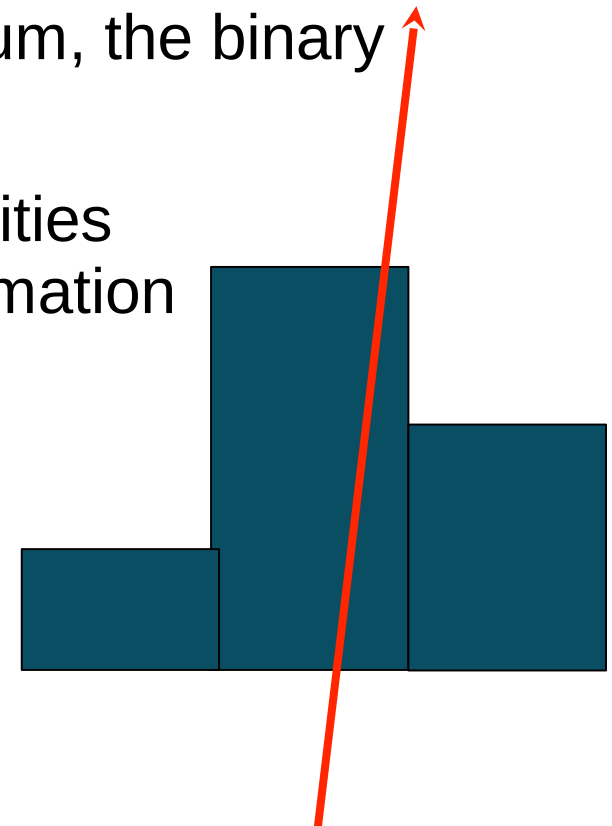
$$\sigma_x^2 = \langle (x - \langle x \rangle)^2 \rangle = \int_{-d/2}^{d/2} x^2 P(x) dx = \frac{d^2}{12}$$

- Resulting in general term for BINARY resolution:

$$\sigma = \frac{d}{\sqrt{12}} \quad \leftarrow \text{very important !}$$

- For a silicon strip detector with pitch = 80 μm , the binary resolution is $\sim 23 \mu\text{m}$
- In case of charge sharing b/w read-out entities
→ Resolution improved by additional information of adjacent channels

Needs to be measured in beam. More sophisticated algorithms for large angle tracks



Slide from I. Gregor

A new Beam Loss Monitor for LHC

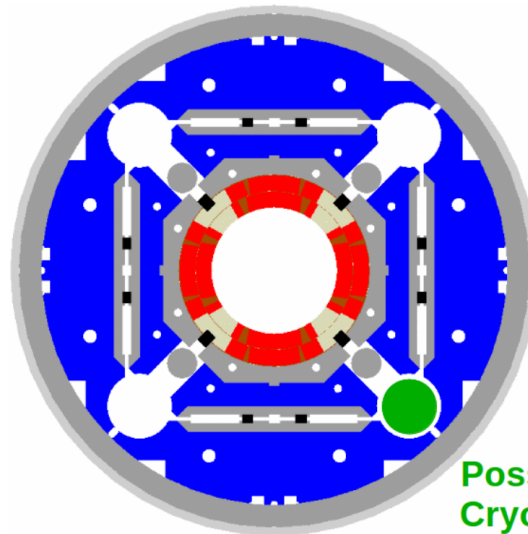


Goal:

- Measure beam loss as precise as possible
- Put detectors INSIDE the magnet
- Need to operate detectors @ 1.8 K

Questions:

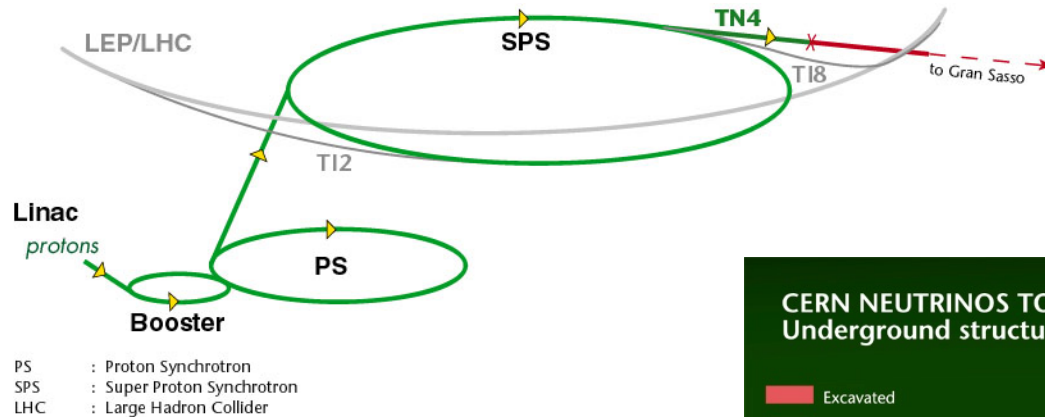
- Which sensors work at 1.8 K?
- Do they behave differently?
- Radiation damage different?



Possible
CryoBLM
location

Current
BLM
location

More HEP: CNGS

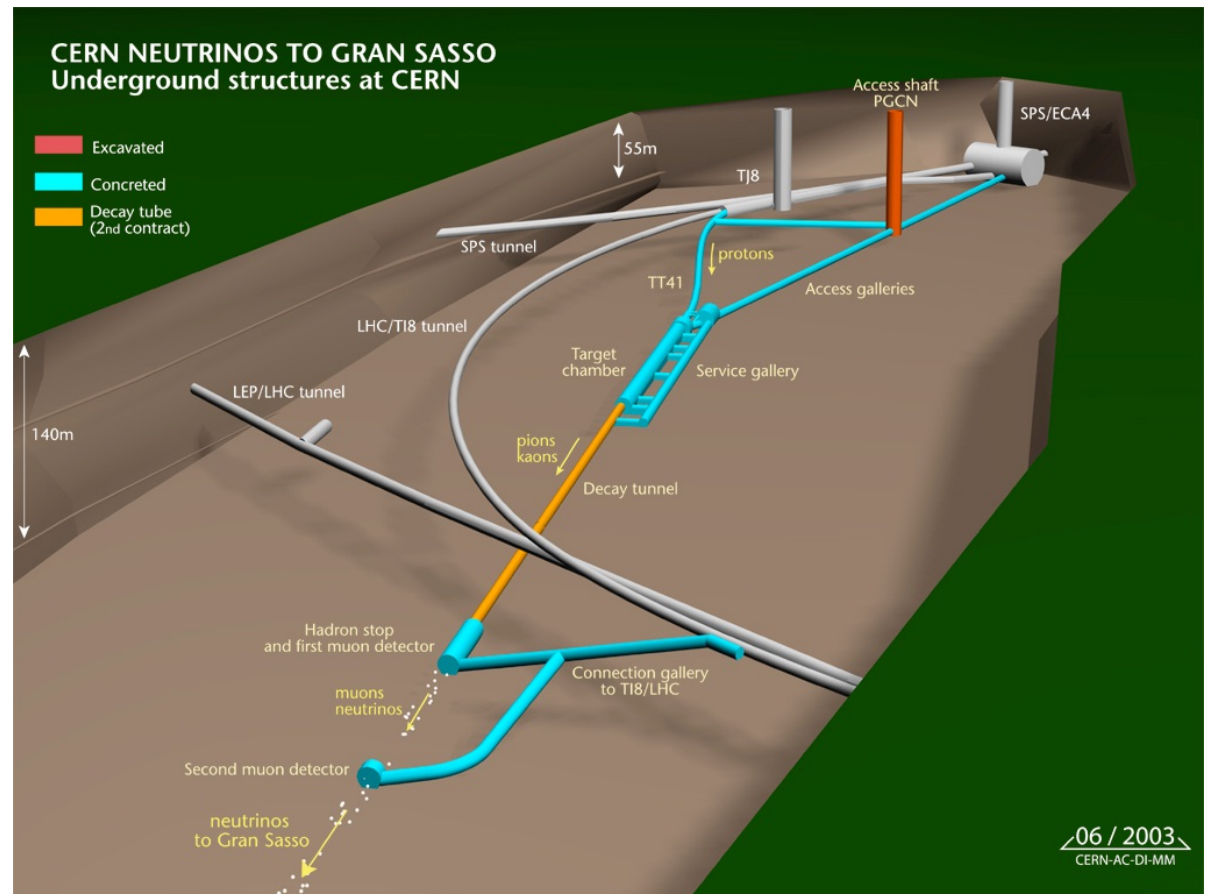


Send neutrinos to Gran Sasso:
Protons on target → kaons/pions
→ Muons → Neutrinos

Measurement:

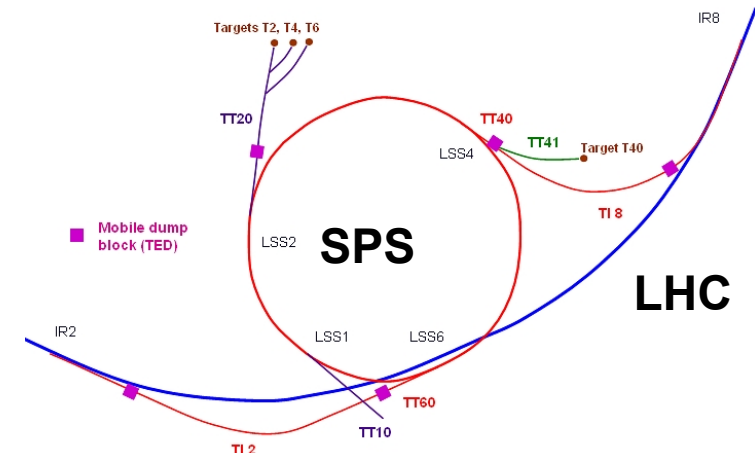
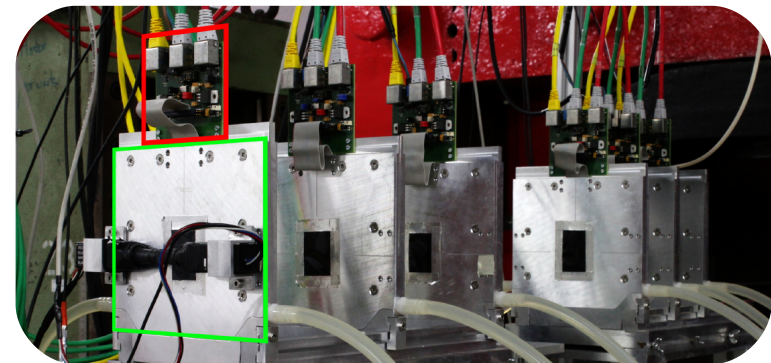
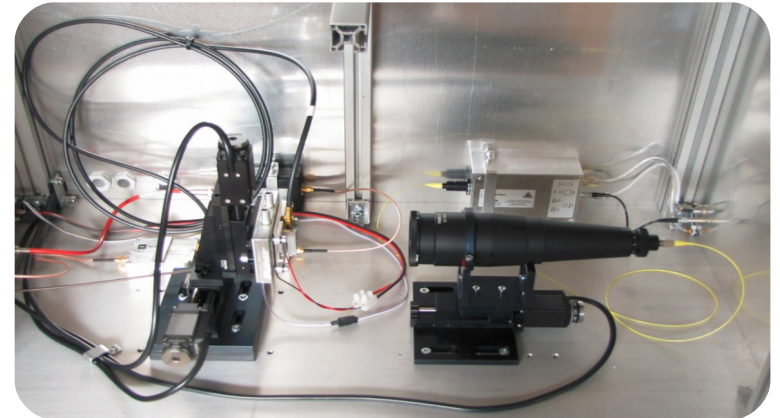
Proton intensity profile +
muon intensity profile

- Correlate
- Time-of-flight
- Cross-check clock system
- Travel neutrinos too fast ?!



Outline

- HEP detector overview
 - what we have and
 - **why we need to do better**
- Radiation damage in semiconductor sensors
- Characterisation techniques
- Clever ideas mitigating radiation damage



Why is more R&D needed?

- We have all these nice detectors, why not use them?
 - Requirements change
 - From LHC to HL-HLC:
 - higher luminosity
 - more interactions per bunch crossing
 - more radiation damage
 - ...
 - At ILC:
 - Low material budget for high resolution tracking
 - Power pulsing (bunch trains)
 - ...
- need sophisticated R&D programs!

R&D answers ...

General:

- How much charge does my detector collect?
- Does my sensor work at 2 K? In space?
- Can I use my detector for a precise timing at high flux?
- What is the spatial resolution of my detector?

Fluence related:

- How (well) does my detector operate after high fluence?
- How does my sensor change with fluence? Why?
- Which material should I choose for my tracker upgrade?

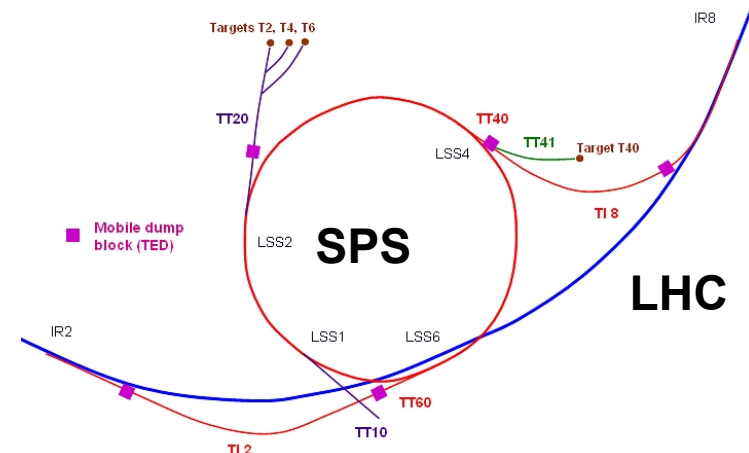
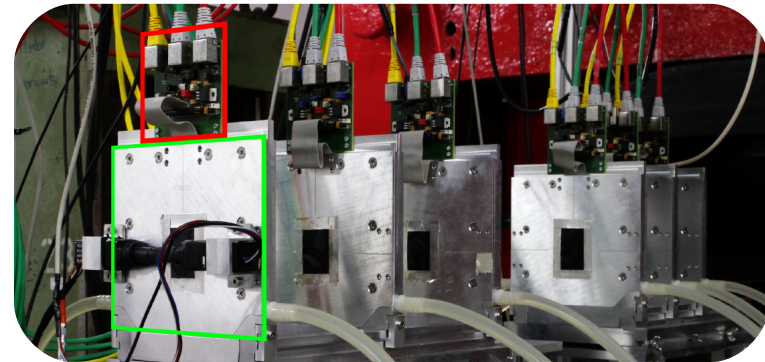
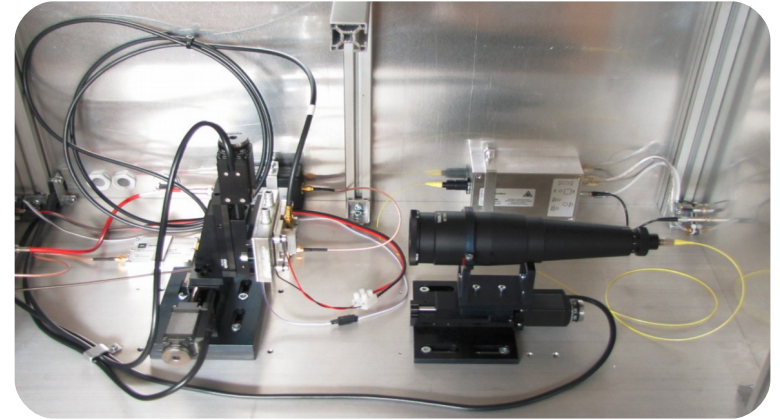
... using different techniques

- Probe station for CV, IV + LCR meter
 - Laser-/Source-based set-up + fast amplifier
 - Cryogenic/temp-controlled set-up + ampere meter
 - Test beam with beam telescope for tracking
 - Irradiation campaign + test beam
 - Cryogenic set-up + test beam
 - ...
- Will introduce an incomplete list of techniques later.

Let's have a look at radiation damage first.

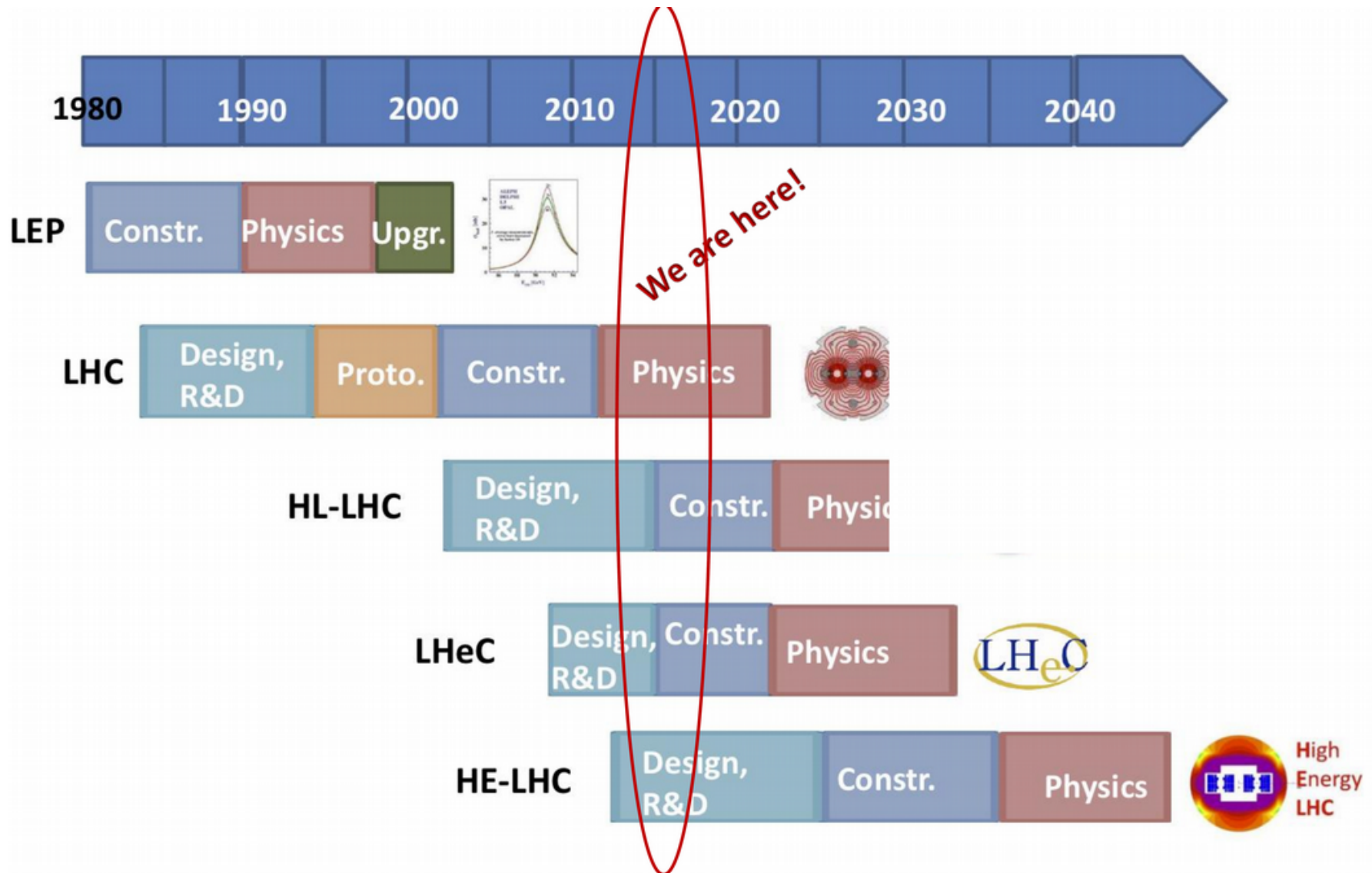
Outline

- HEP detector overview
 - what we have and
 - why we need to do better
- **Radiation damage in semiconductor sensors**
- Characterisation techniques
- Clever ideas mitigating radiation damage



Past, present, future

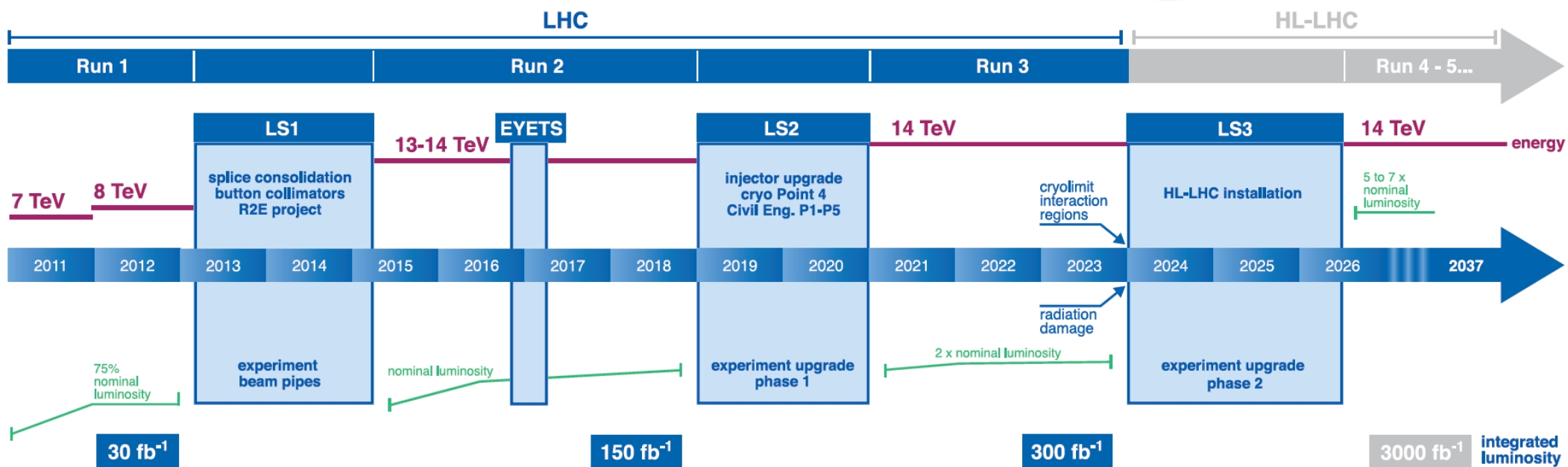
- What fluences (and hence damage) shall we expect?



HL-LHC roadmap

- 300 fb⁻¹ in 10 years of operation (end 2023)
- 3000 fb⁻¹ expected for HL-LHC
→ for 10 y operation: yearly rad. damage of run I-III
- R&D takes time, better start now to be ready for installation in ~2024/25

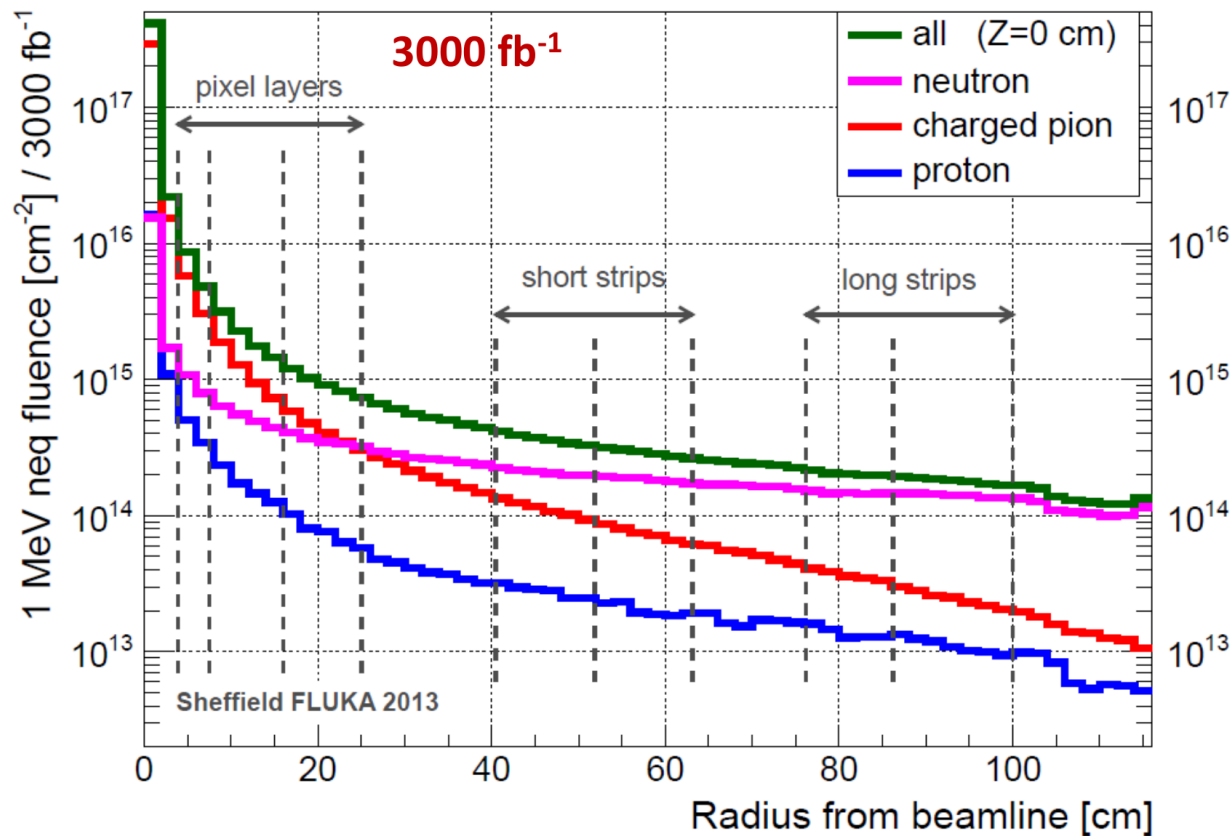
LHC / HL-LHC Plan



Fluence

- Most damage for detectors close to the IP: usually vertex/pixel detector

ATLAS Inner Tracker Fluences at the HL-LHC

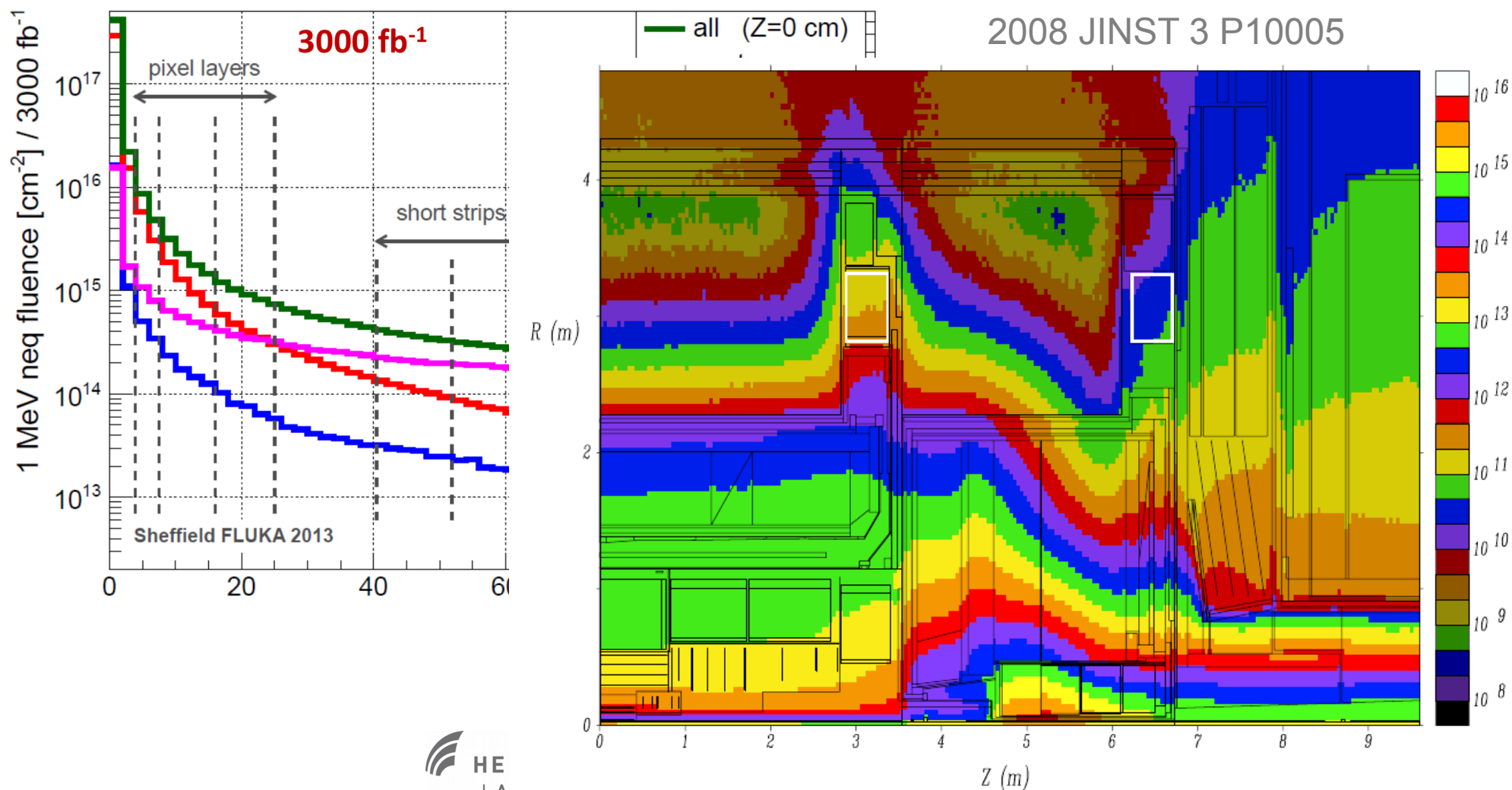


I. Dawson, et al., Sheffield University,
ATLAS upgrade radiation background simulation

Fluence

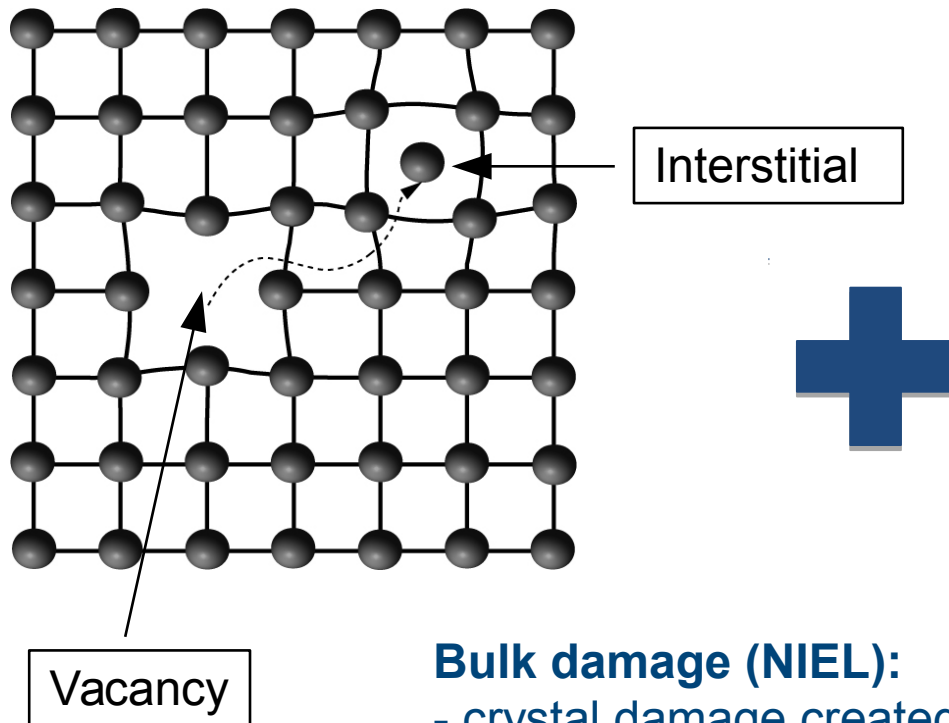
- Most damage for detectors close to the IP: usually vertex/pixel detector

ATLAS Inner Tracker Fluences at the HL-LHC

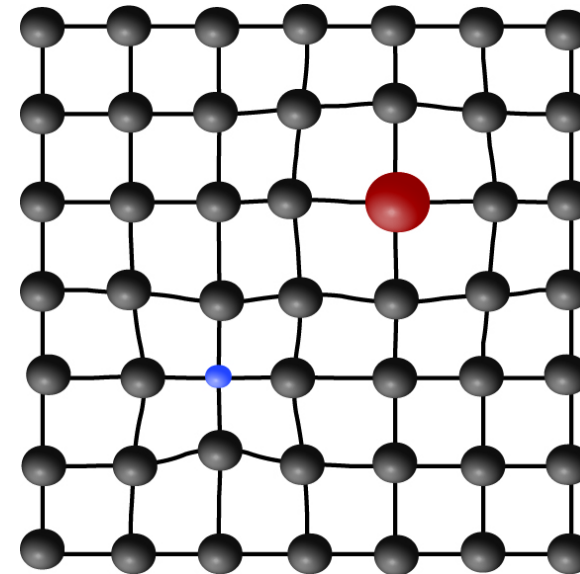


Radiation damage

- Radiation induced



- Material impurities



Bulk damage (NIEL):

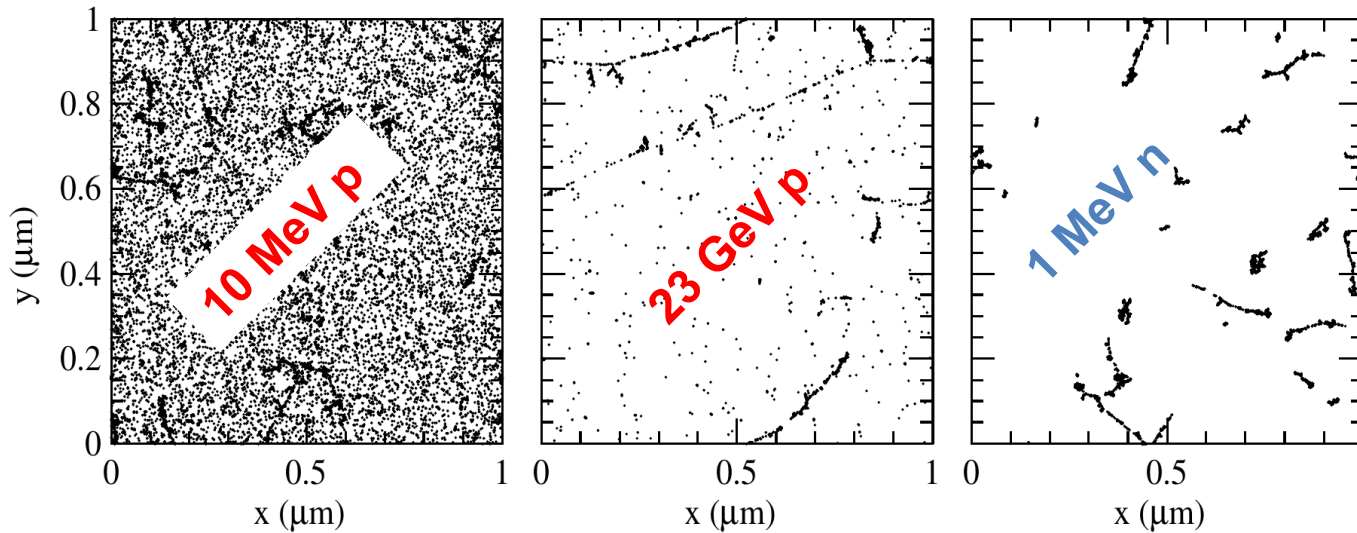
- crystal damage created by neutrons, pions, protons, electrons
- Irradiation + migration creates complex defects: V2, VO, ...

Surface damage (IEL):

- at oxide-Si-interface

Creation and impact of bulk defects

- Depends on particle charge, mass, energy

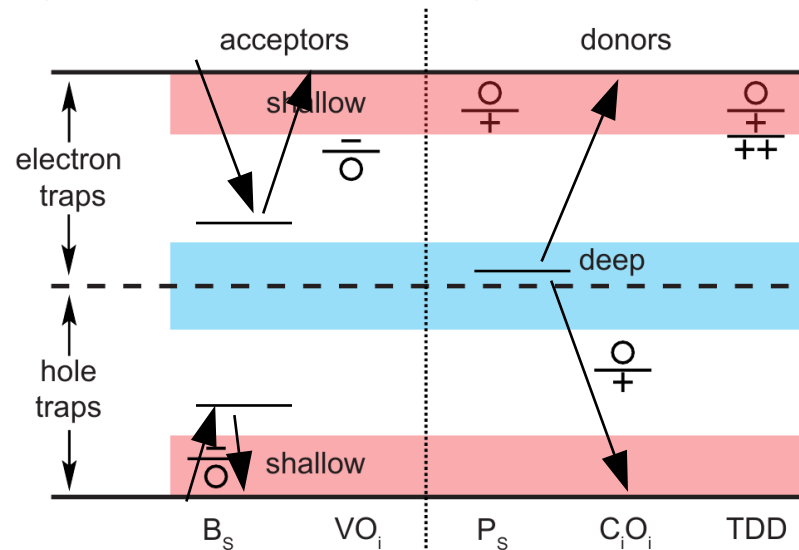


Mika Huhtinen, NIMA 491 (2002) 194

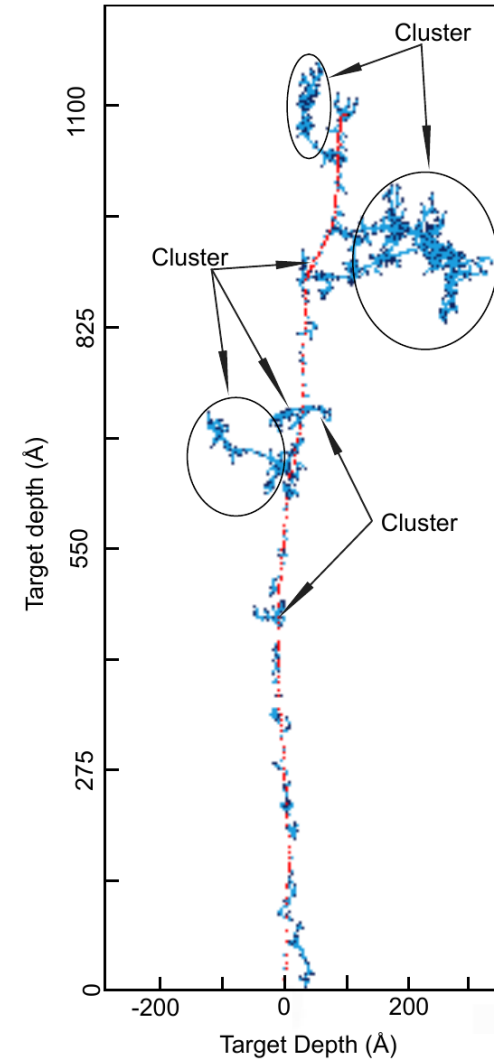
enable trapping,
generation,
recombination

$$\tau_{trapping} = \frac{1}{\sigma v_{th} N}$$

$$\tau_{detrap} = \frac{1}{\sigma v_{th} N} * \exp(E_a/k_B T)$$

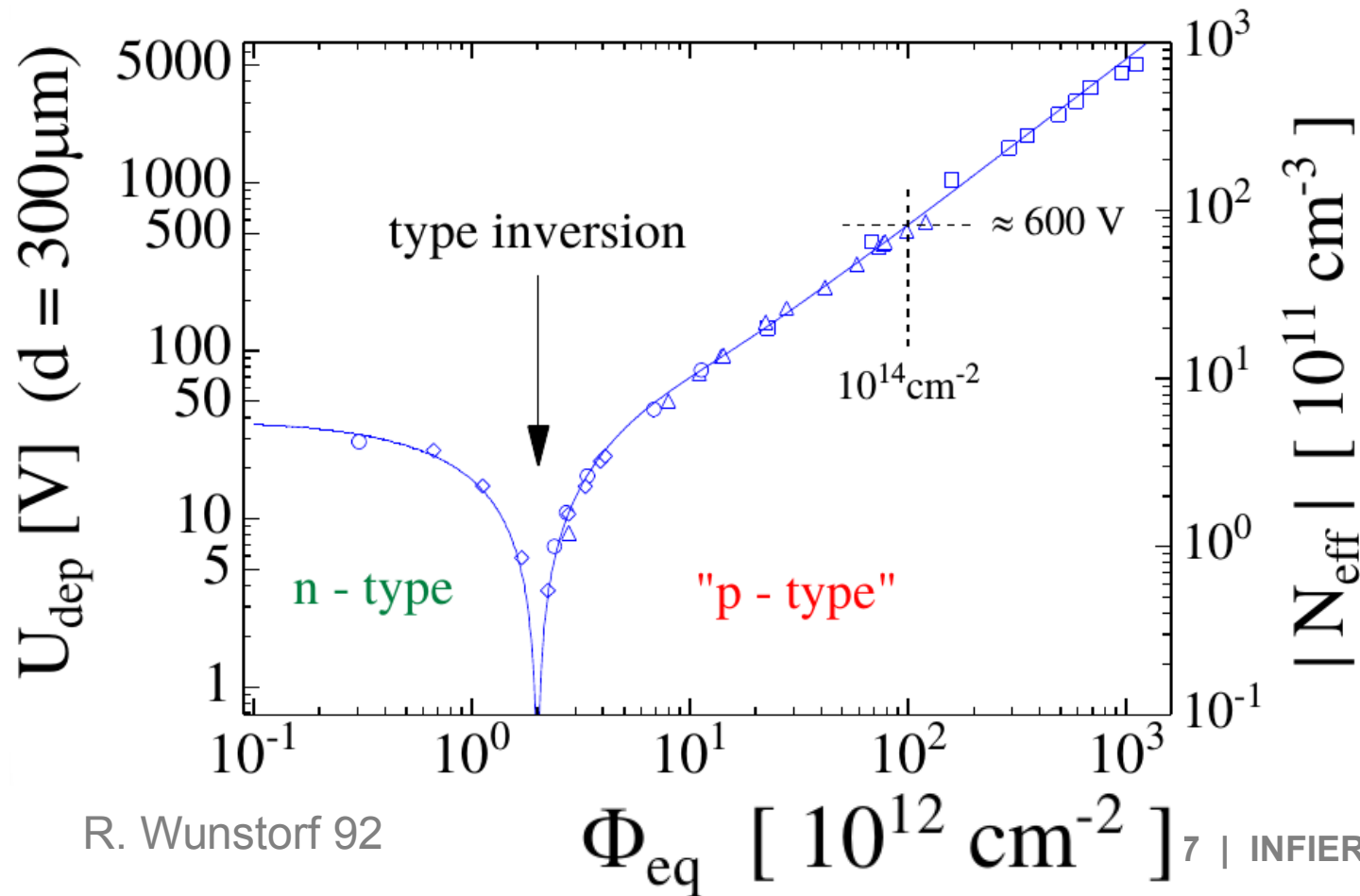


1 MeV n
50 keV PKA



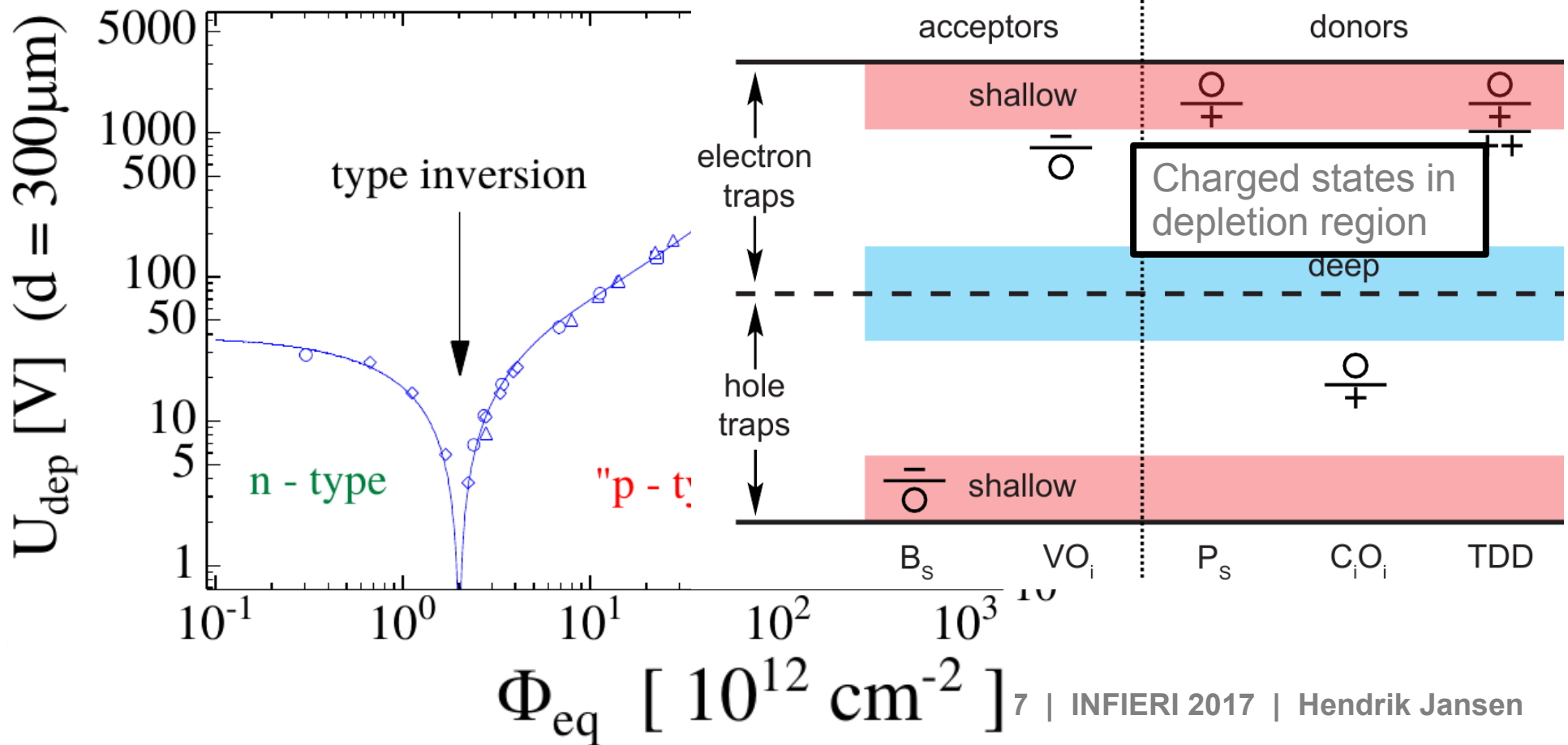
Macroscopic effects

- Change of depletion voltage (and possible type inversion)



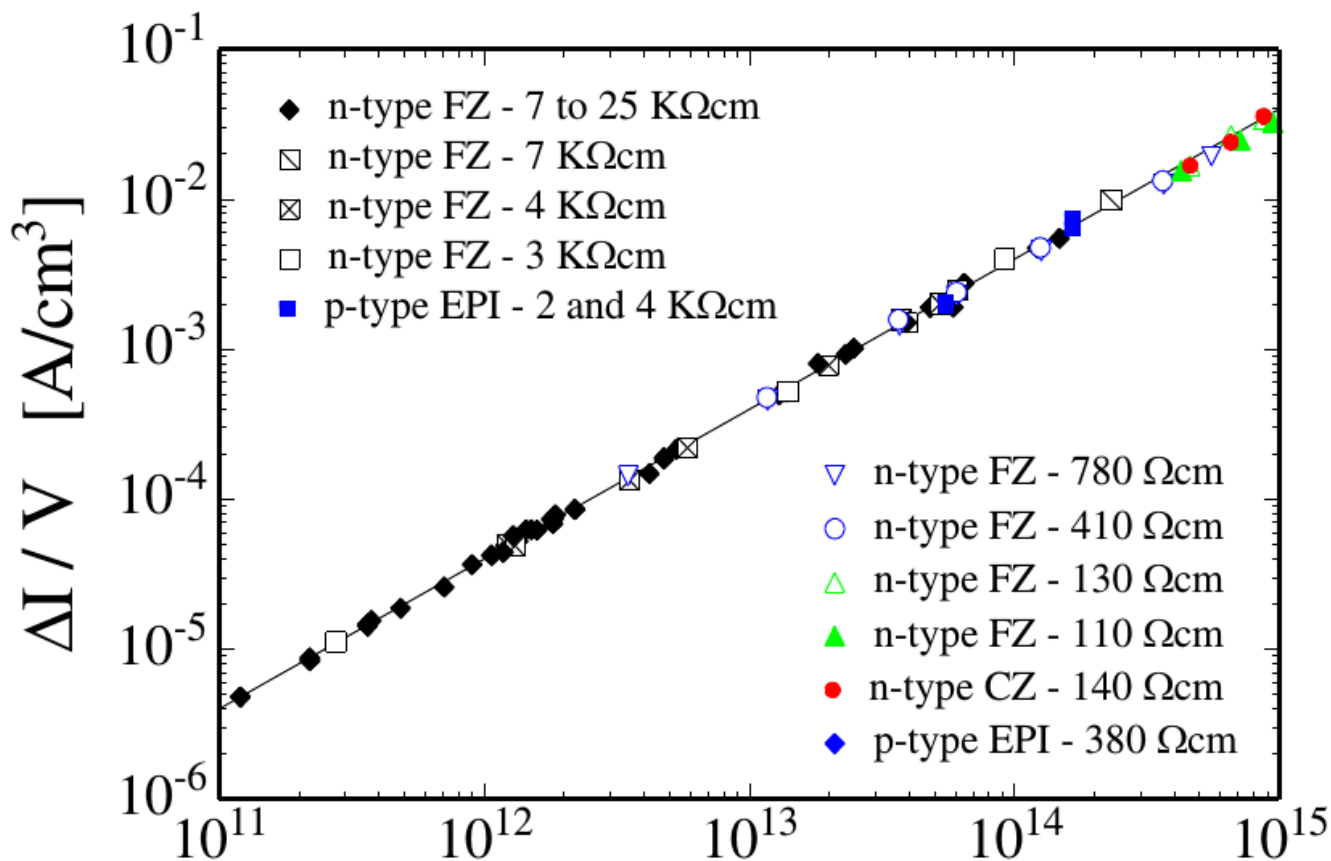
Macroscopic effects

- Change of depletion voltage (and possible type inversion)



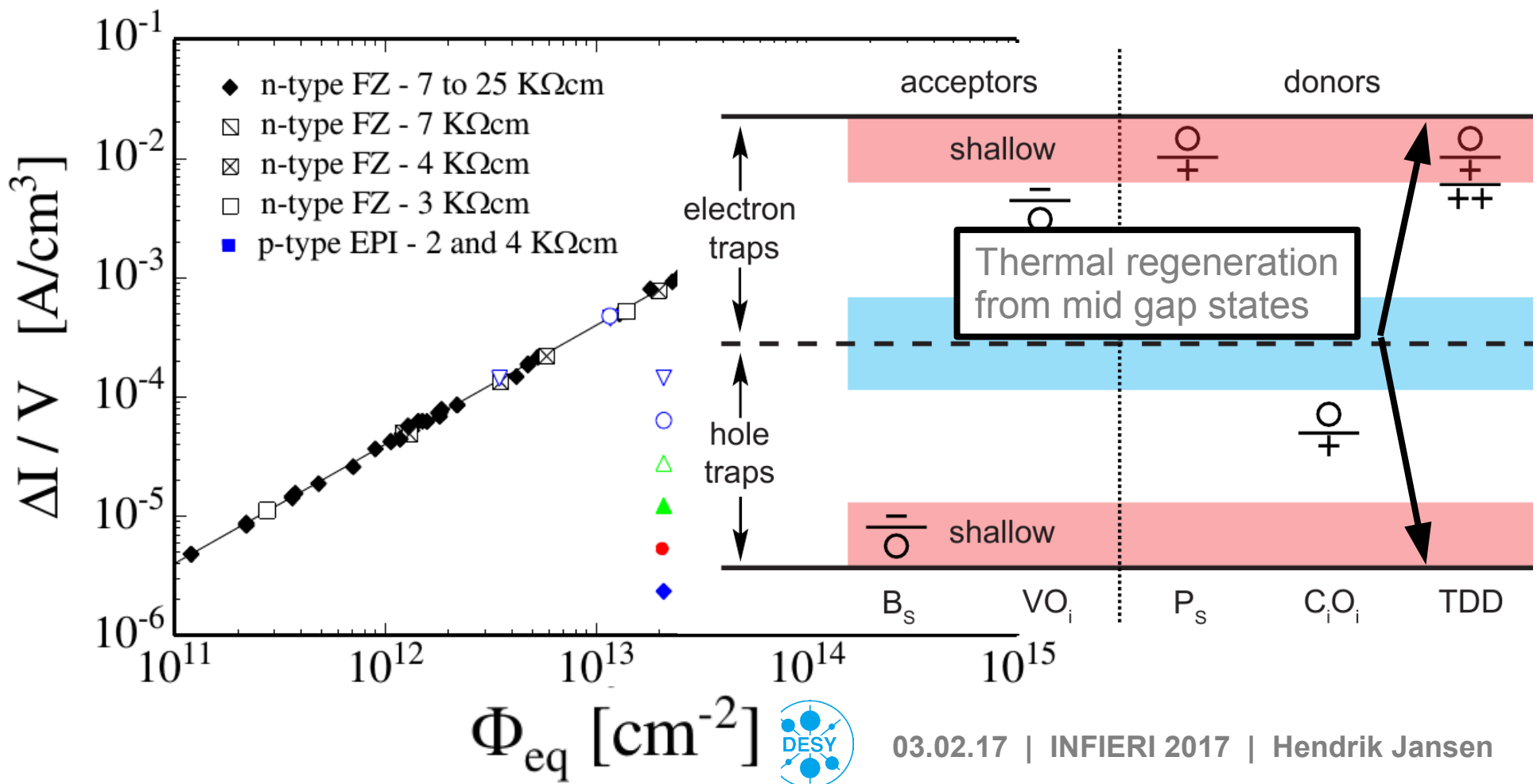
Macroscopic effects

- Change of depletion voltage (and possible type inversion)
- Increase in leakage current



Macroscopic effects

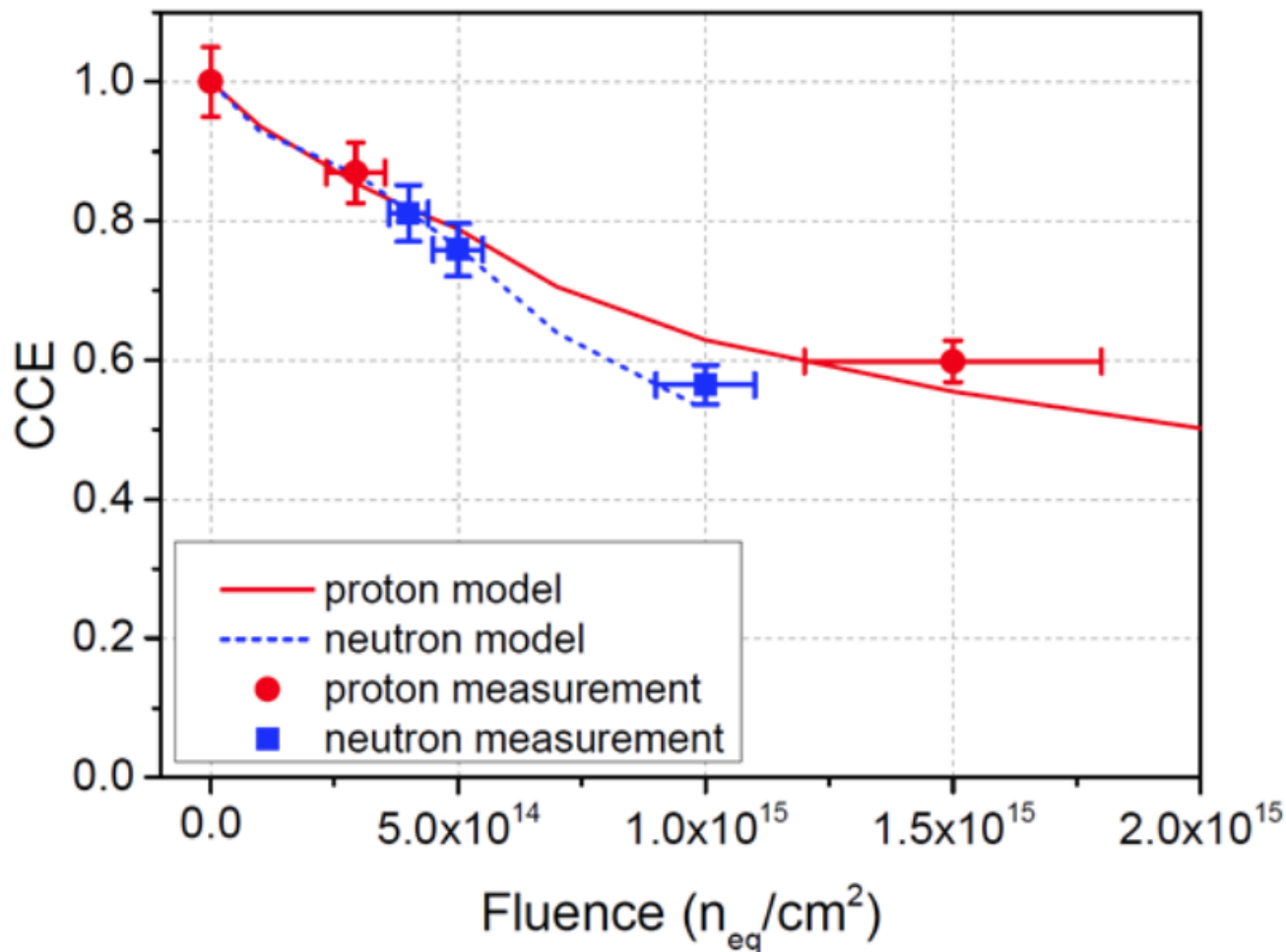
- Change of depletion voltage (and possible type inversion)
- Increase in leakage current



Macroscopic effects

- Change of depletion voltage (and possible type inversion)
- Increase in leakage current
- Decrease in charge collection efficiency

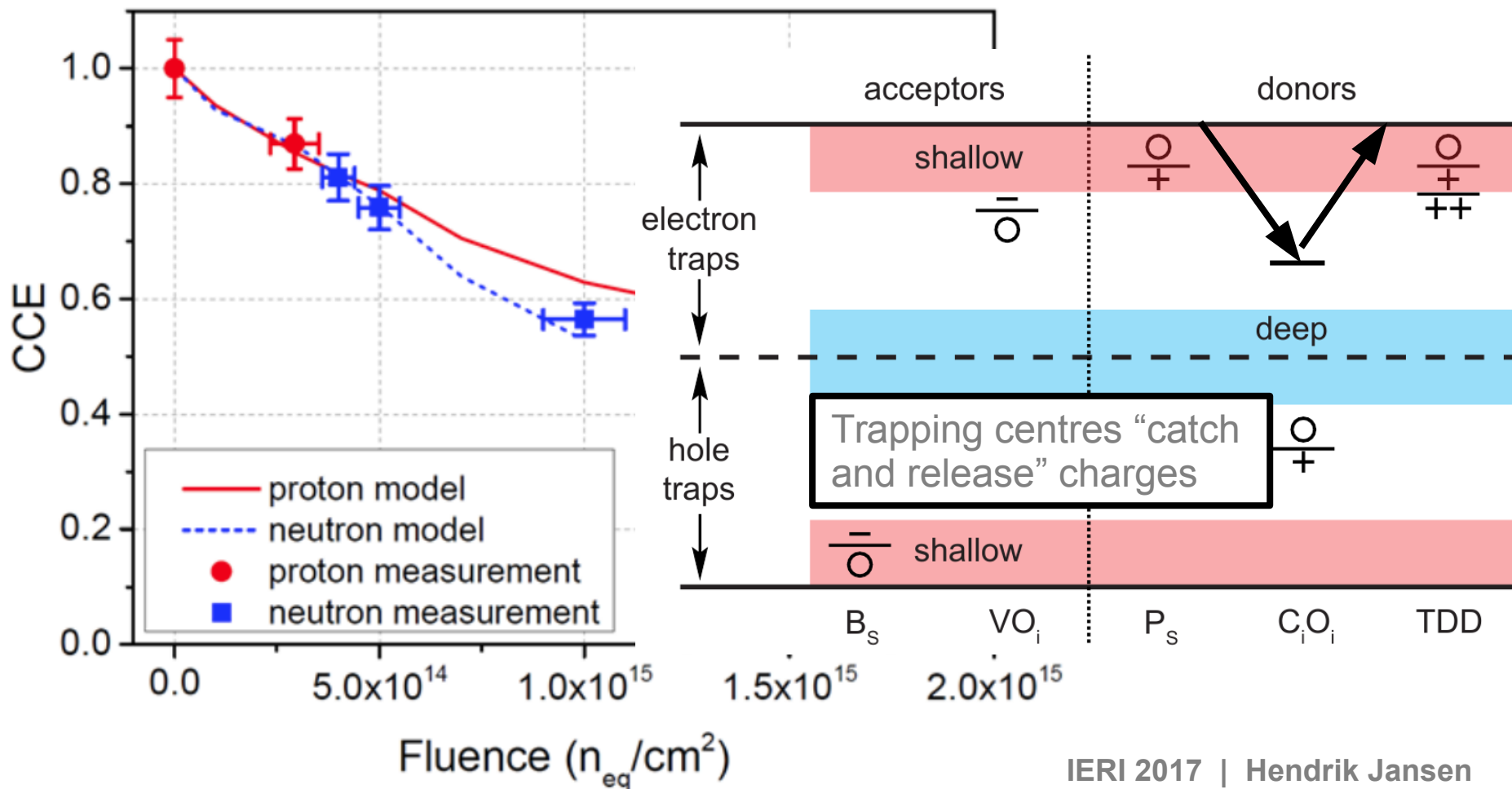
CMS Tracker JINST 9 (2014)12



Macroscopic effects

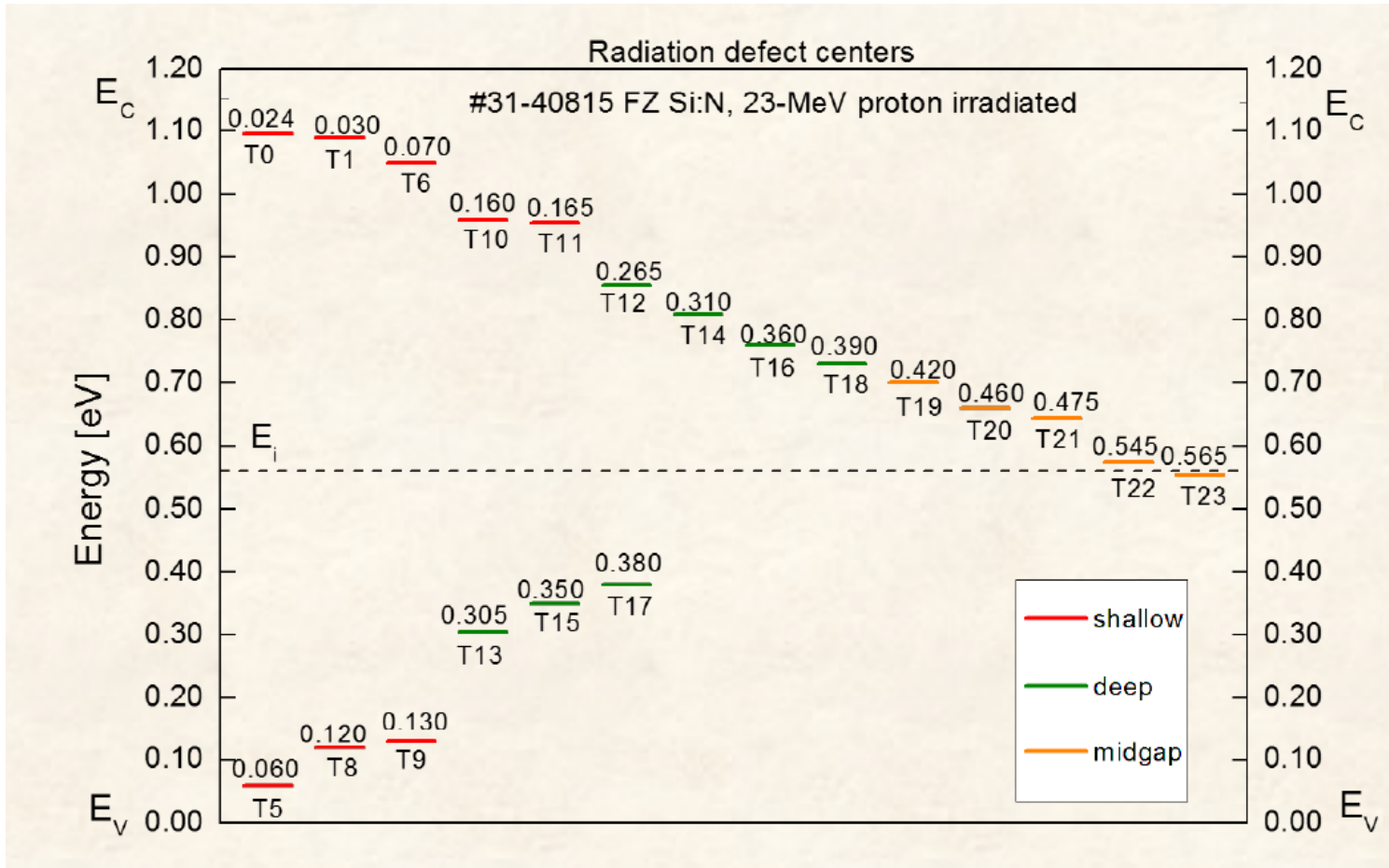
- Change of depletion voltage (and possible type inversion)
- Increase in leakage current
- Decrease in charge collection efficiency

CMS Tracker JINST 9 (2014)12



Cumbersome work

- Identification of ~20 defects in silicon

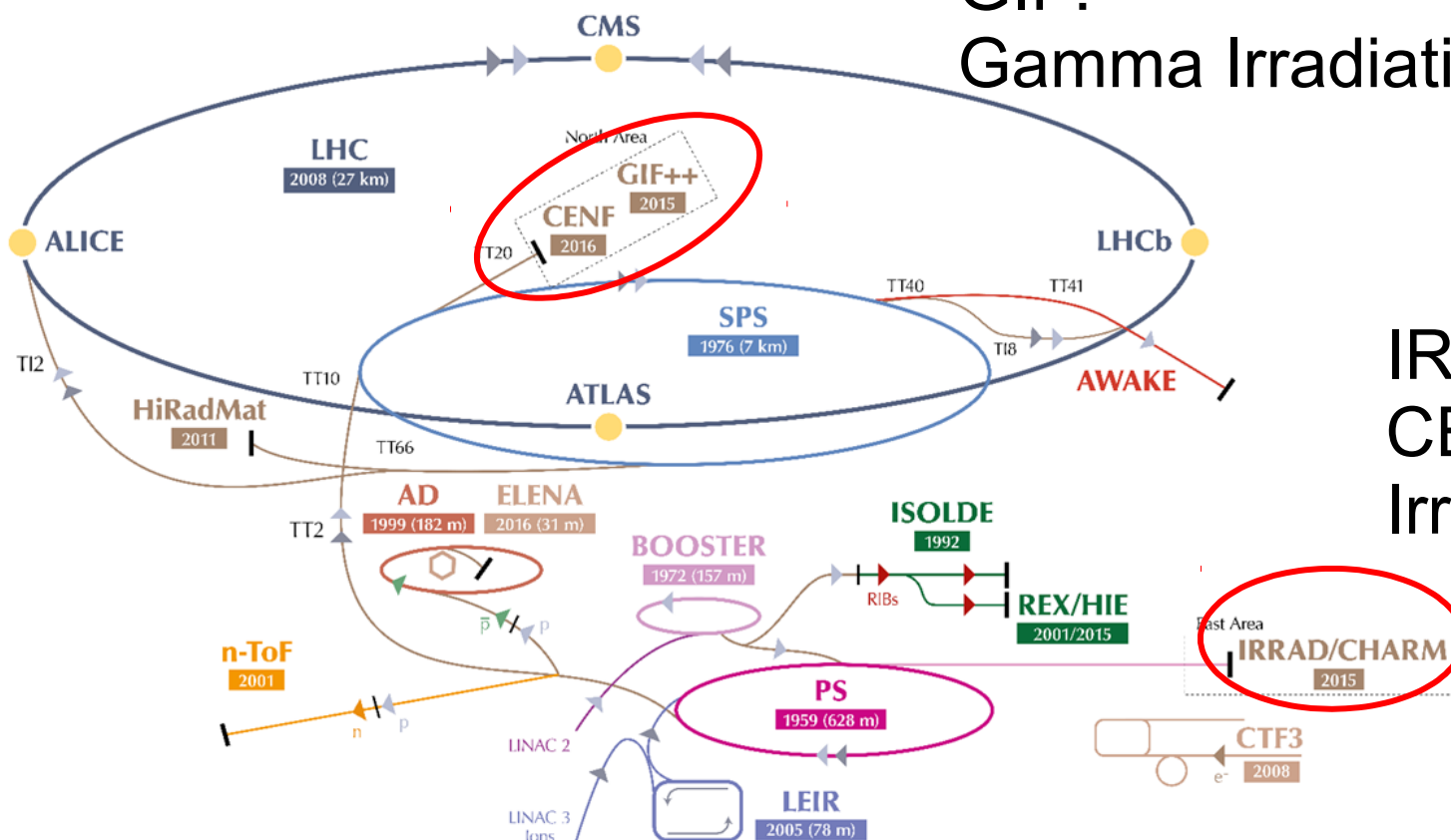


We'll see later about the techniques

Keeping ahead of damage

- Dedicated irradiation facilities to simulate expected flux
- Damage depends on particle type and energy
→ many facilities

GIF:
Gamma Irradiation Facility



IRRAD:
CERN Proton
Irradiation Facility

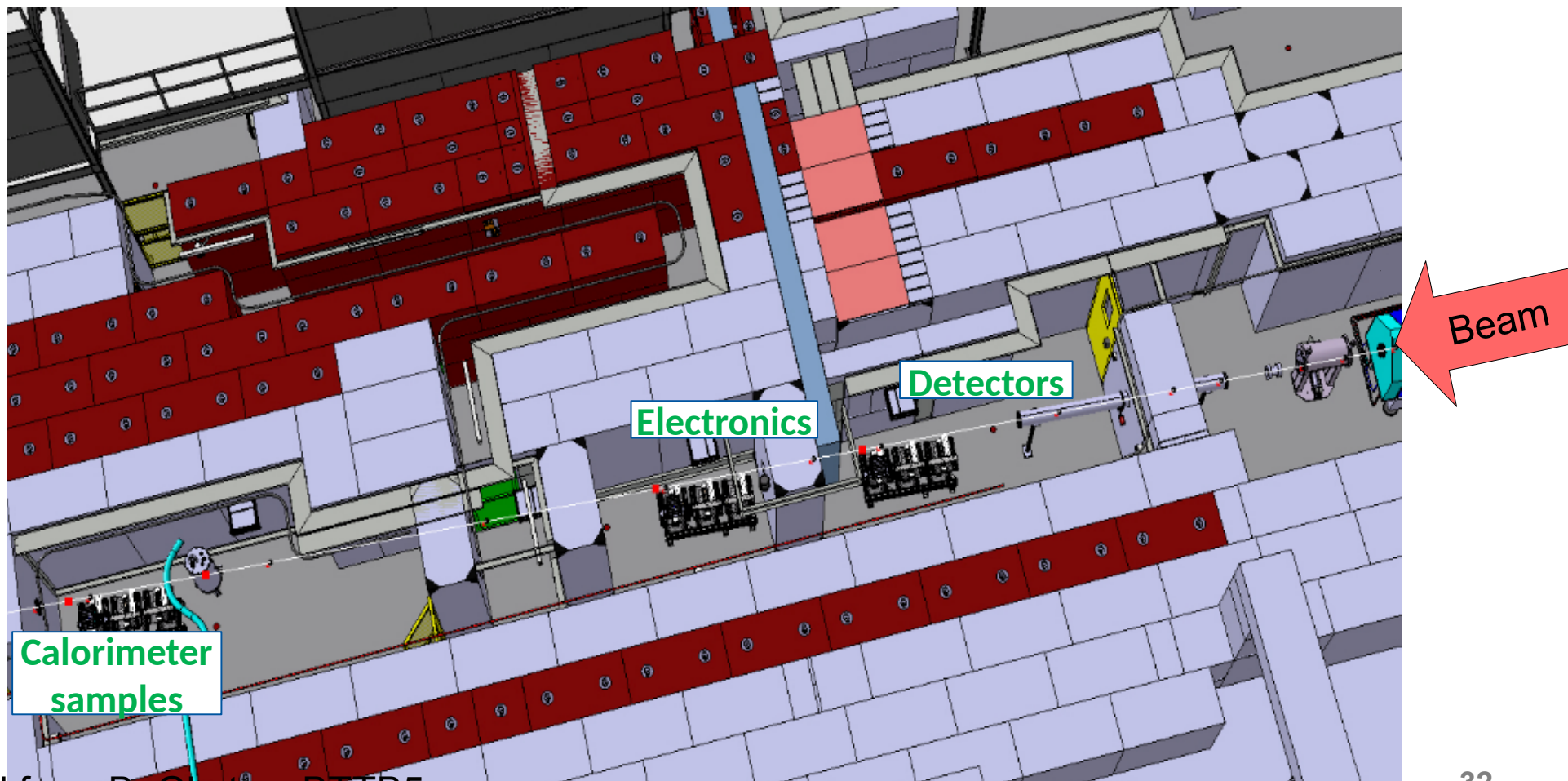
GIF

- $E_\gamma = 0.66 \text{ MeV}$; max. dose-rate 2.5 Gy/h @ glass contact



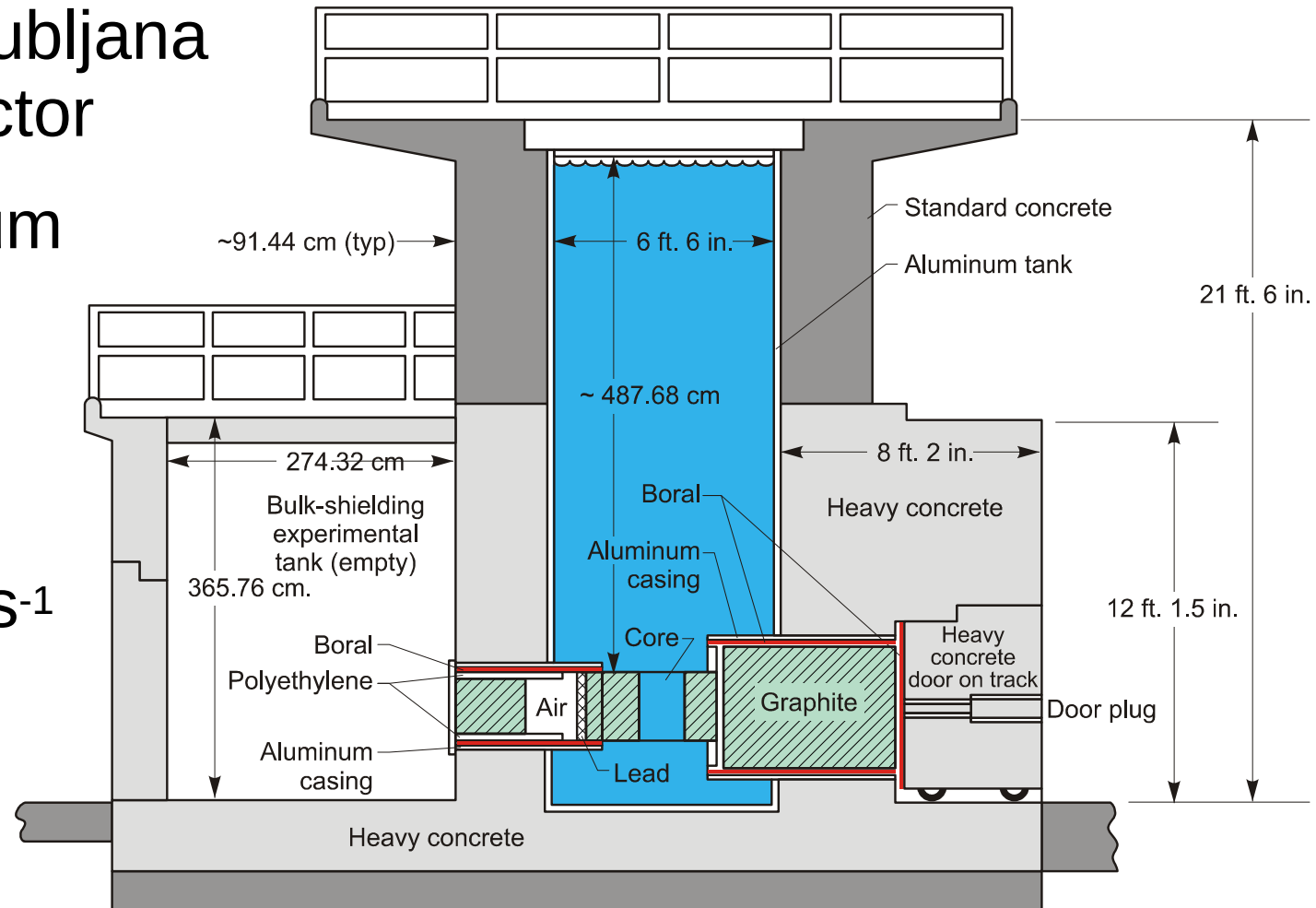
IRRAD

- Component testing of HEP experiments
- Proton beam of 24 GeV/c, 12 x 12 mm²
- Fluence: 1e16 p/cm² in 14 days



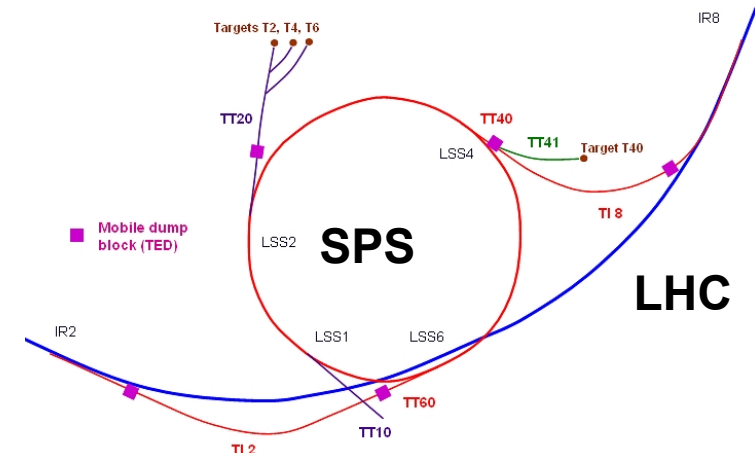
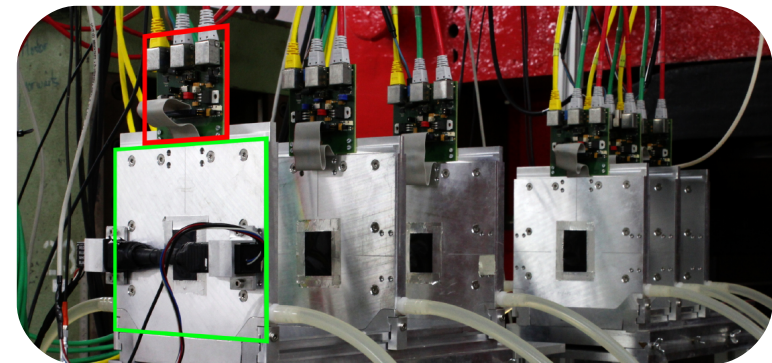
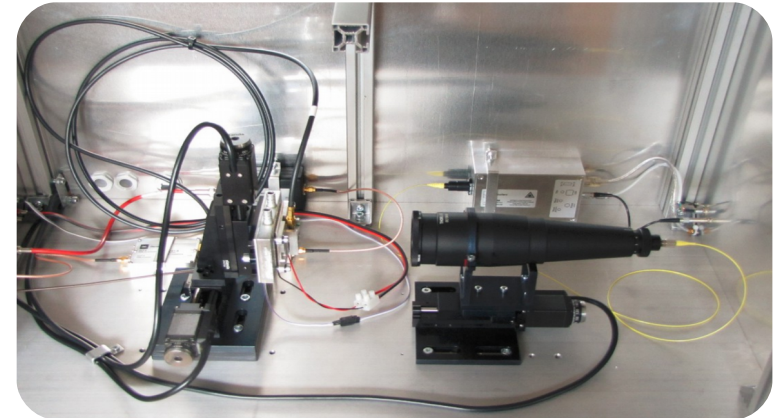
Other irradiation facilities

- Neutron damage is also important
- Neutron irradiation possible at reactors, e.g. Ljubljana JSI TRIGA Reactor
- 250 kW maximum
- Fast & thermal neutrons
- Flux:
up to $4 \times 10^{12} \text{ cm}^{-2} \text{ s}^{-1}$



Outline

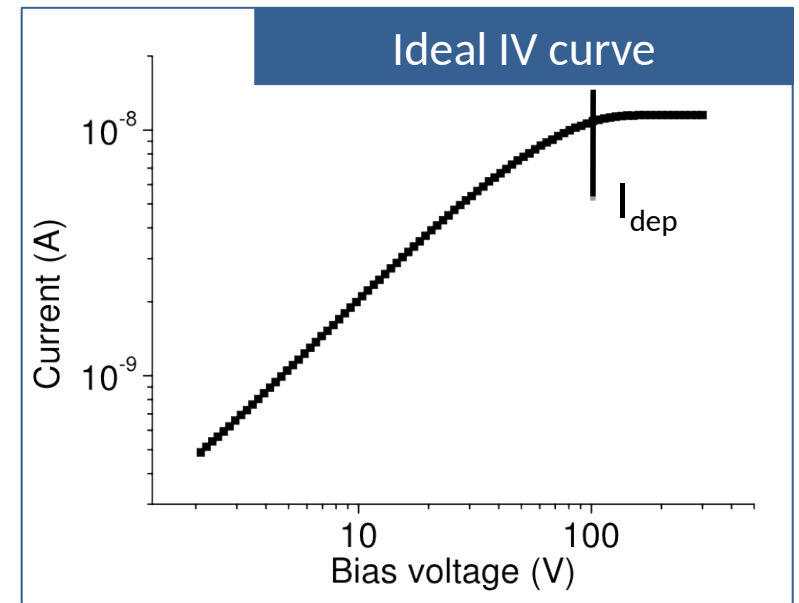
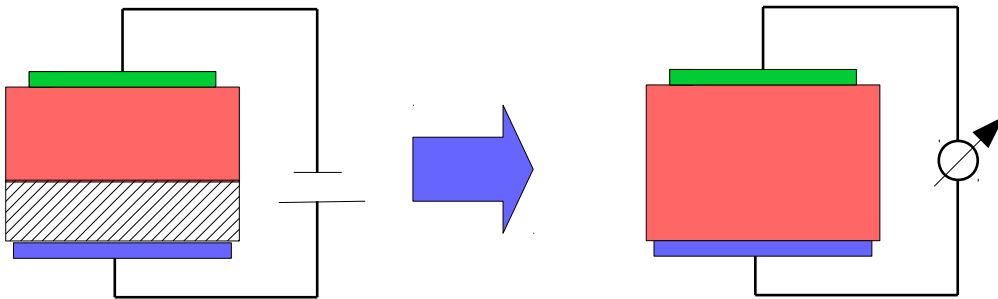
- HEP detector overview
 - what we have and
 - why we need to do better
- Radiation damage in semiconductor sensors
- **Characterisation techniques**
 - **lab-based**
 - with beams
- Clever ideas confronting radiation damage



Basic sensor tests

CV and IV measurements

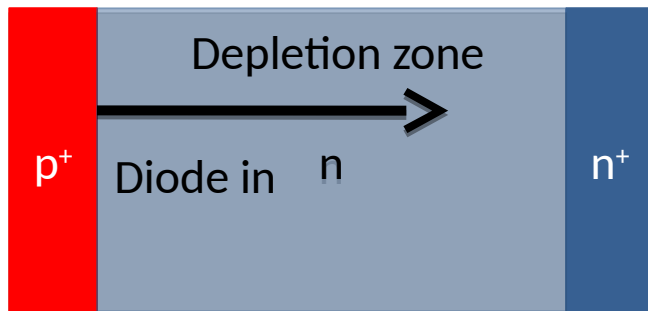
- Use a probe station
- IV (back → front) shows current characteristic:
reverse current, depletion current/voltage, breakdown, ...



CV and IV measurements

- Use a probe station
- IV (back → front) shows current characteristic:
reverse current, depletion current/voltage, breakdown, ...

Basic pn-junction properties

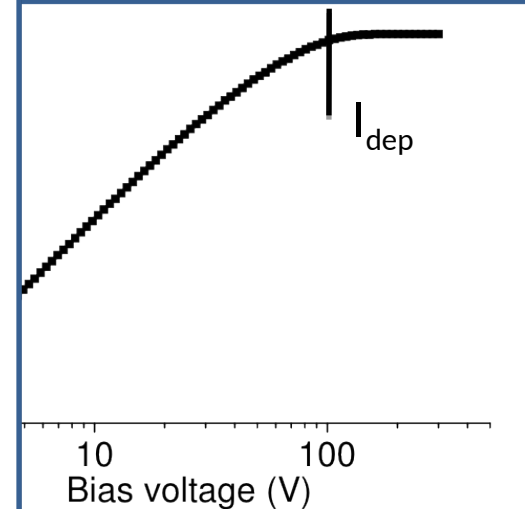


reverse-bias reveals

- I_{dep}
- $V_{dep} (\propto N_{eff})$
- C_{end} (detector thickness)

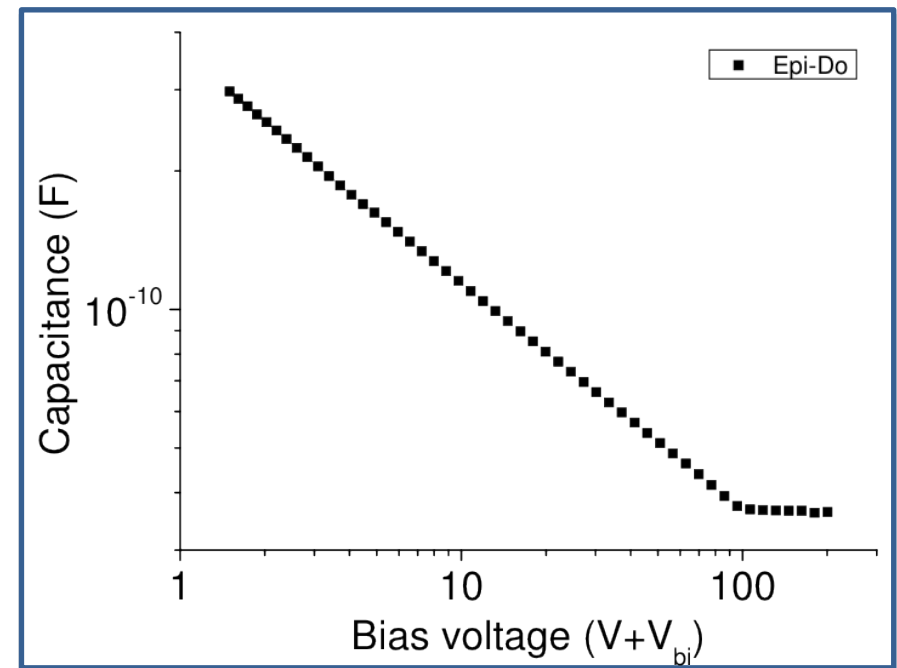
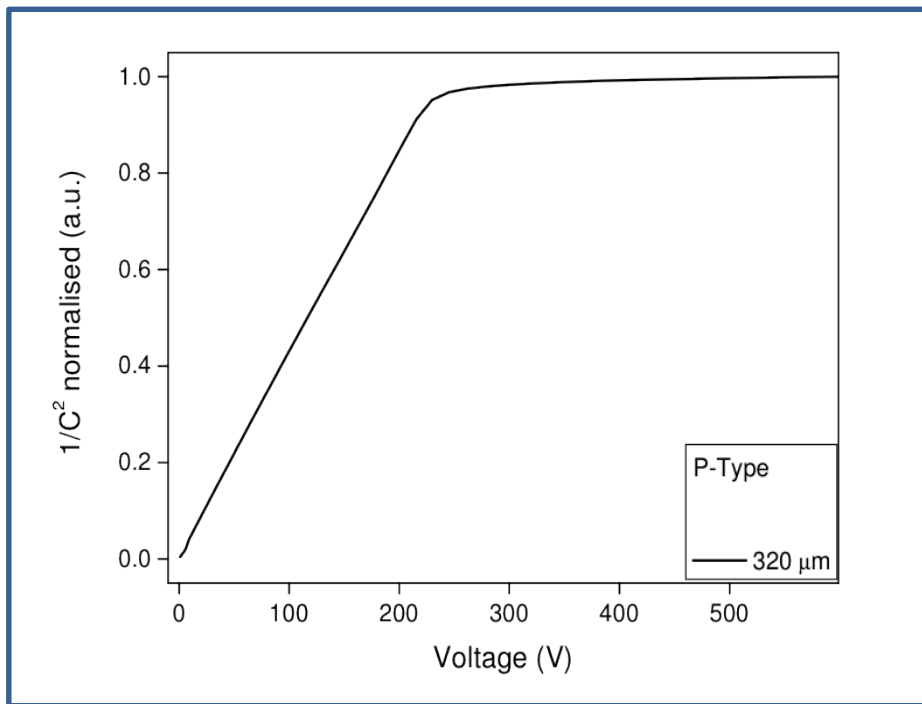
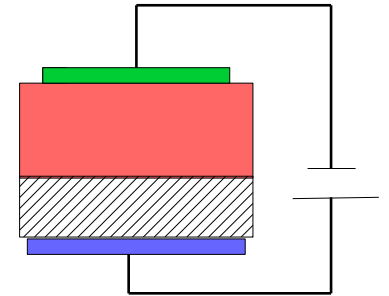
$$V_{dep} = \frac{q_0}{\epsilon\epsilon_0} \cdot |N_{eff}| \cdot d^2$$

Ideal IV curve



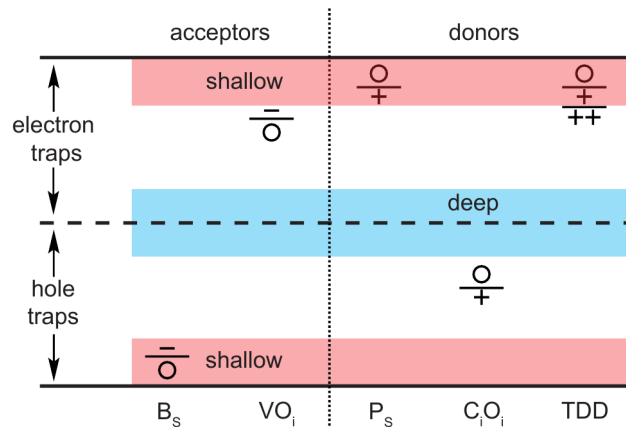
CV and IV measurements

- Use a probe station
- IV (back → front) shows current characteristics
- C vs V or $1/C^2$ vs $1/V$ reveals full depletion voltage and detector capacitance

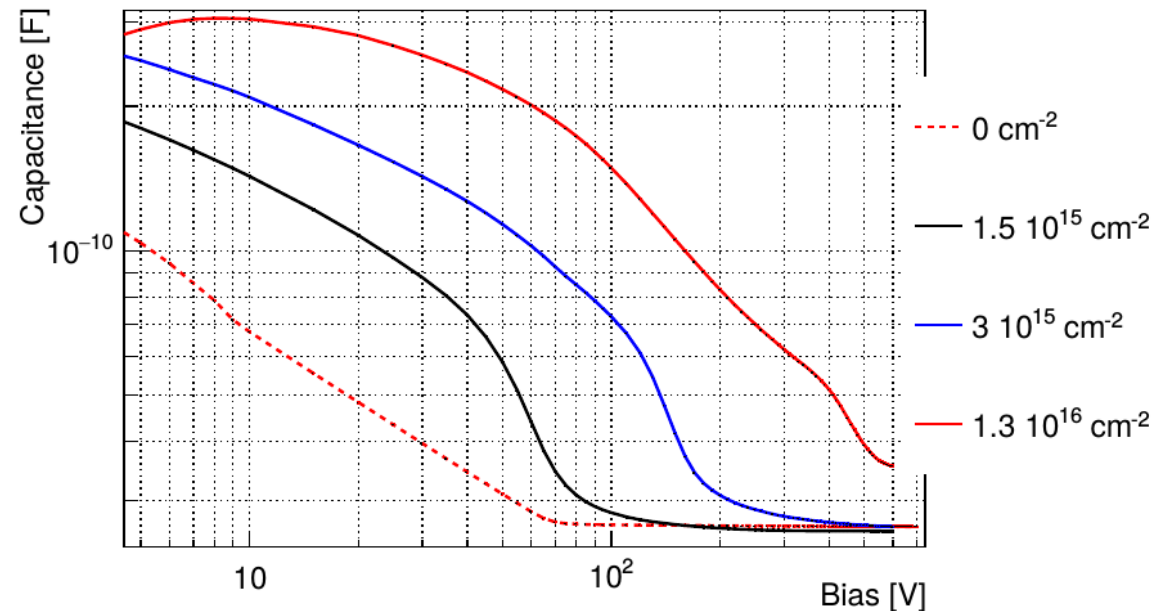


CV and IV measurements

- What happens with irradiation?

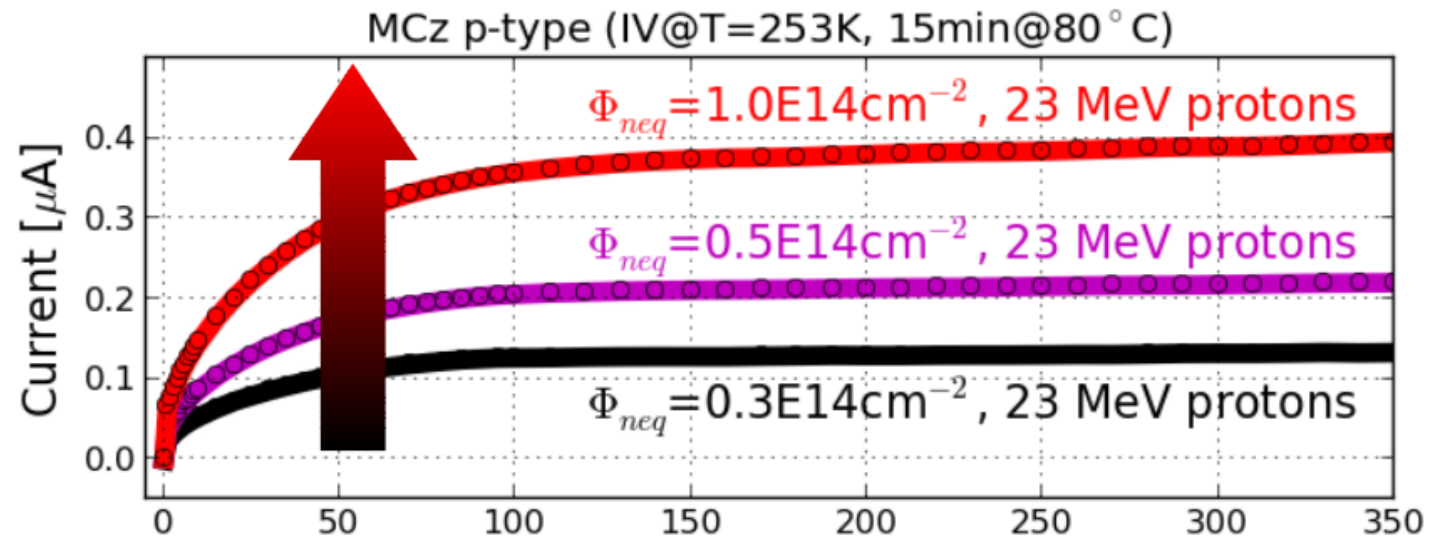
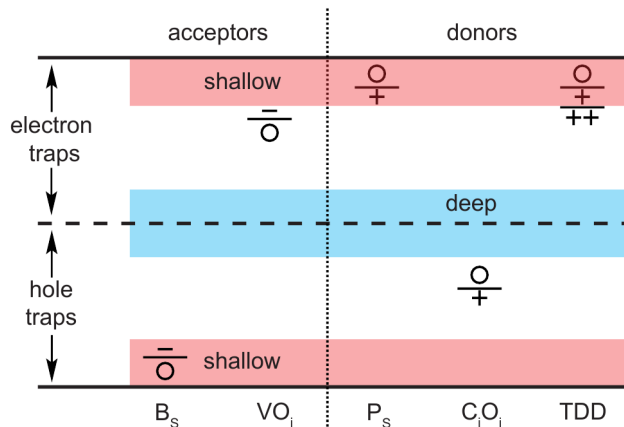


Matteo Centis, Thesis UHH



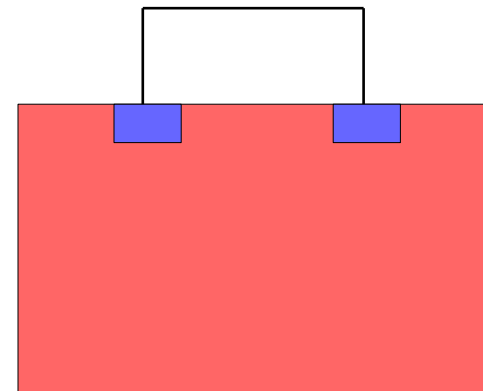
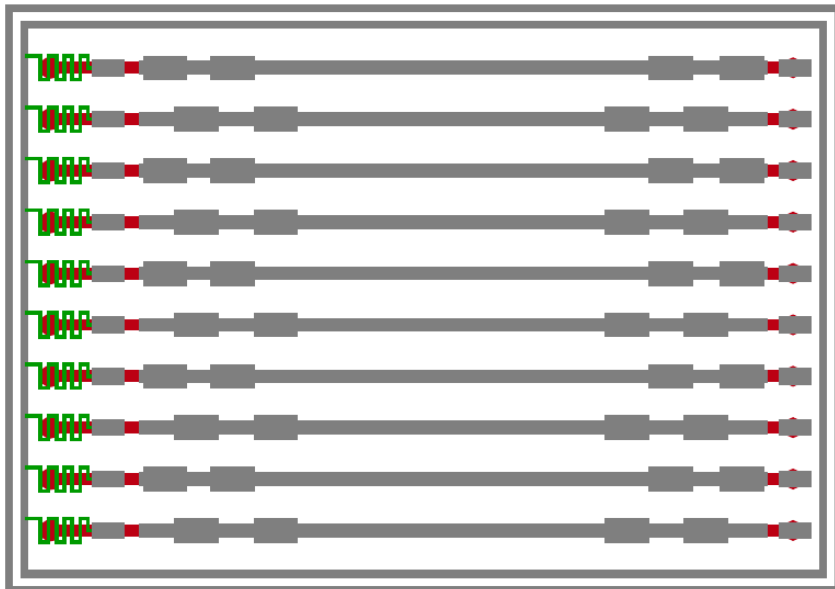
CV and IV measurements

- What happens with irradiation?



CV and IV measurements

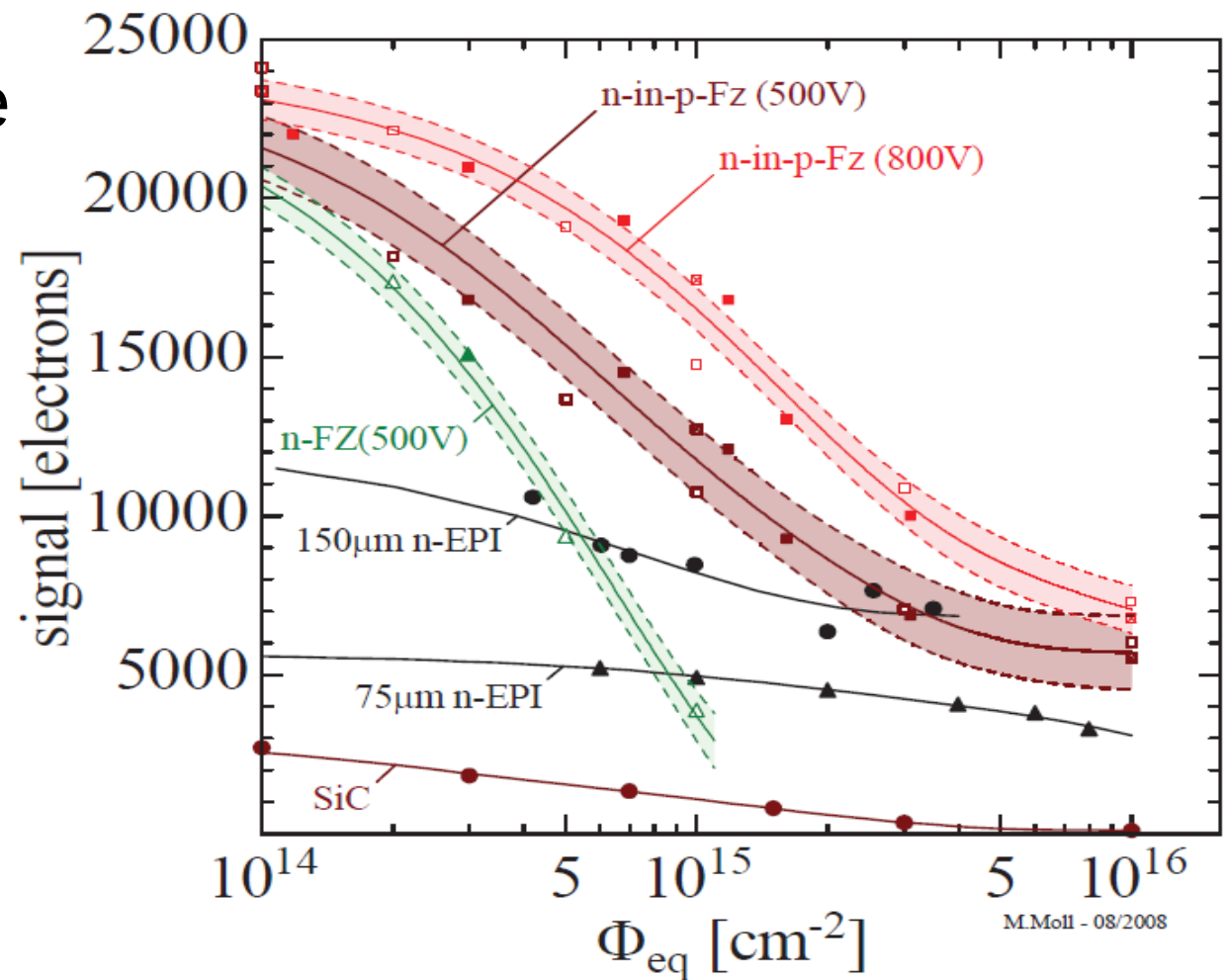
- Use a probe station
- IV (back → front) show current characteristic
- C vs V or $1/C^2$ vs $1/V$ reveals full depletion voltage
- IV (bias-ring → strip): poly-silicon resistor
- IV, CV (strip → strip): inter-strip resistance/capacitance



TSC measurements

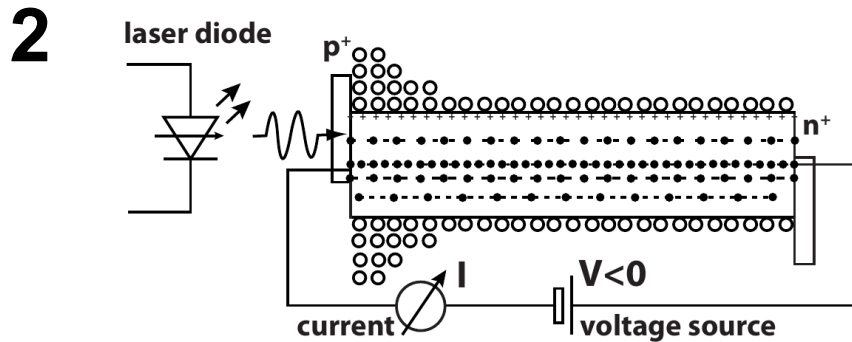
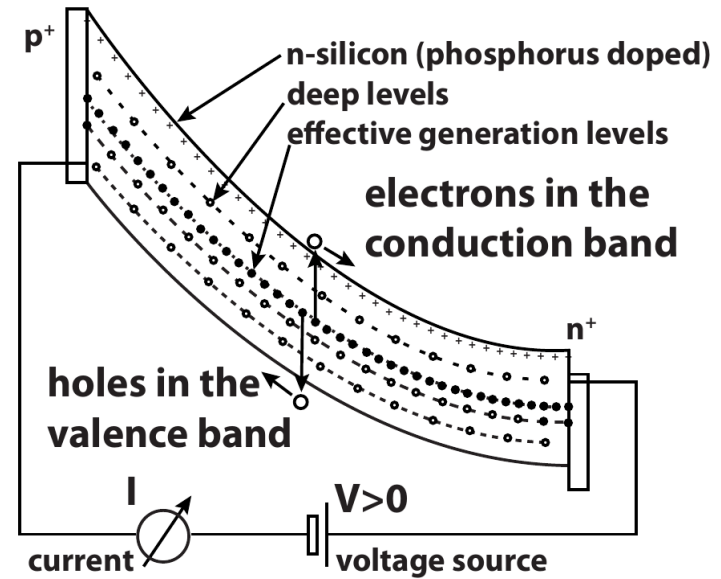
Why material studies?

- Signal degradation depends on
 - thickness
 - operation voltage
 - fluence
 - material

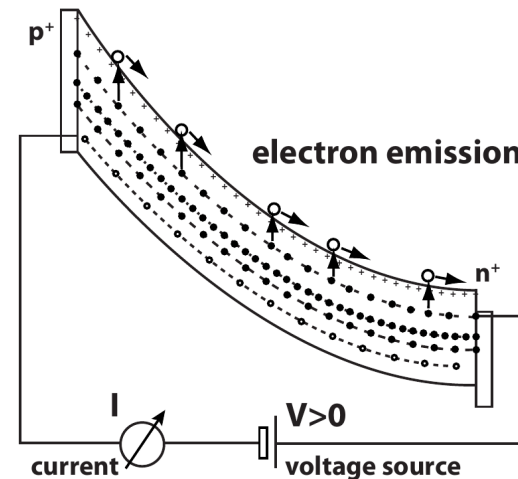


Thermally stimulated current technique

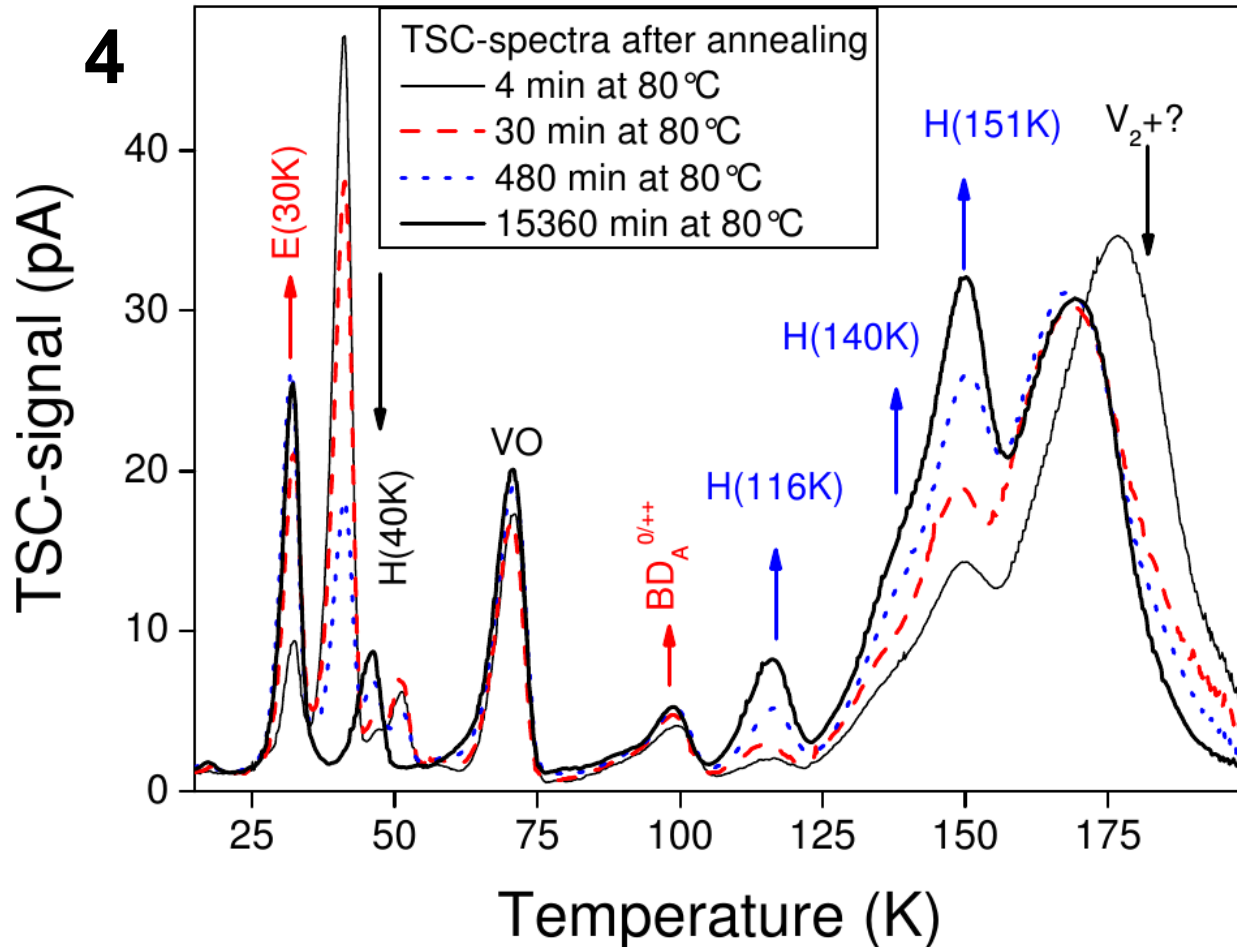
- Principle:
 - 1) Cooling **1**
 - 2) Filling of traps (**once** per cycle)
 - 3) Heating + recording current
 - 4) Data analysis



3



The analysis



- Energy from rising edge
- N_t from area
- σ from fit to peak

Defect spectroscopy:

Calculate concentration, energy, and cross-section from TSC-signal:

- shallow traps towards low T
- deep traps towards high T

Annealing at 80 C:

- Simulate shut-down time in short period.
- what happens electrically

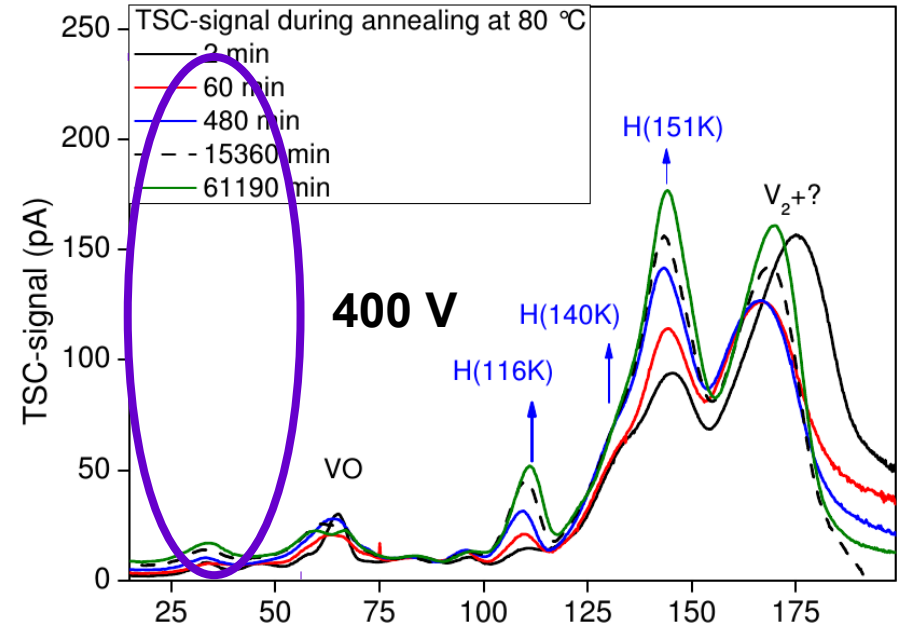
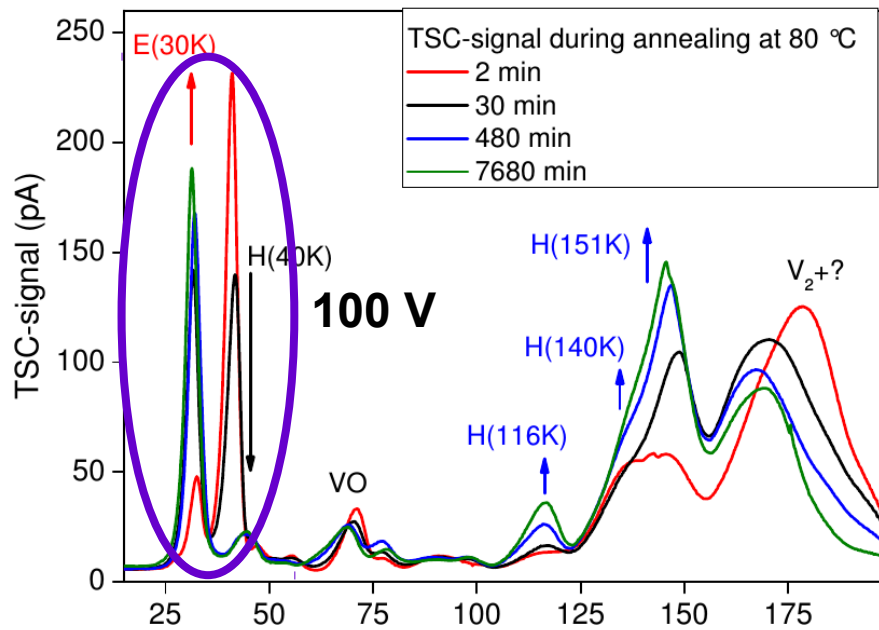
Annealing at 200 C:

- Affects also the crystal structure itself: Migration of silicon atoms from e.g. interstitials to vacancies
- Defect identification

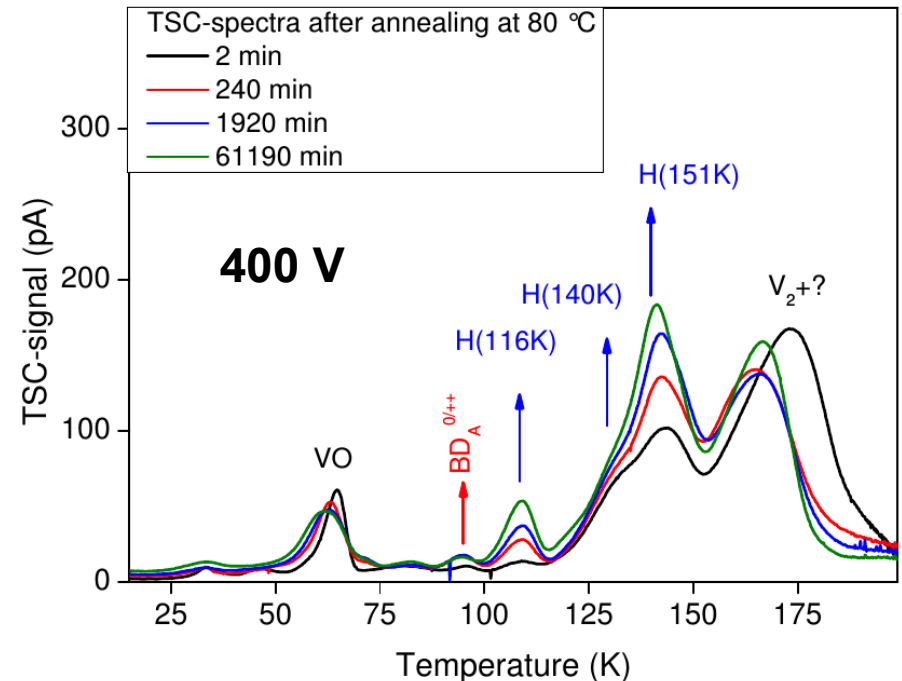
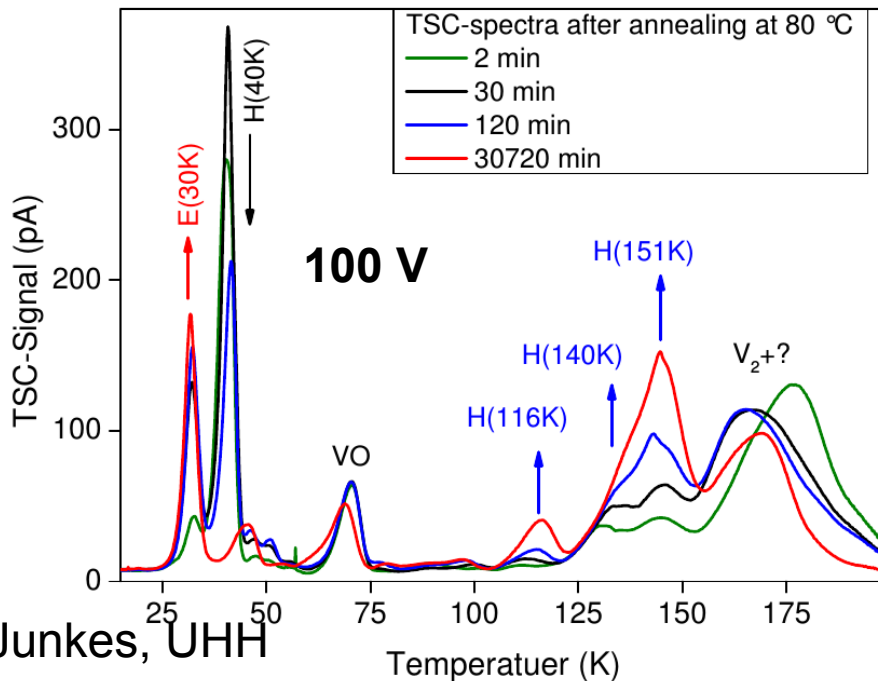
Comparison

@ 1e15 n

**Epi-
standard**



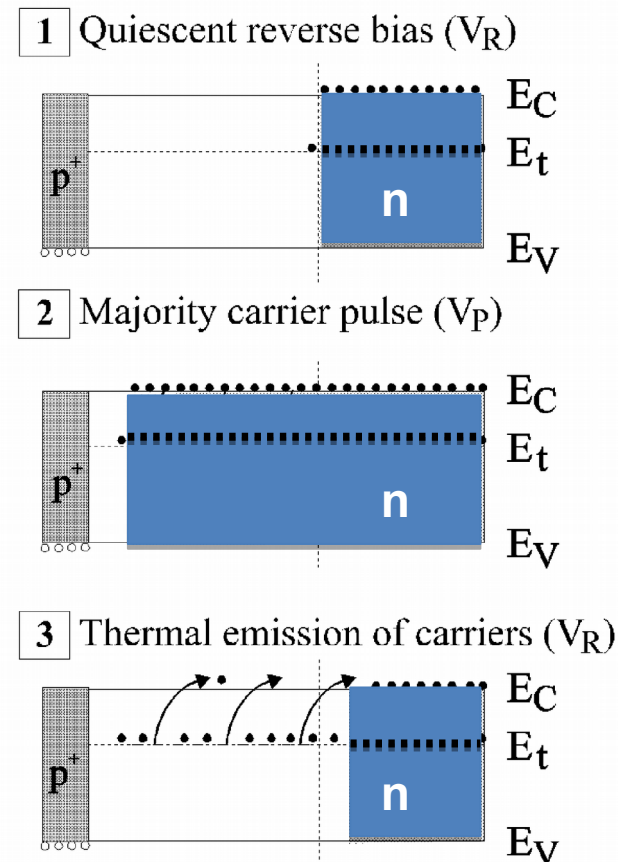
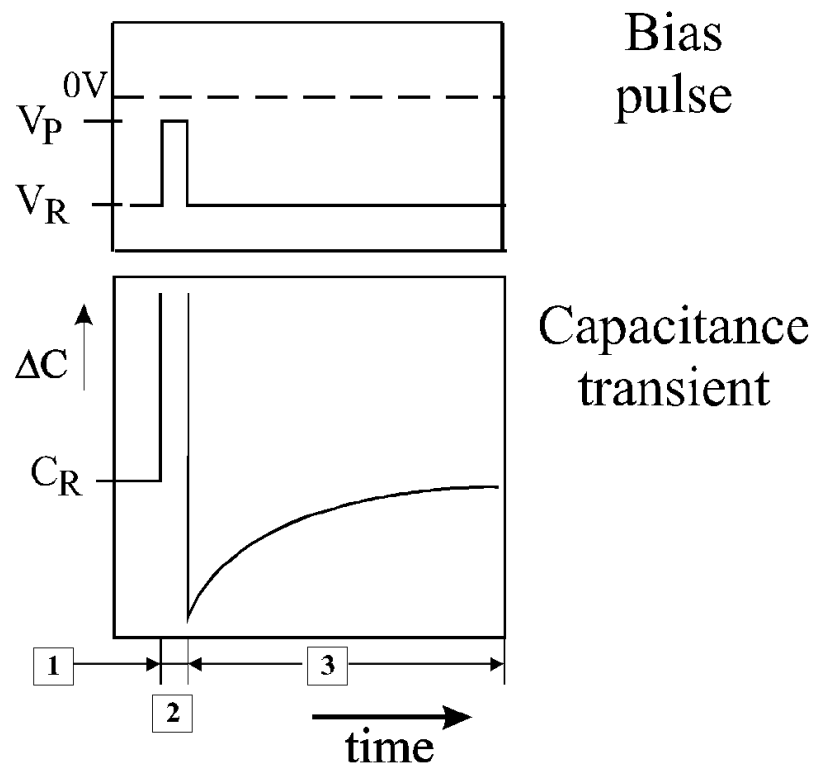
**Epi-
oxygen
enriched**



DLTS measurements

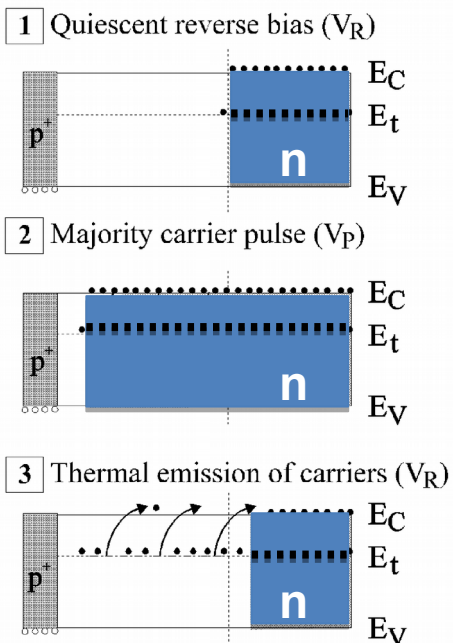
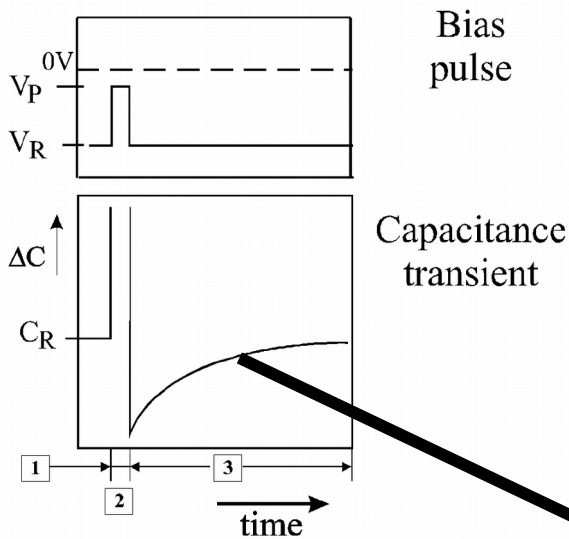
Deep Level Transient Spectroscopy

- Principle:
 1. Diode under reverse-bias
 2. Filling of traps with charge carriers at various T
 3. Emission from filled traps → change of capacitance



Deep Level Transient Spectroscopy

- Principle:



- Multi-shot technique

→ Traps filled for each T!

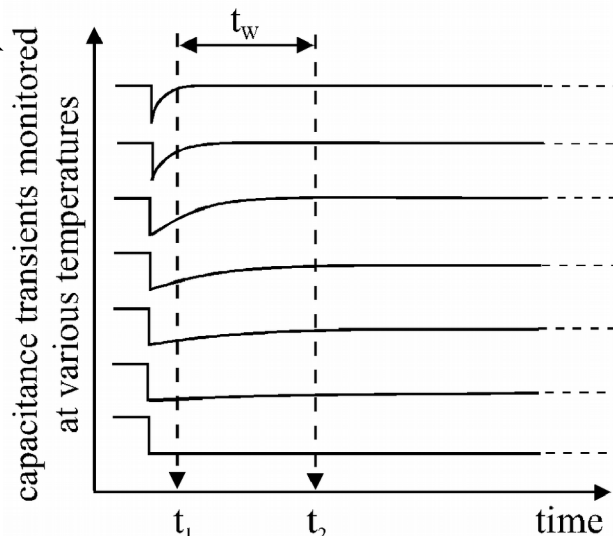
– Capacitance transient recorded a.f.o. t , T

– Transient follows: $\Delta C(t, T) = \Delta C_0 \exp(-e_n(T) \cdot t)$

– Emission time constant from shape

– Concentration:

$$N_t \approx 2N_D \frac{\Delta C}{C_0}$$

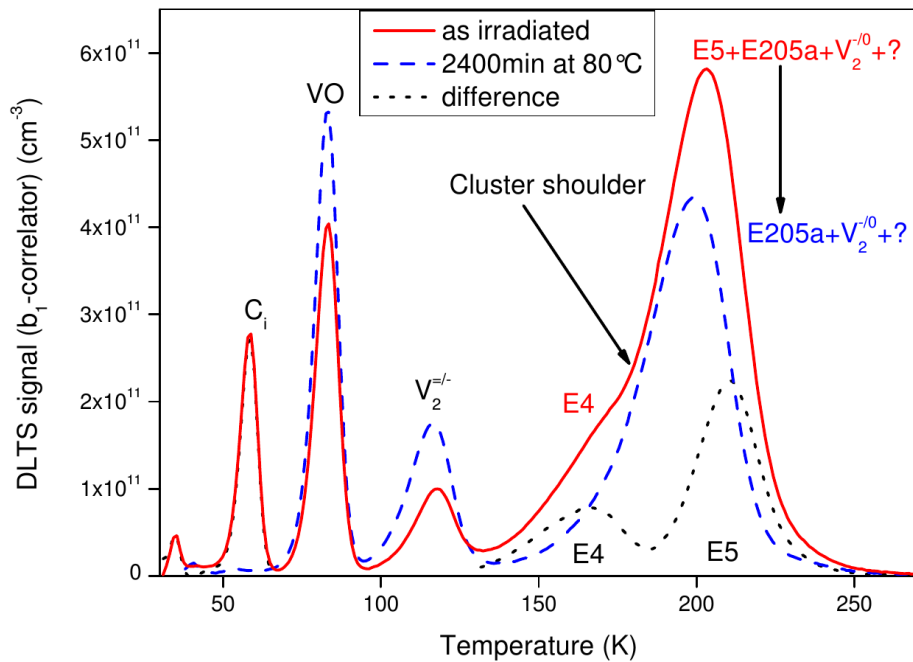


$$\tau_{trapping} = \frac{1}{\sigma v_{th} N}$$

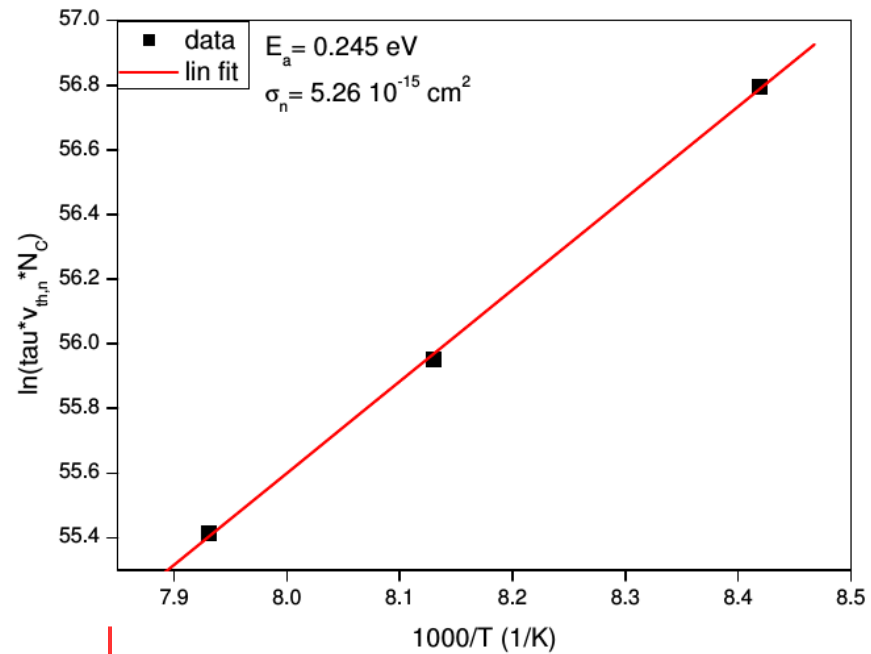
$$\tau_{detrap} = \frac{1}{\sigma v_{th} N} * \exp(E_a/k_B T)$$

Analysis

- From ΔC vs T:



- From transient:



$$e_{n,p} = \sigma_{n,p} v_{th,n,p} N_{C,V} \exp\left(-\frac{\Delta E_a}{k_B T}\right)$$

\uparrow from fit \uparrow \uparrow from literature \uparrow from measurement

$$v_{th,n,p} = \sqrt{\frac{3k_B T}{m_{n,p}^*}}$$

$$\frac{e}{v N_C} \equiv \frac{1}{\tau v N_C} = \sigma \exp(-E_a/kT)$$

$$\tau v N_C = \frac{1}{\sigma \exp(-E_a/kT)}$$

$$\ln(\dots) = -\ln(\sigma) + \frac{E_a}{kT}$$

Intermediate summary

- Understanding microscopic details helps understand macroscopic measurements:
 - IV after irradiation
 - **more current** → more mid-gap traps
 - CV after irradiation
 - Different V_{dep} → N_{eff} has changed
 - Compare TSC and DLTS spectra before/after irradiation
 - Identify new defects:
 - Energy level
 - Density a.f.o fluence
 - Cross section

Current measurements

The Transient-Current Technique

- Measuring drifting charges:

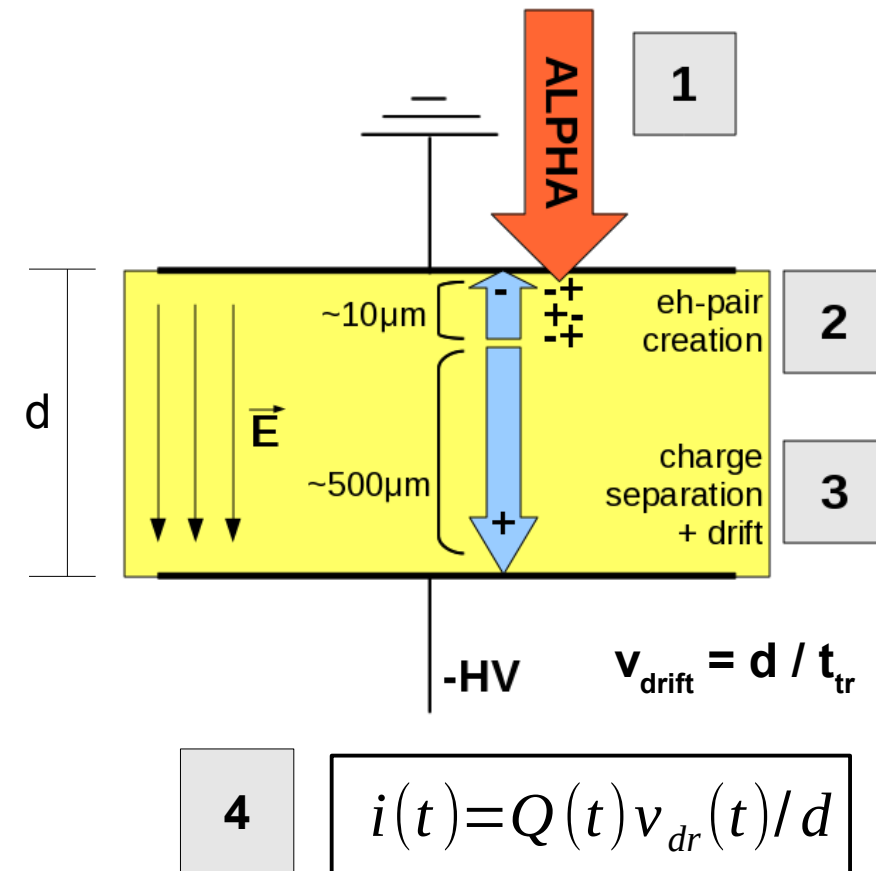
- 1) α particles impinge on top side
- 2) Create eh-pairs **close** to electrode
- 3) Electric field separates charges
- 4) Drifting charges induce current

→ measure the **transient current**

→ **Pos.** (**neg.**) bias → Measure **e⁻** (**h⁺**)

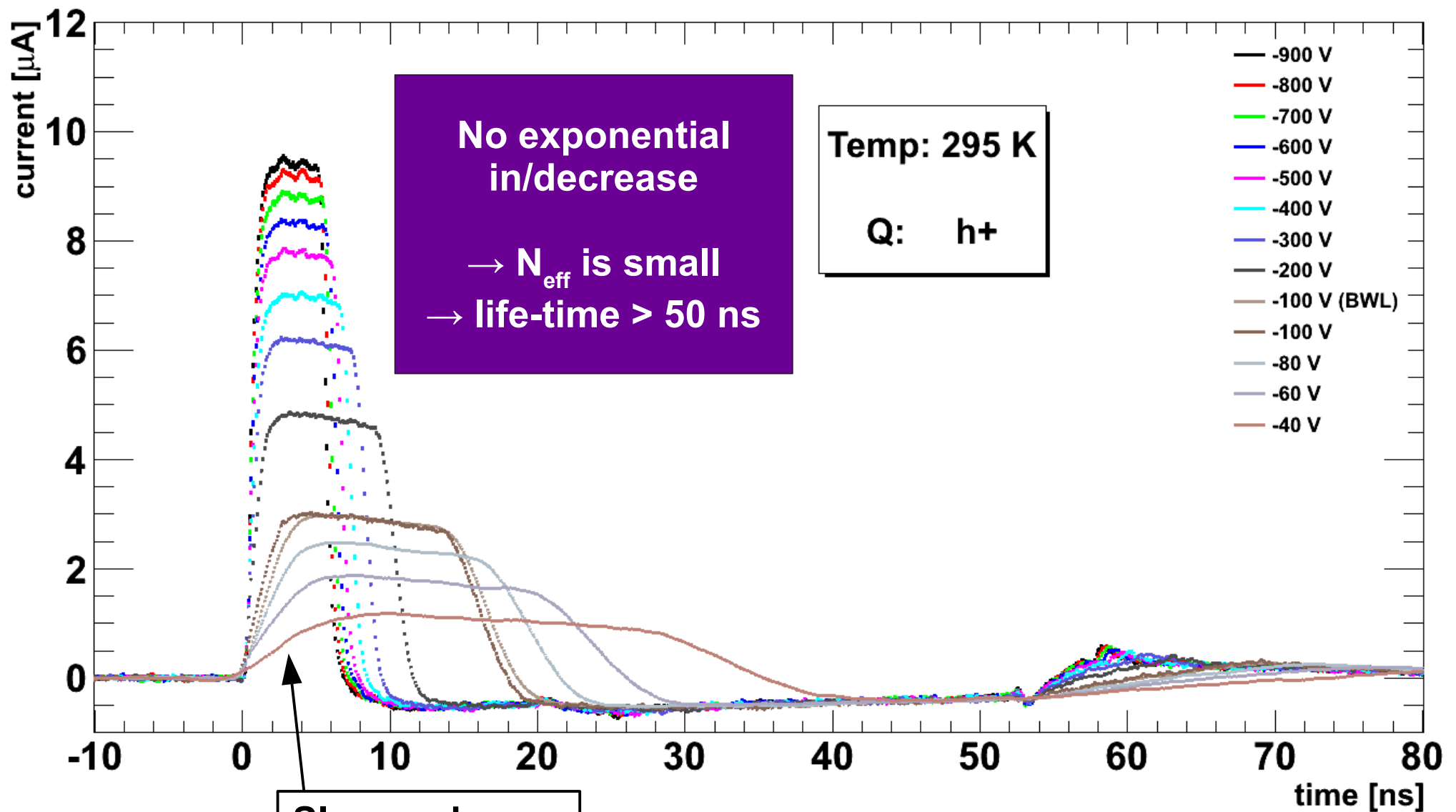
→ Use fast (2 GHz), low noise (3 mV) current amplifier, 40 dB

→ record signal with oscilloscope

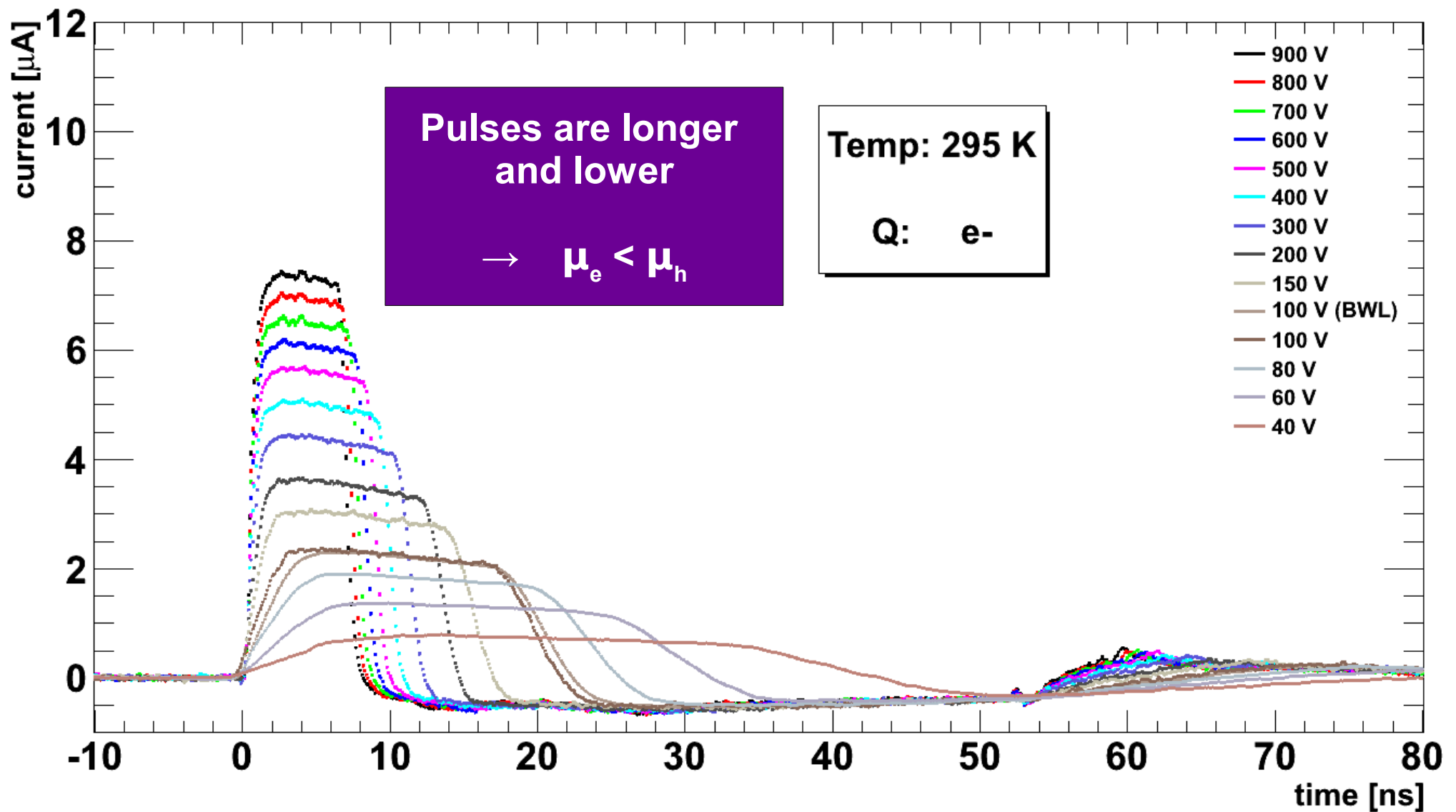


e.g. in diamond

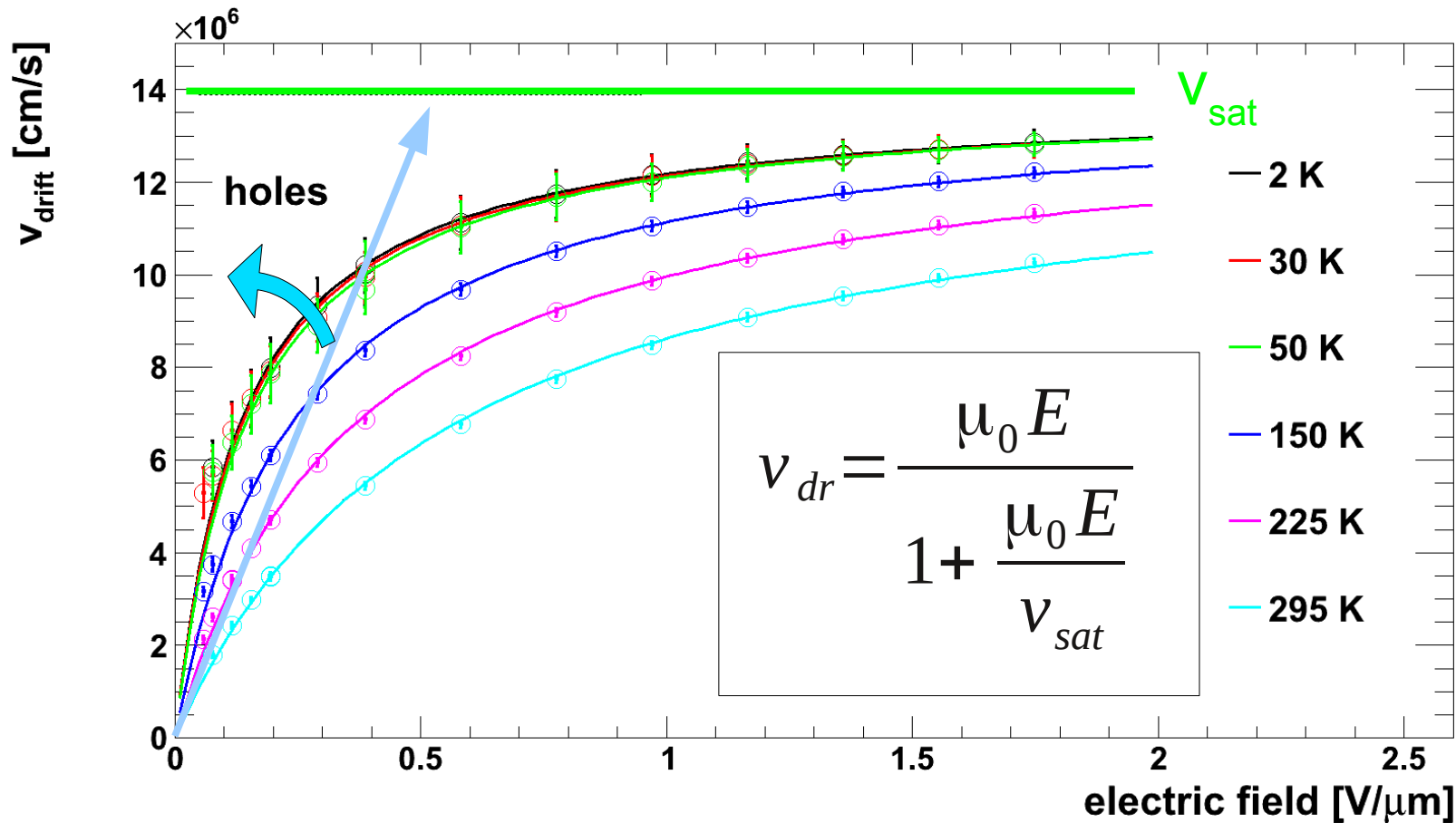
TCT Pulses at RT: Holes



TCT Pulses at RT: Electrons



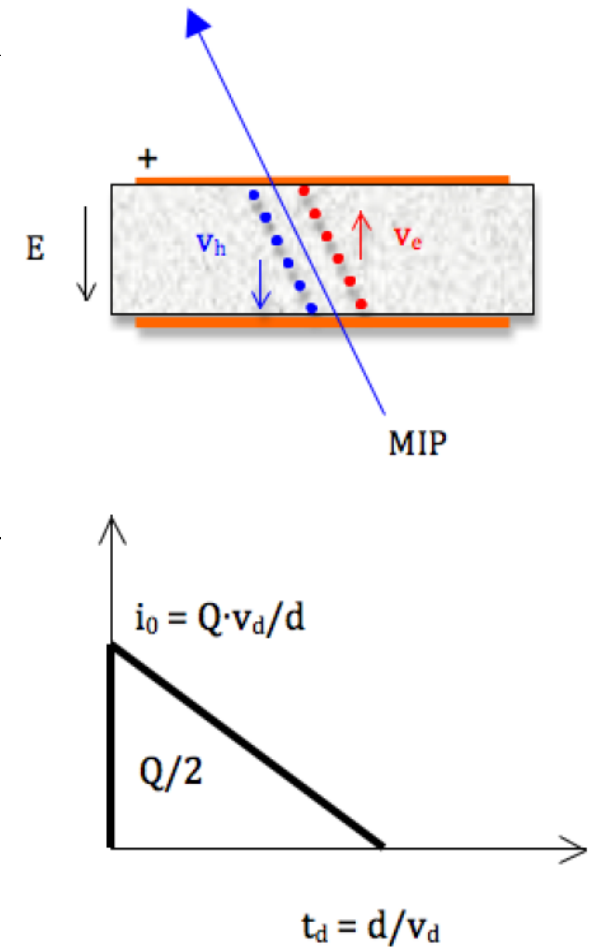
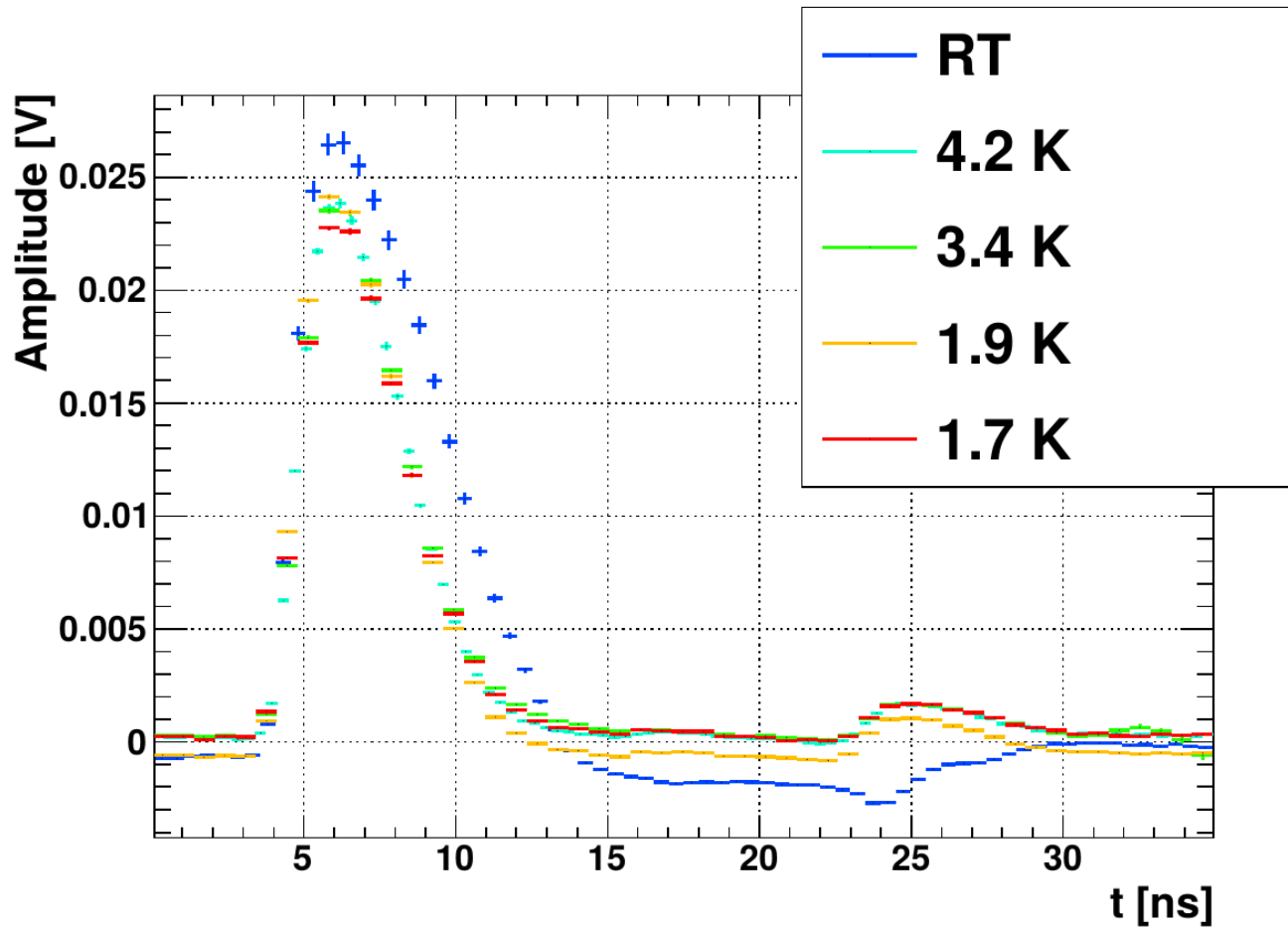
Hole Drift Velocity



- μ_h increases with decreasing T down to 2 K
- $v_{sat} \sim$ constant with temperature: $14e6$ cm/s

TCT pulses from MIPs in silicon

- Current pulses for different temps:

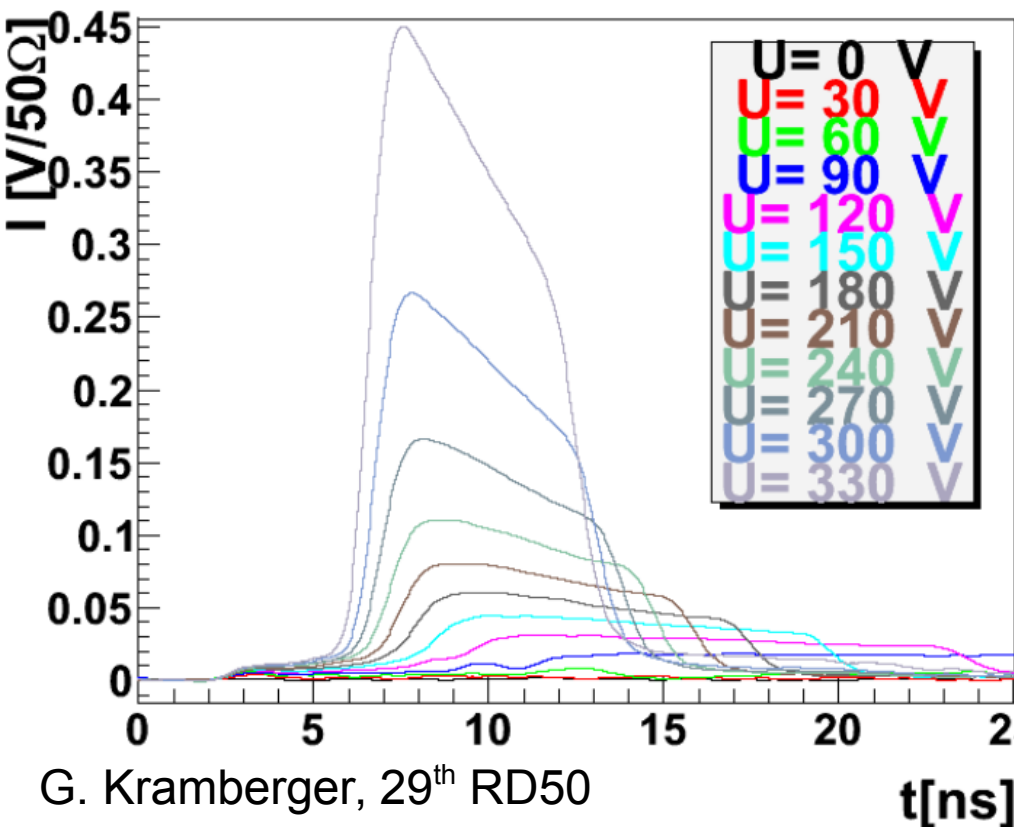


C. Kurfuerst
CERN-THESIS-2013-232

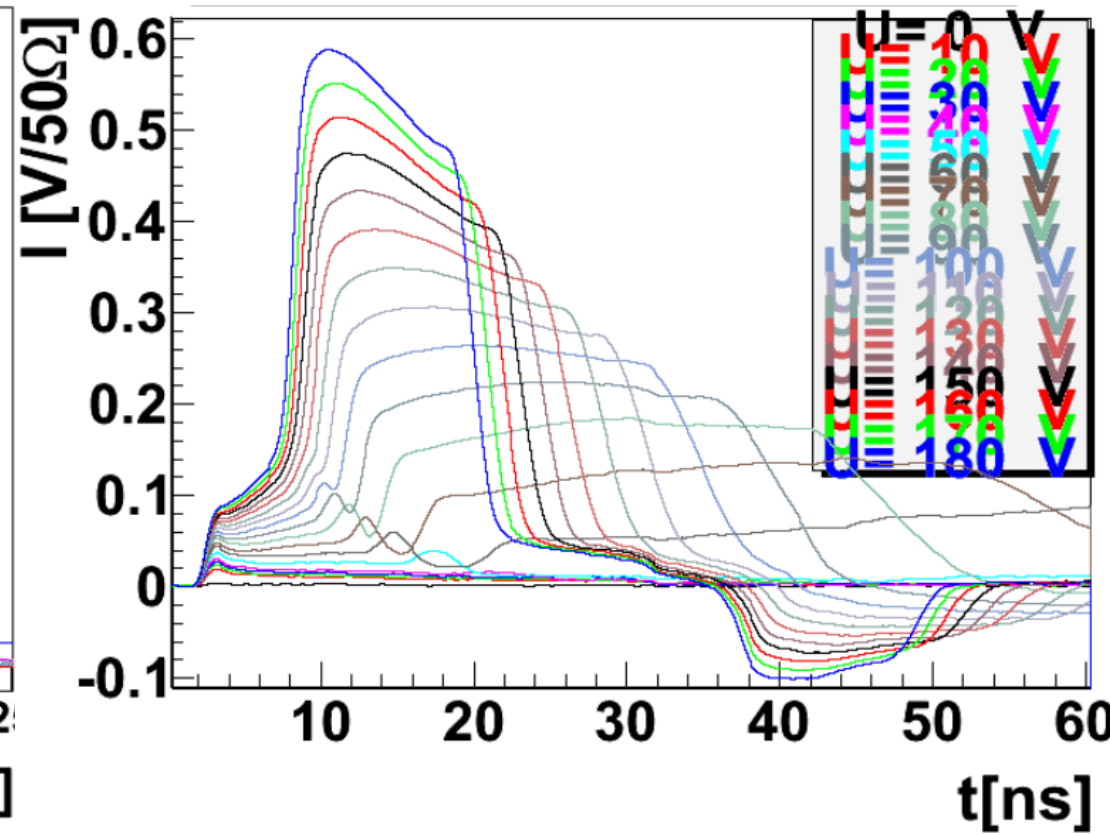
TCT and irradiation

- Very sensitive to changes during drift:
 - Number of charges (trapping, amplification)
 - Velocity of charges (electric field, mobility)

un-irradiated



irradiated



Intermediate summery

- TCT measures the current induced by drifting charges
 - With irradiation, the shape of the signal changes:
 - N_{eff} → slope during drift
 - Traps → decrease of current during drift
 - ...
- “See” effects that influence the drift of charge carriers
(does not mean you understand the microscopic details)

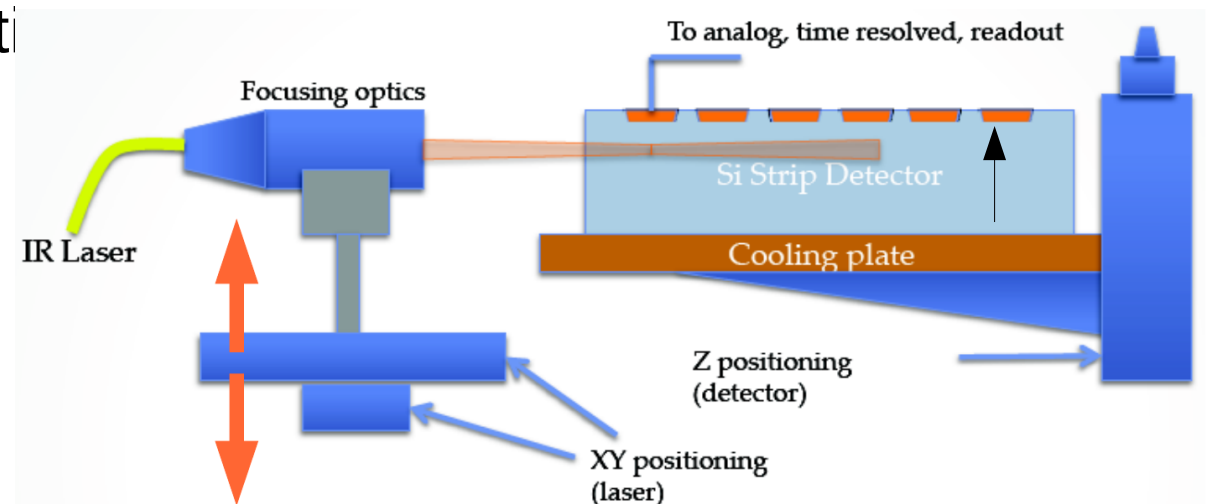
edge-TCT measurements

Edge-TCT

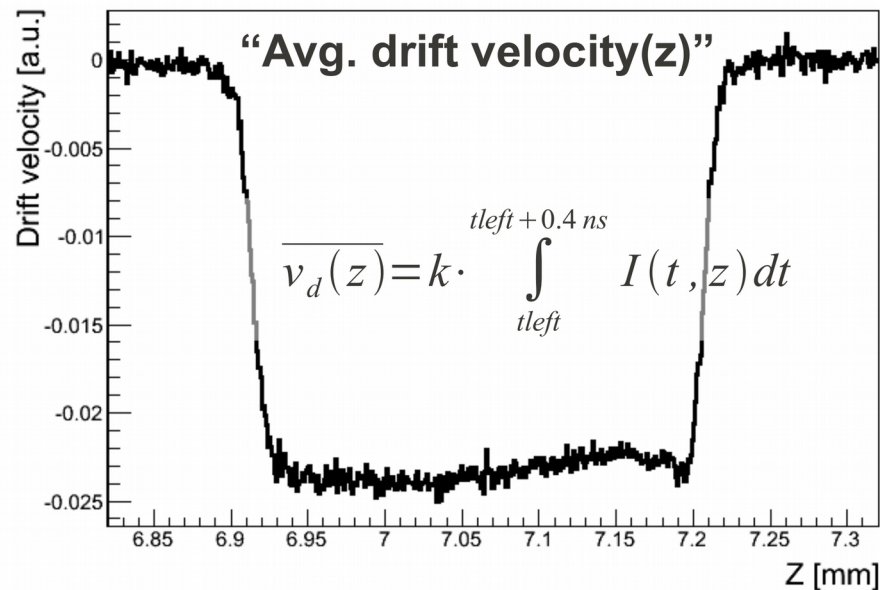
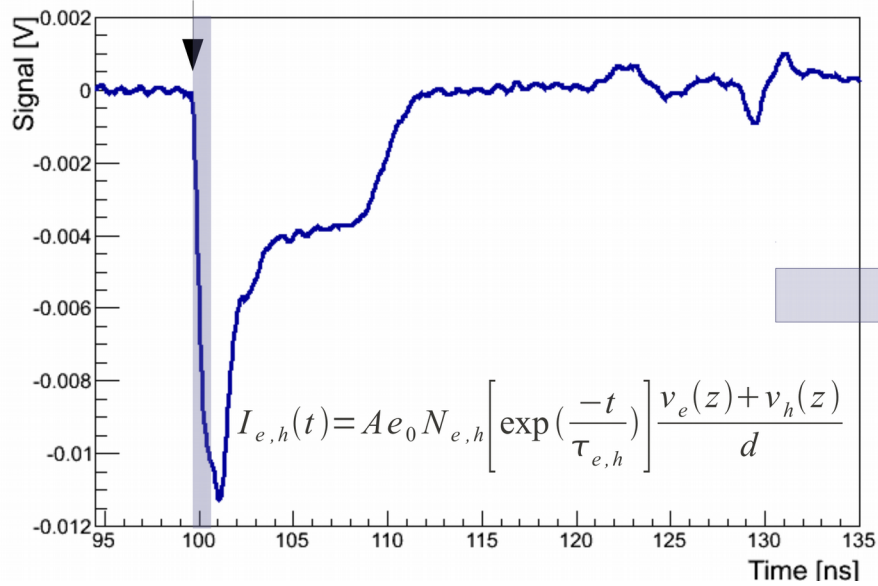
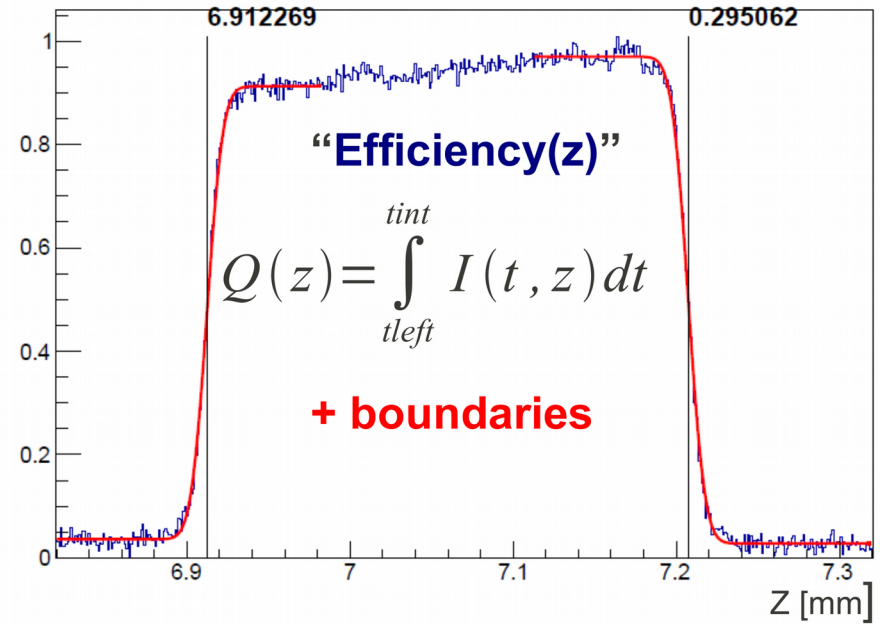
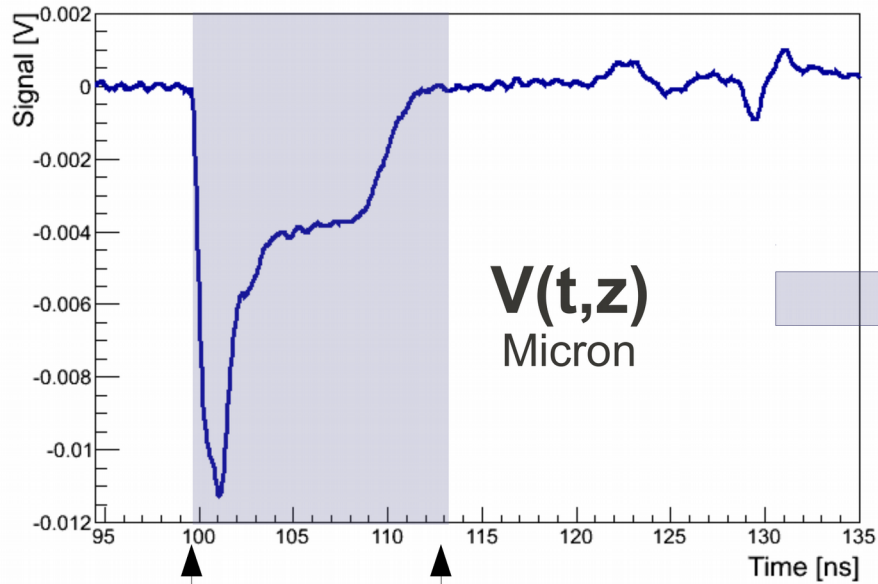
- Shoot with laser from the side
- Charge carriers created at selected depth with respect to strips
- Sensor properties can be studied as a function of depth
- Spatial resolution given by laser width (vertical). Measurements averaged over strip width.

- Measure current a.f.o. t

- Charge profile
- Velocity profile
- **Calculate $E(z)$**

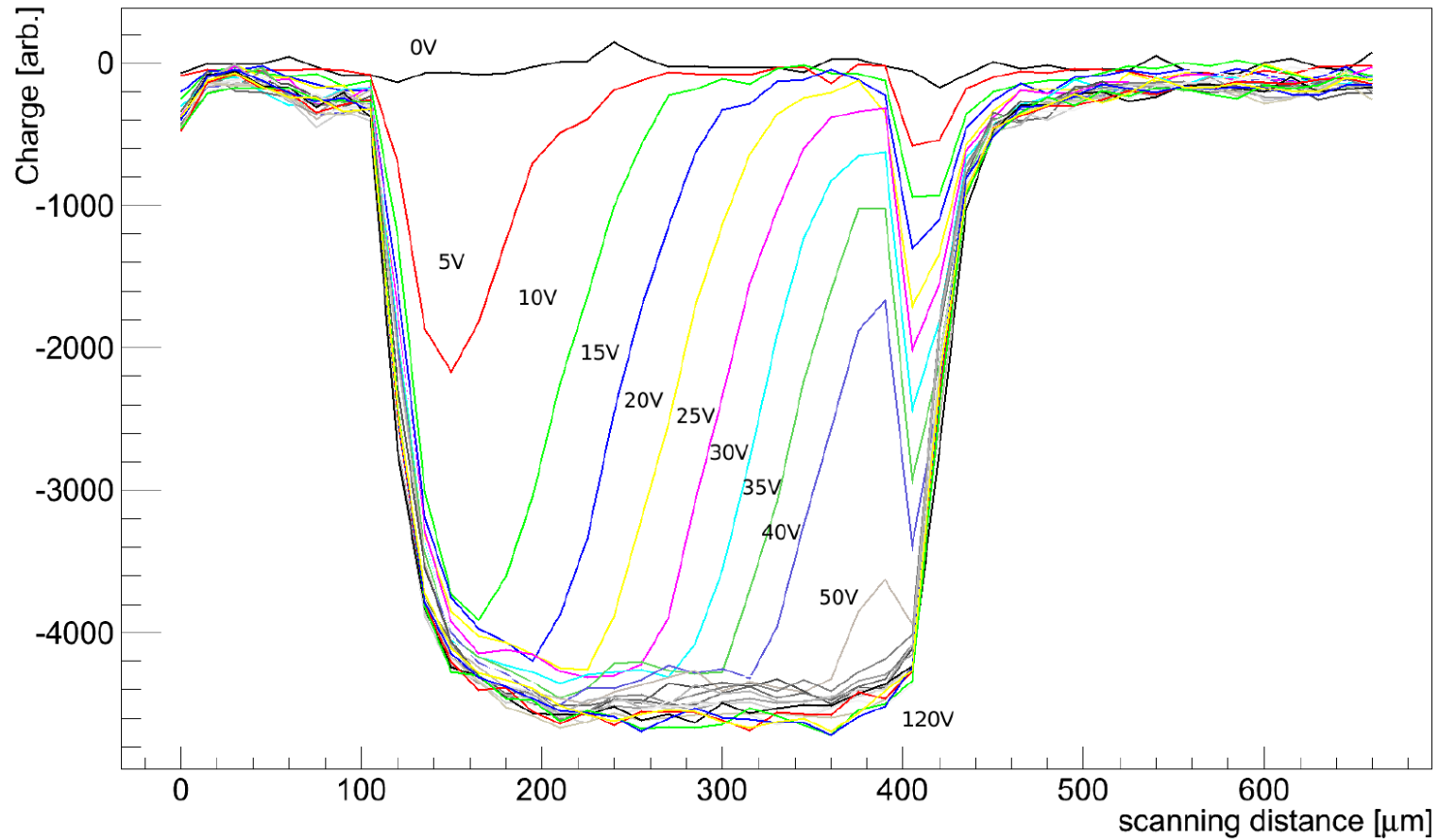


Procedure



Results

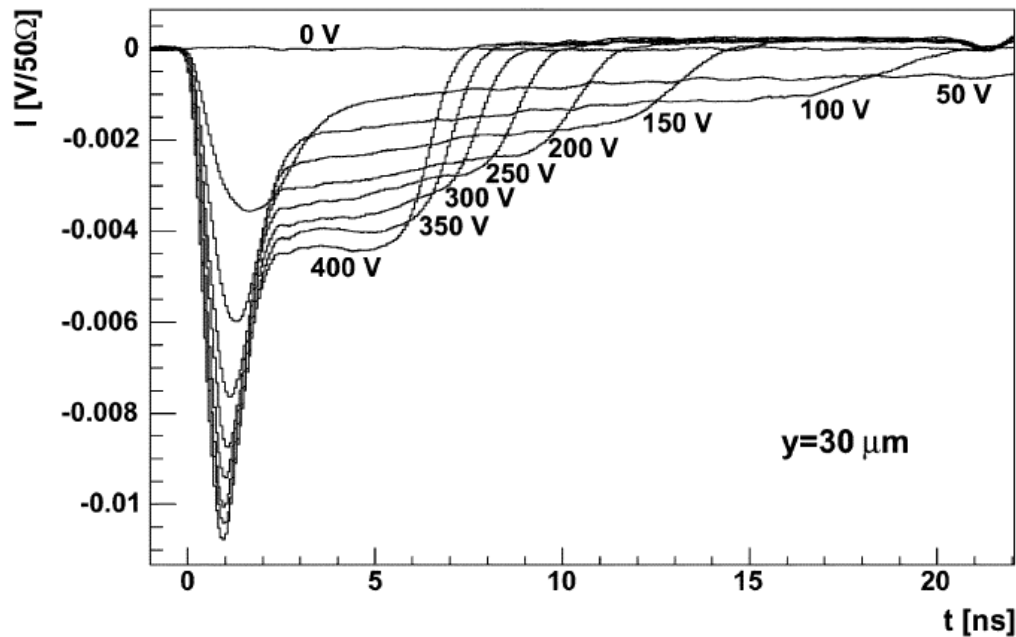
- Integrate current \rightarrow charge



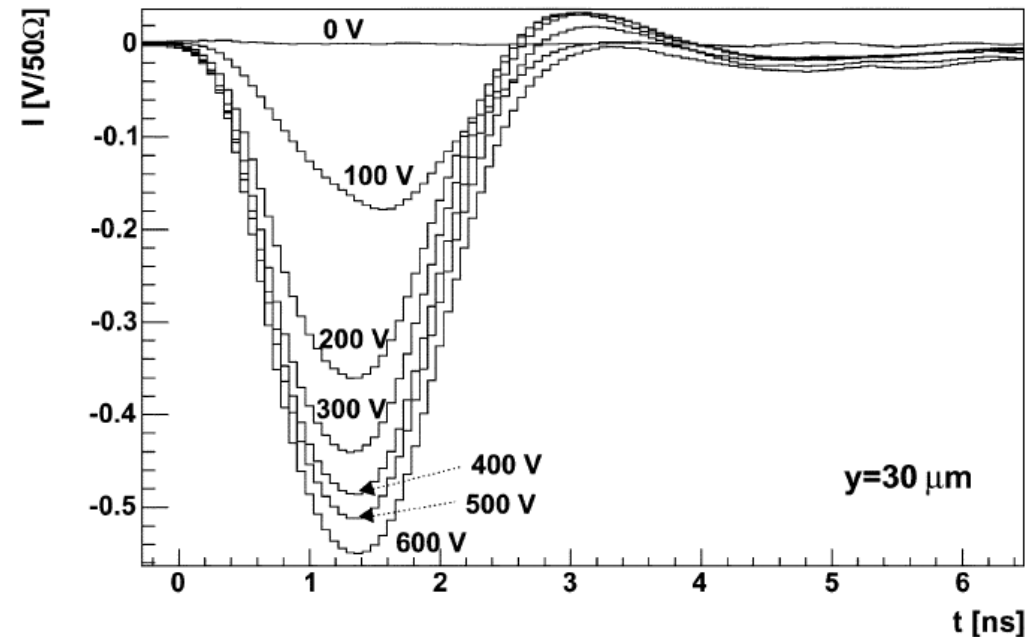
M. Haranko, former DESY summer student

Results for transient

- Comparison for un-irradiated sensor



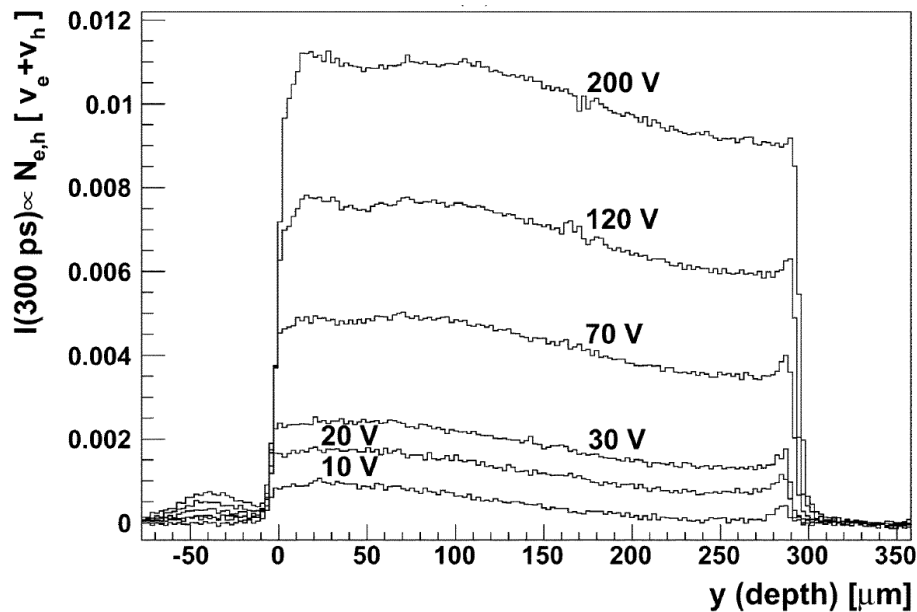
with irradiated sensor



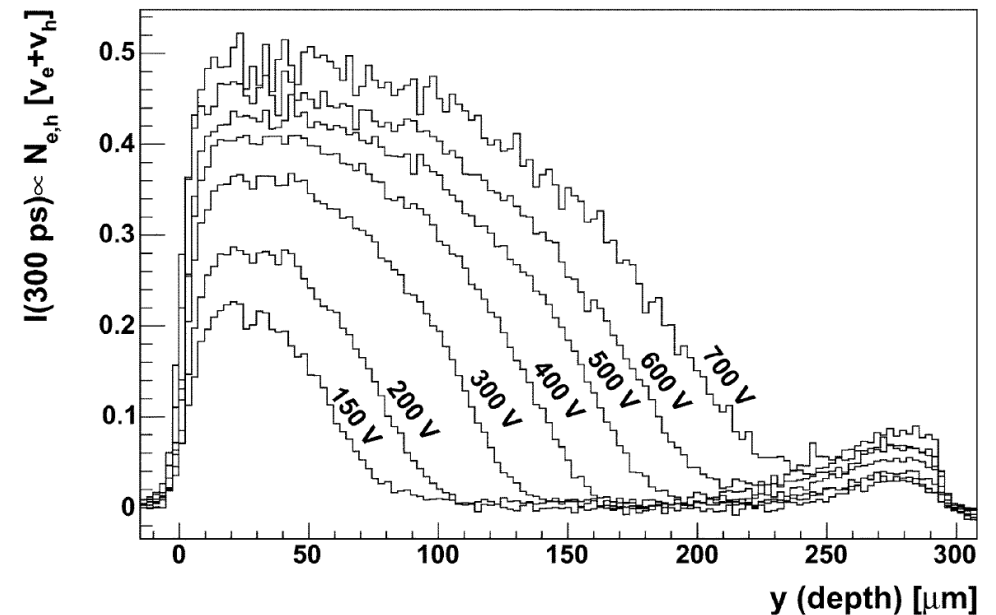
IEEE TRANSACTIONS ON NUCLEAR SCIENCE, VOL. 57, NO. 4, AUGUST 2010

Results for electric field

- Comparison for unirradiated sensor



- with irradiated sensor

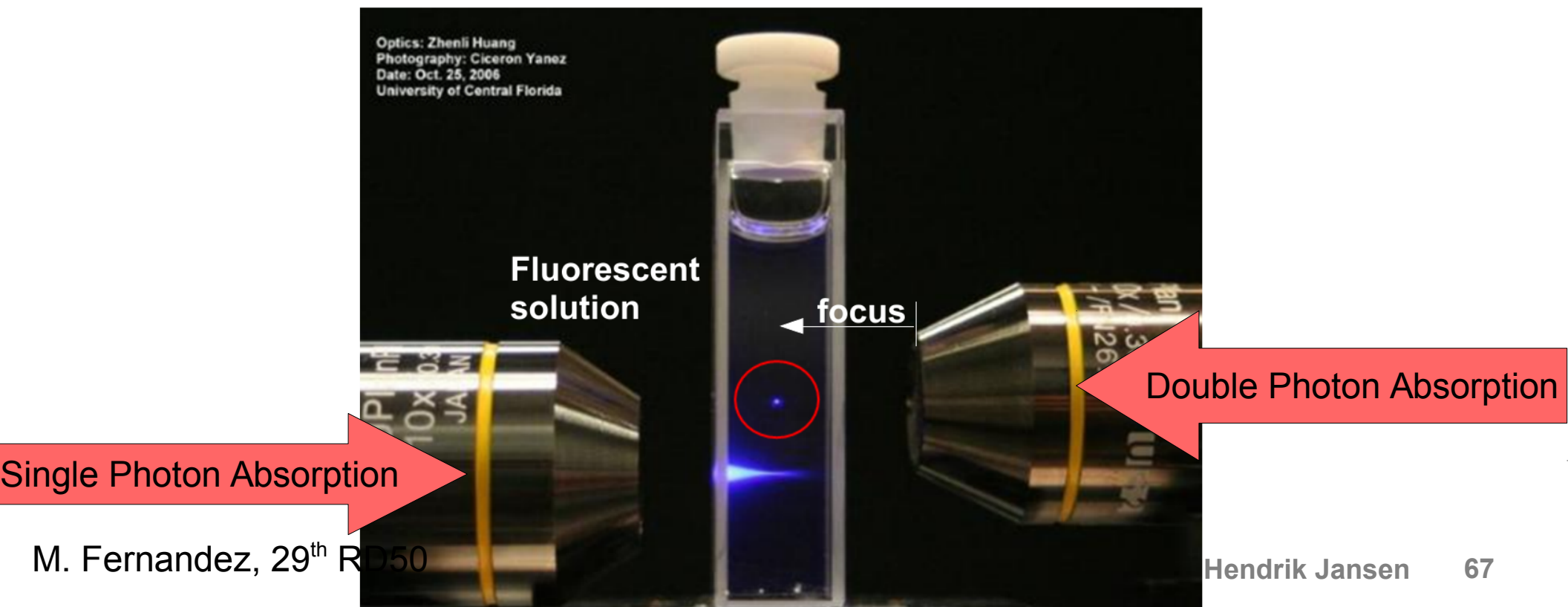


IEEE TRANSACTIONS ON NUCLEAR SCIENCE, VOL. 57, NO. 4, AUGUST 2010

DPA-TCT technique - improving edge TCT

Double Photon Absorption Technique

- Laser TCT: create charge along entire path
- DPA-TCT: well defined volume of carrier generation
 - exploits non-linear effect of absorption at high intensity
 - single photon energy is SMALLER than band-gap
 - happens only at/near the focus

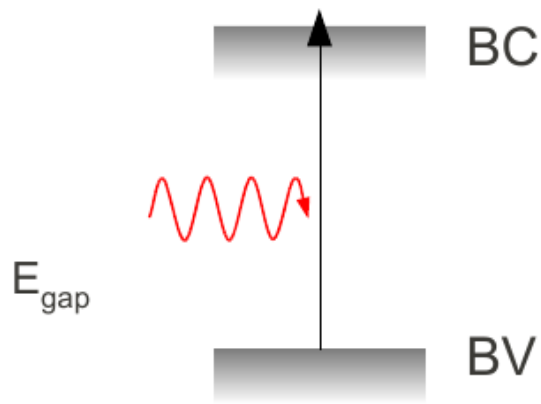


Double Photon Absorption Technique

- Laser TCT: create charge along entire path
- DPA-TCT: well defined volume of carrier generation
 - exploits non-linear effect of absorption at high intensity
 - single photon energy is **SMALLER** than band-gap
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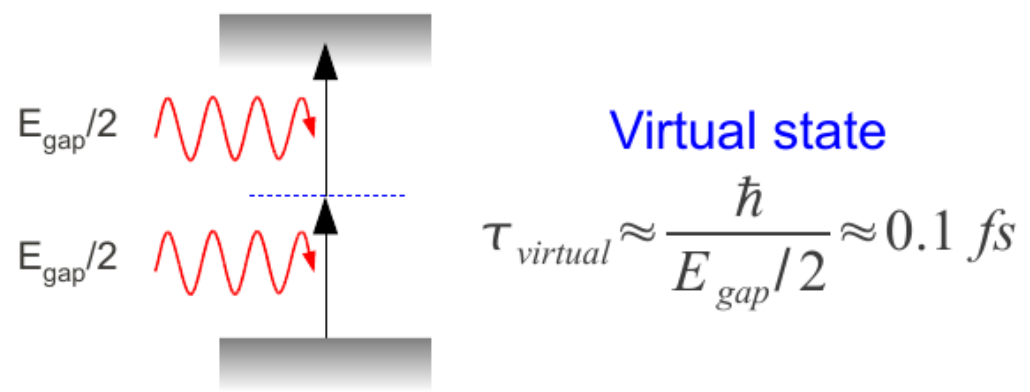
SPA

SPA: $E_{\text{photon}} \geq E_{\text{gap}} \sim 1.12 \text{ eV}$



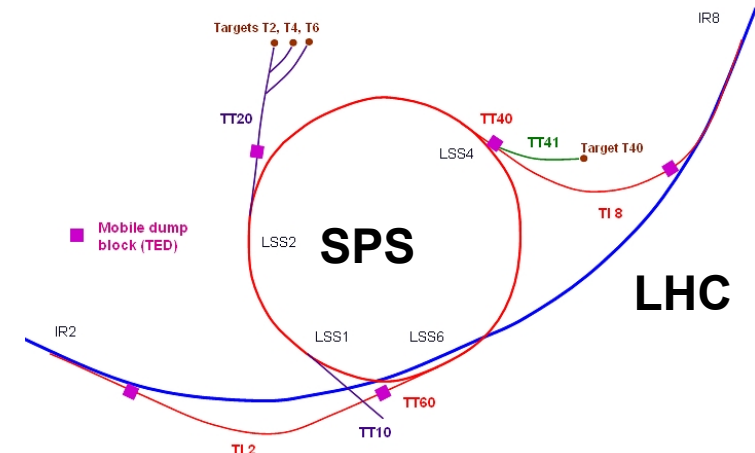
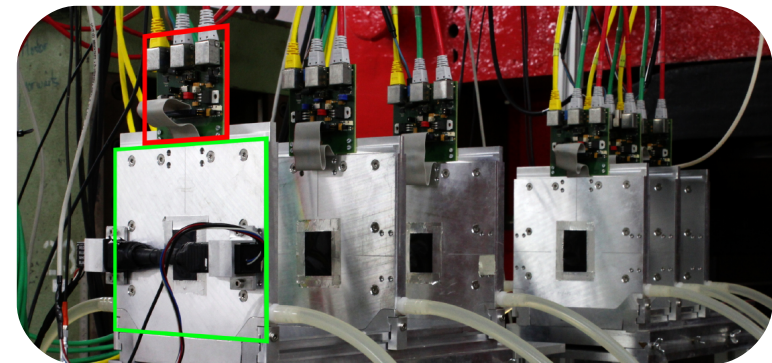
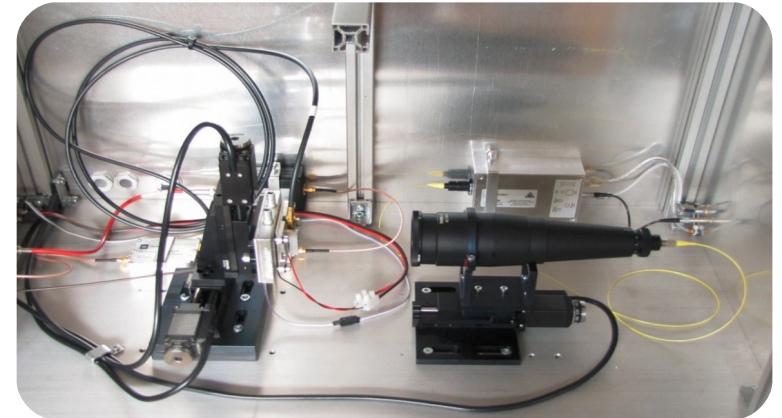
TPA

TPA: Conventionally, no excitation if $E_{\text{photon}} < E_{\text{gap}} \sim 1 \text{ eV}$. But, if **TWO** photons arrive in ~ 100 attoseconds:



Outline

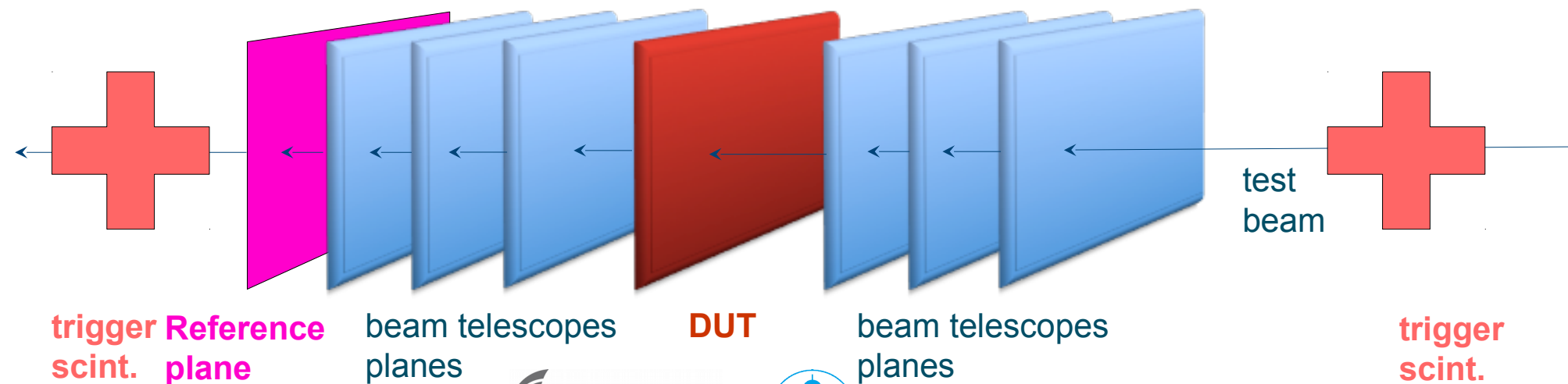
- HEP detector overview
 - what we have and
 - why we need to do better
- Radiation damage in semiconductor sensors
- **Characterisation techniques**
 - lab-based
 - **with beams**
- Clever ideas confronting radiation damage



Beam telescopes and test beams

Test beam studies

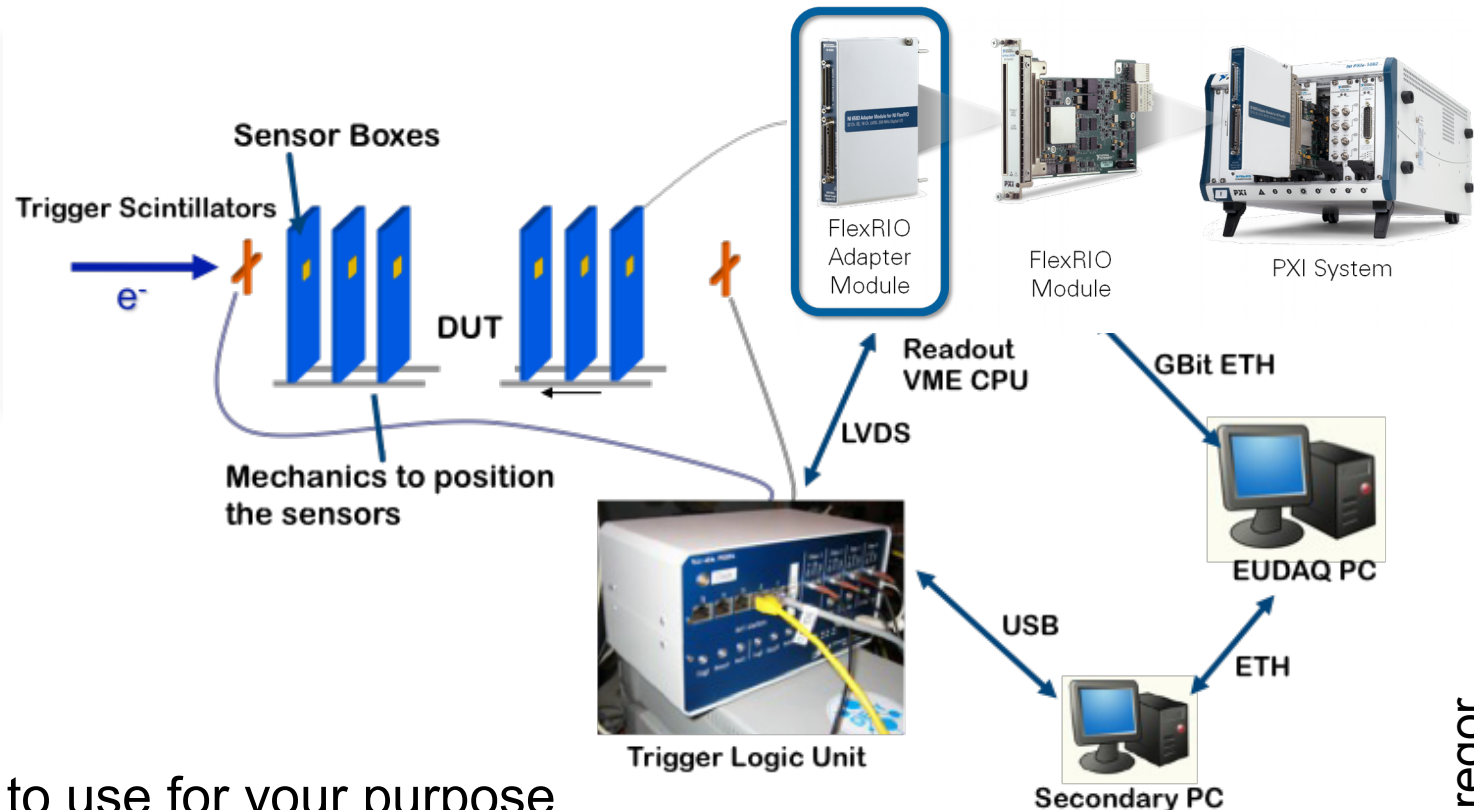
- How to study a tracking device in a test beam?
- Need reference frame for precise tracking of beam particles
 - Usually use tracking up + downstream the **D**evice **U**nder **T**est
 - Reference system at least the same resolution compared to the DUT
- Two possibilities
 - Many layers of same sensor (choose middle one to be DUTs)
 - An independent reference system: “Beam telescope”



Slide from I. Gregor

Telescope ingredients

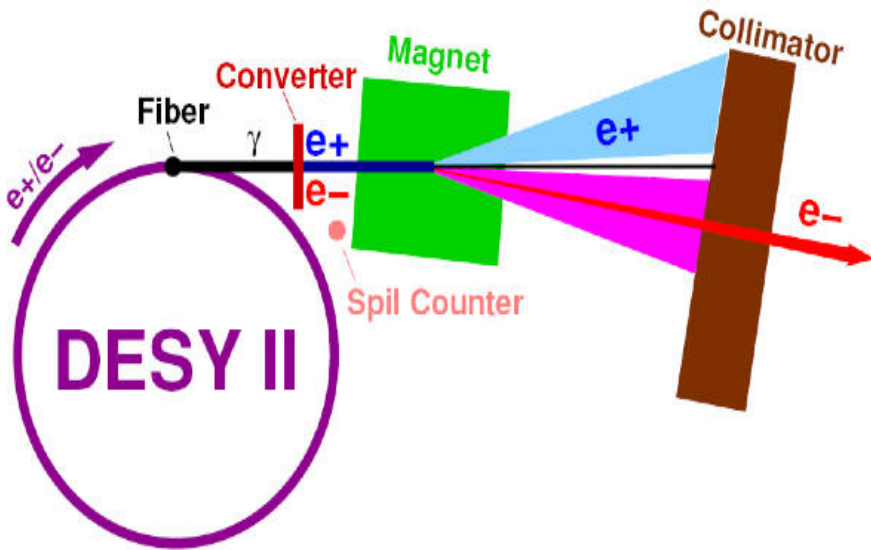
- ✓ Sensors (Mimosa26)
- ✓ Readout System
- ✓ EUDAQ
- ✓ Trigger Logic Unit
- ✓ Mechanics



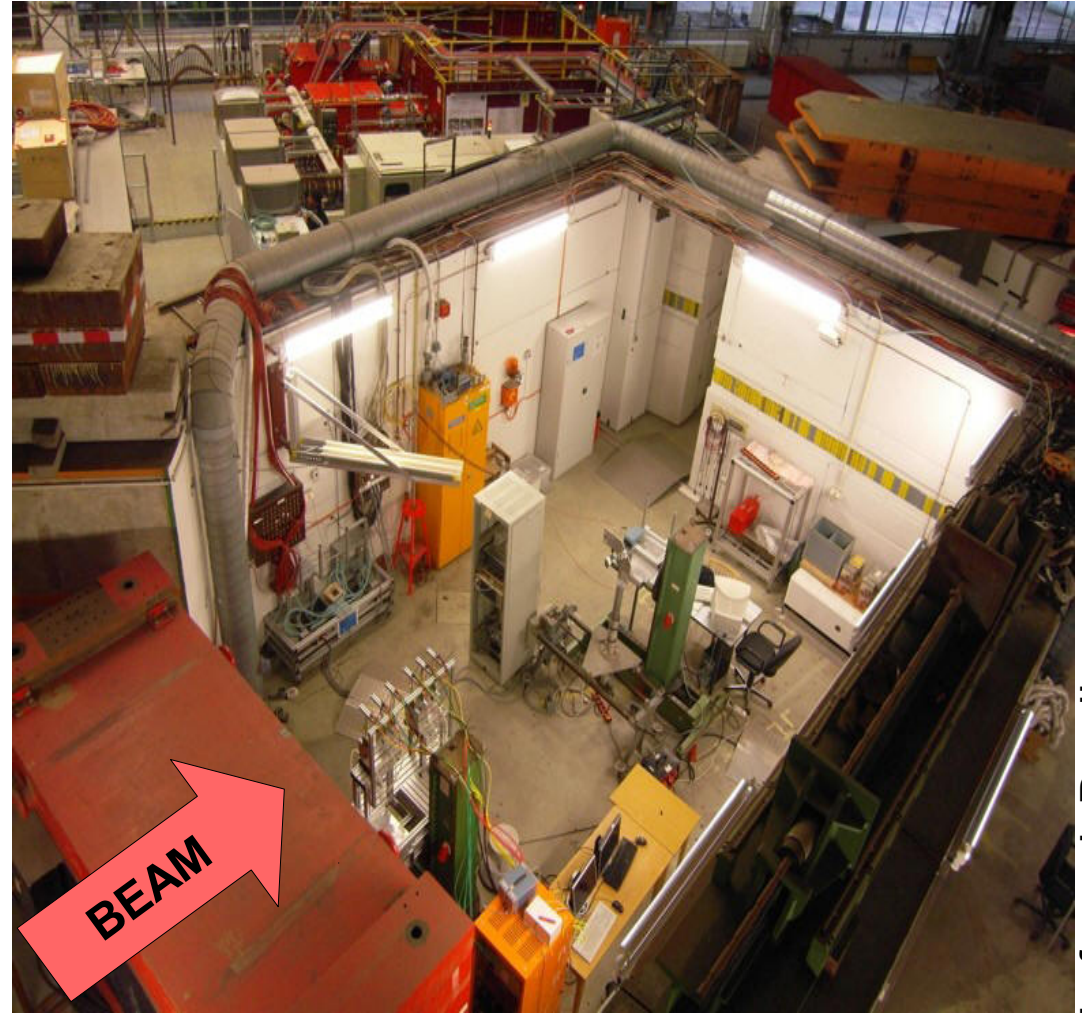
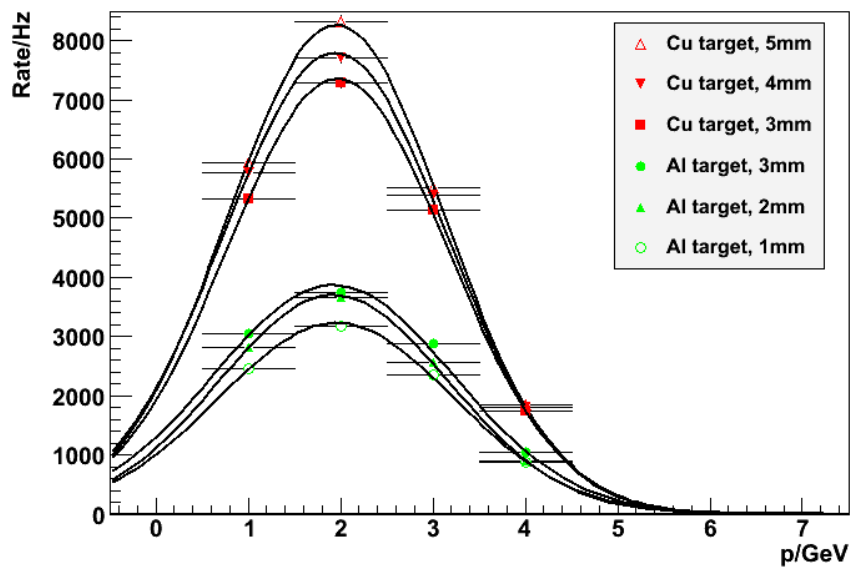
Nota bene:

- Use a DAQ that is
 - easy enough to use for your purpose
 - generic enough to accommodate your needs
- Reconstruction software for track reconstruction
 - e.g. EUTelescope based on ILCSoft
- You'll need time to get acquainted with the tools

Test beam studies



Testbeam 21 (e^+ @ 6GeV)



Slide from J. Dreyling

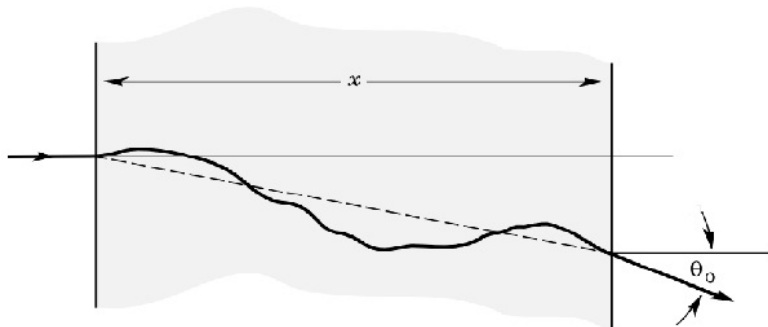
Test beams around the world



Slide from I. Gregor

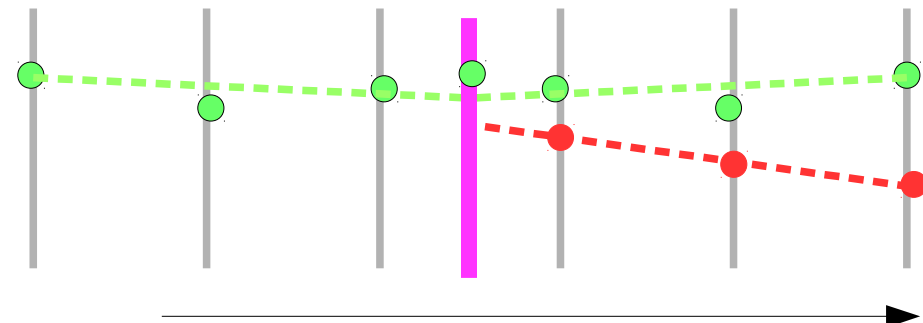
Test beam studies

- Know precisely the resolution of your telescope sensors
- Measure many particle tracks (hits in telescope + DUT)
 - Find hits that belong together (track finding)
 - Fit/Extrapolate track to DUT (for good fit, need estimate of material budget in beam)



- Residual = fit – measured
→ Fill residual distribution

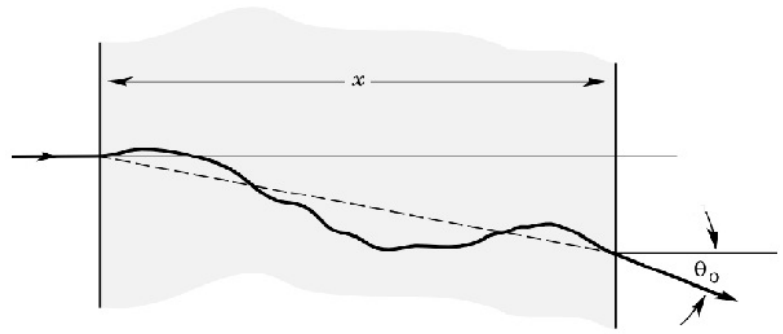
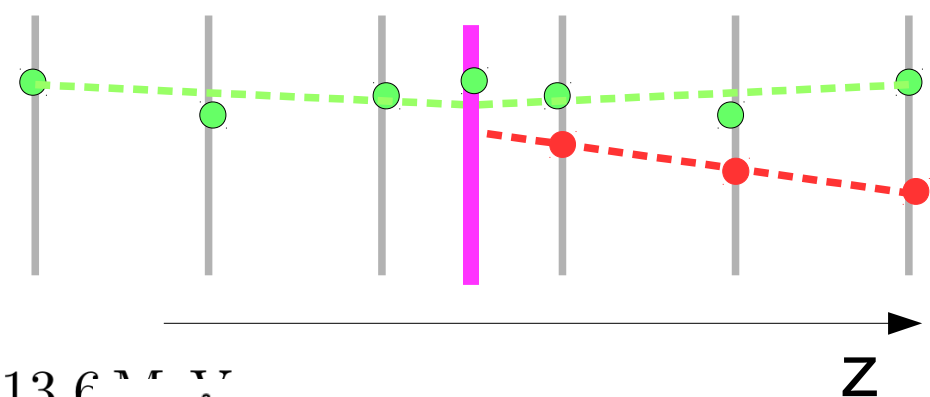
$$r_u^2(z) = \sigma_{\text{int}}^2(z) + \sigma_{t,u}^2(z)$$



$$\Theta_0 = \frac{13.6 \text{ MeV}}{\beta c p} \cdot Z \sqrt{\epsilon} \cdot (1 + 0.038 \ln(\epsilon))$$

Test beam studies

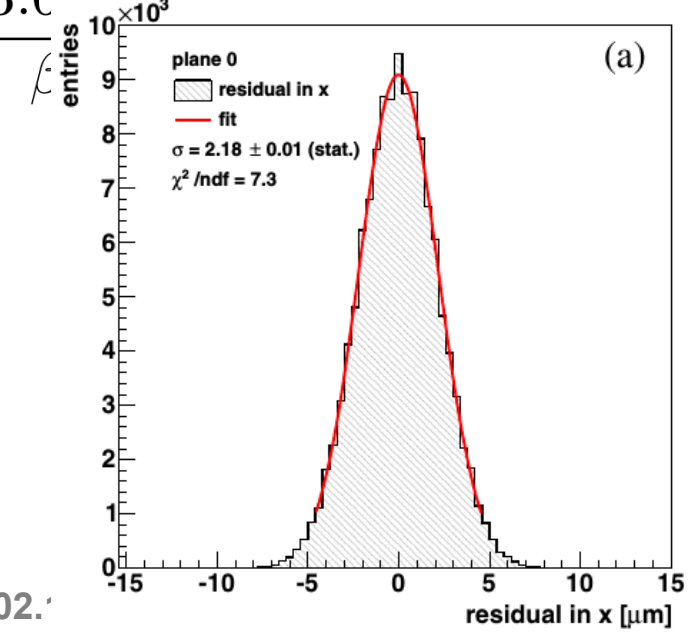
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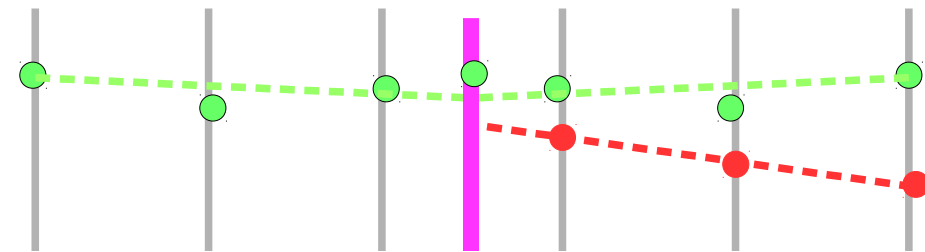
$$r_u^2(z) = \sigma_{\text{int}}^2(z) + \sigma_{t,u}^2(z)$$

$$\Theta_0 = \frac{13.6}{\beta} \times 10^3 \cdot (\epsilon)$$

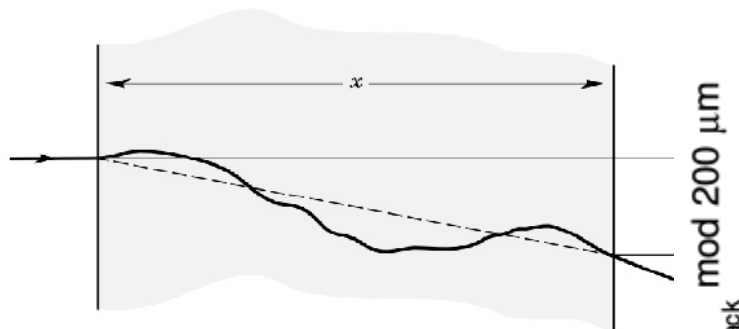


Test beam studies

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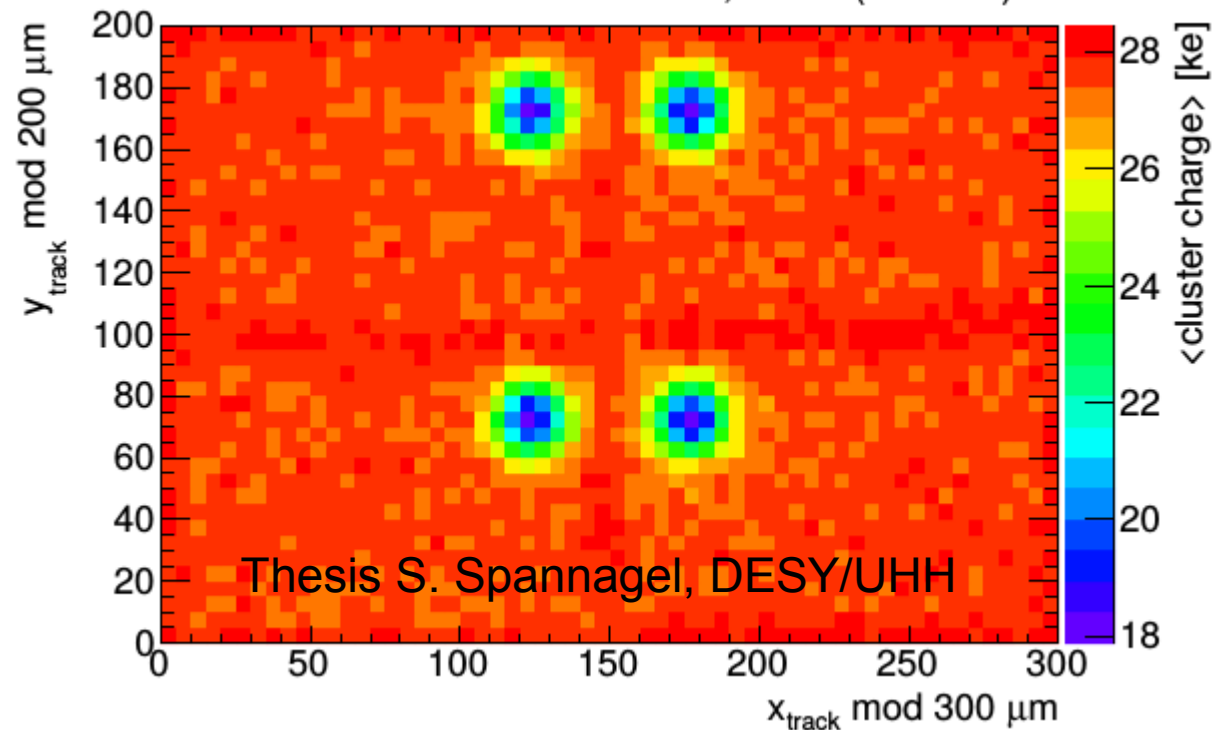


8.3×10^6 tracks, $\alpha = 0^\circ$ (5.2 GeV)

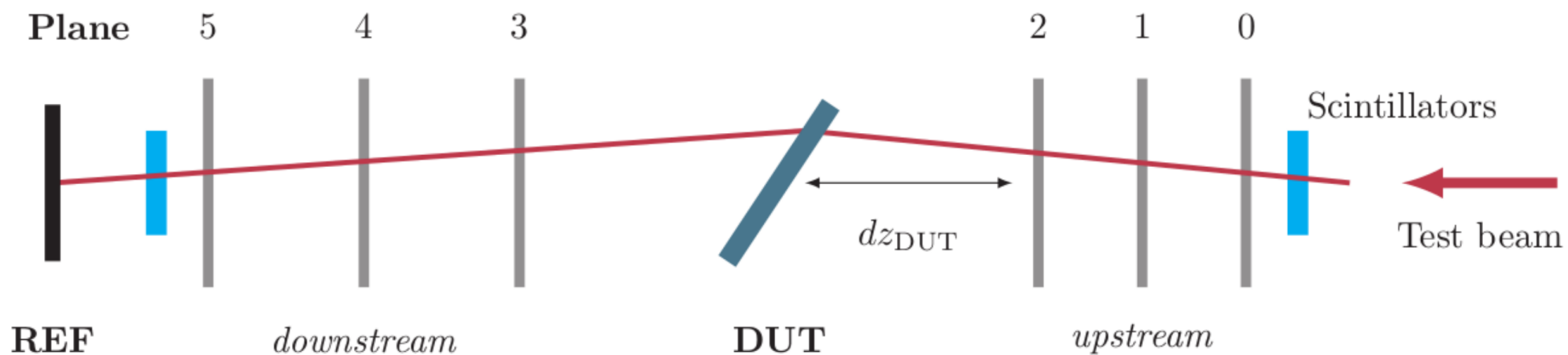


- Residual = fit - me
- Fill residual distribution

$$r_u^2(z) = \sigma_{\text{int}}^2(z) + \sigma_{t,u}$$



Thesis S. Spannagel, DESY/UHH



test beam measurements

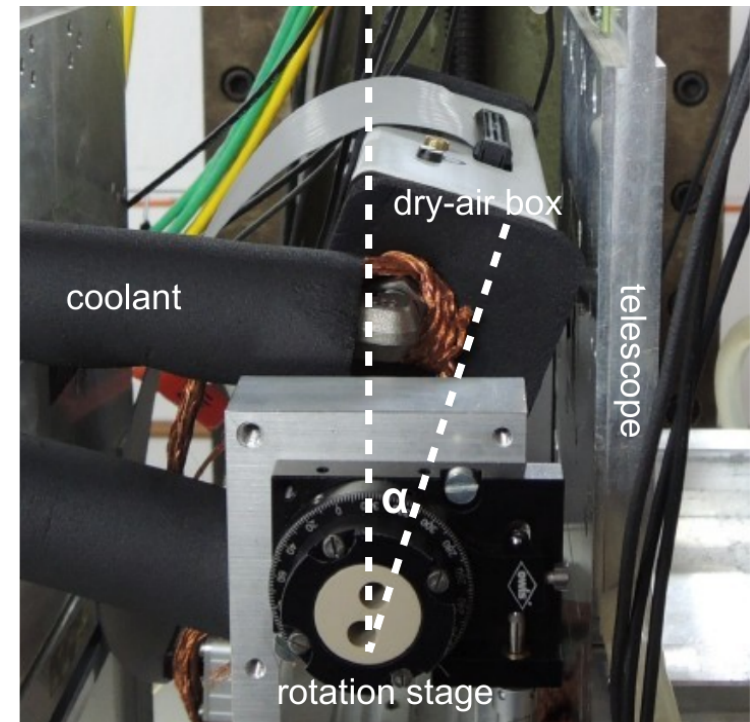
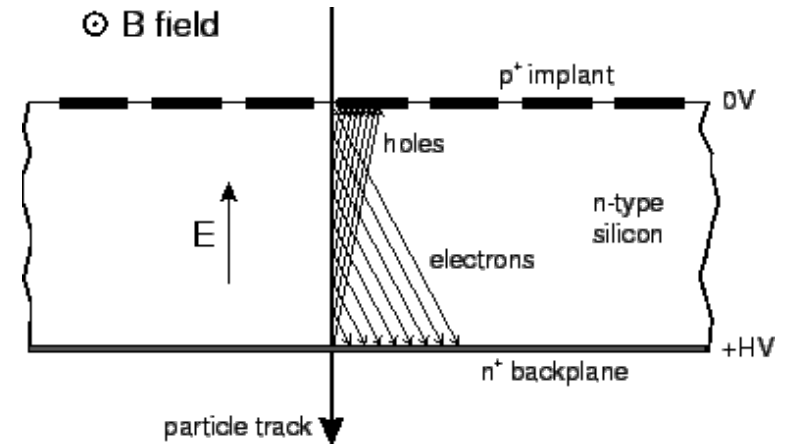
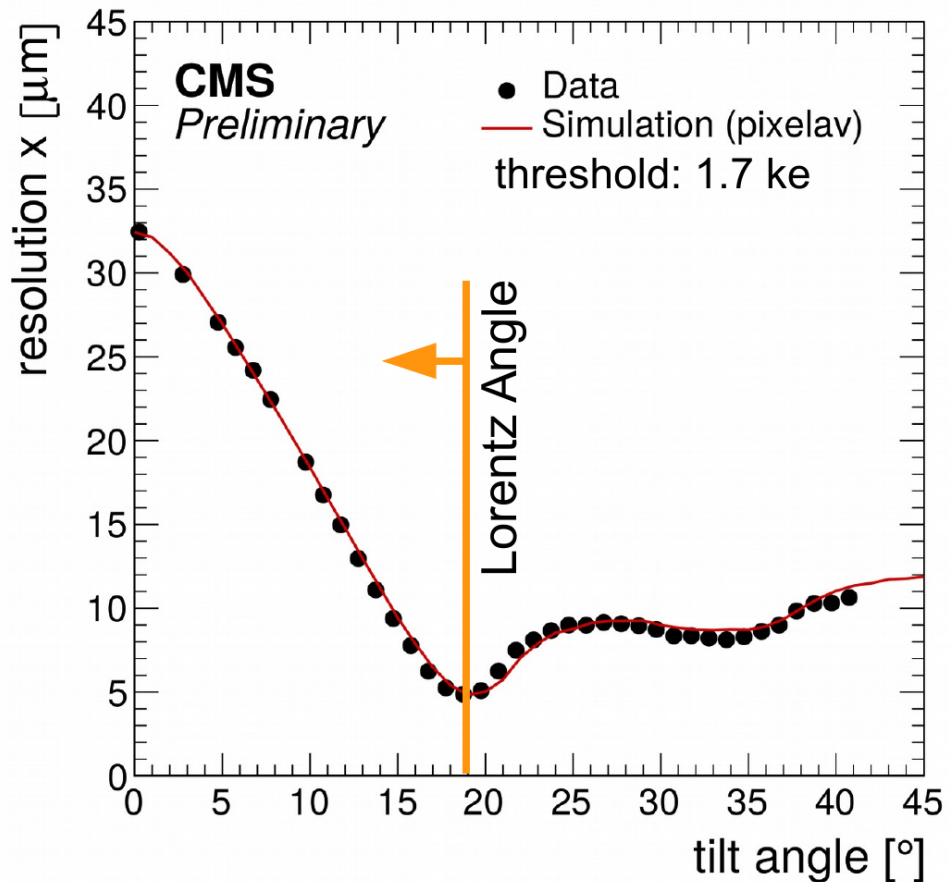
-

Resolution studies with CMS pixel detectors

Spatial Resolution

- Mimic Lorentz drift by rotating ROC
- Very good agreement with simulation
- Best resolution: 5 μm

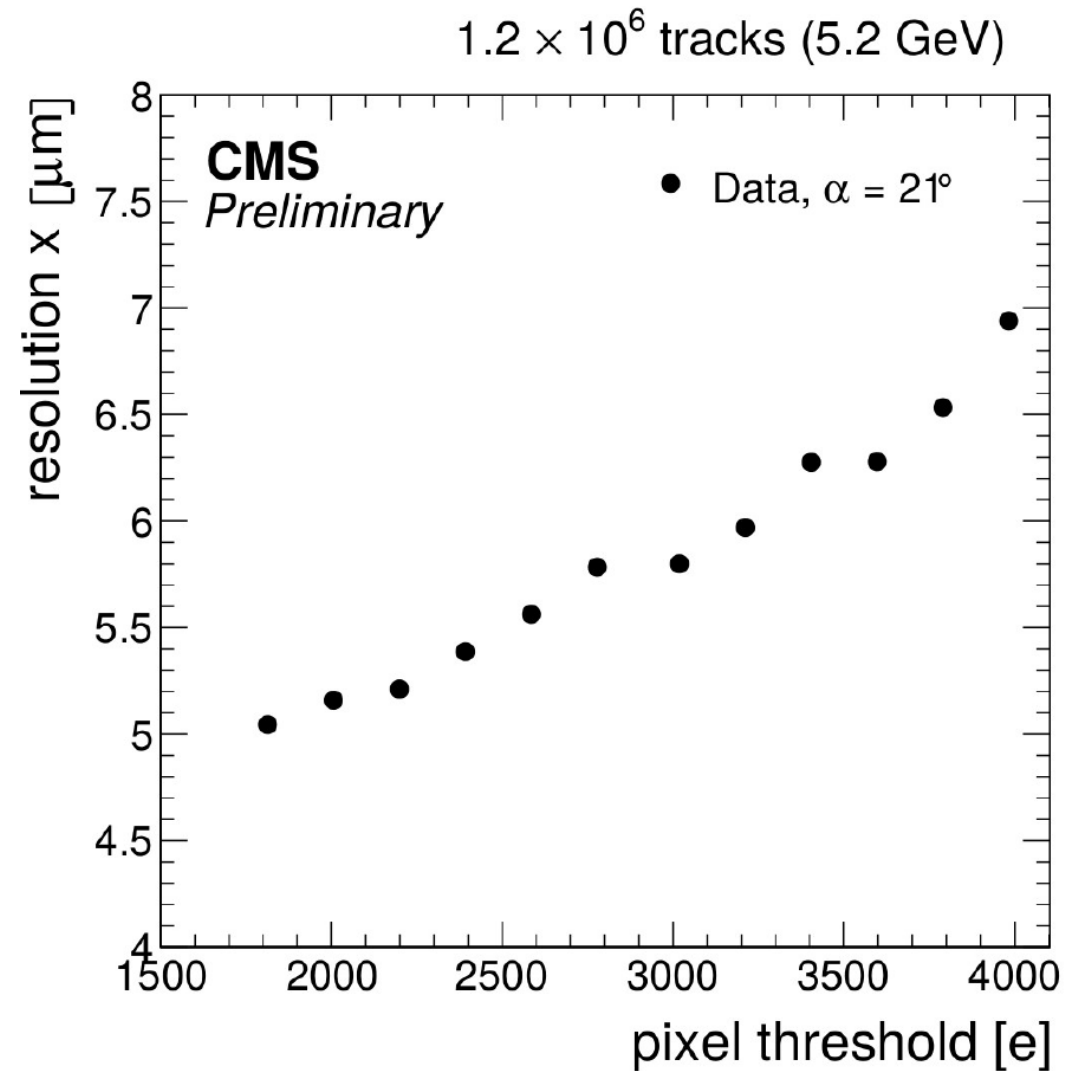
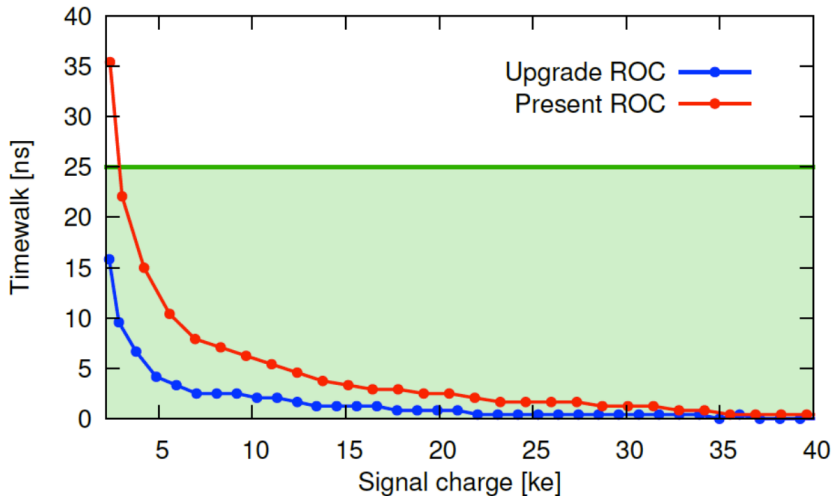
3.2×10^6 tracks (5.6 GeV)



Slide from S. Spannagel

ROC Analogue performance

- Improved analogue circuitry
- Lower absolute & in-time threshold
 - ~1.5 ke
- Current ROC:
 - 2.5 ke- minimal threshold
 - 3.2 ke in-time threshold
- Reduced time walk due to faster comparator



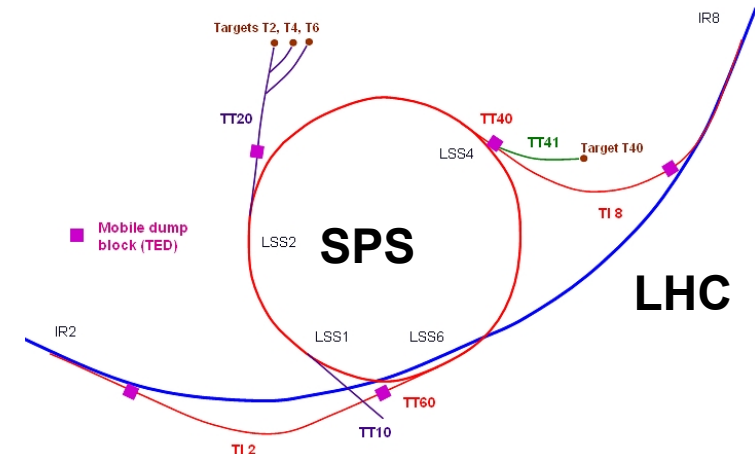
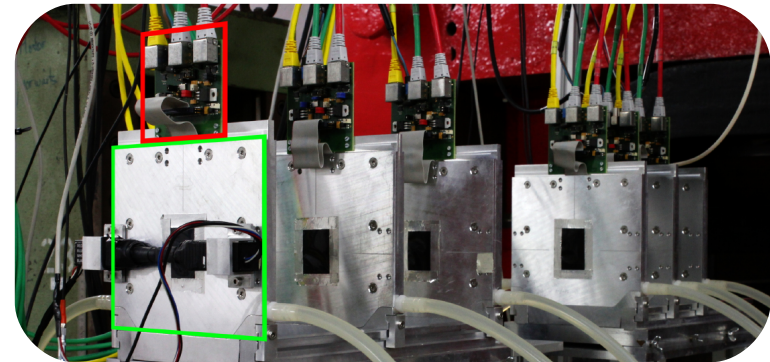
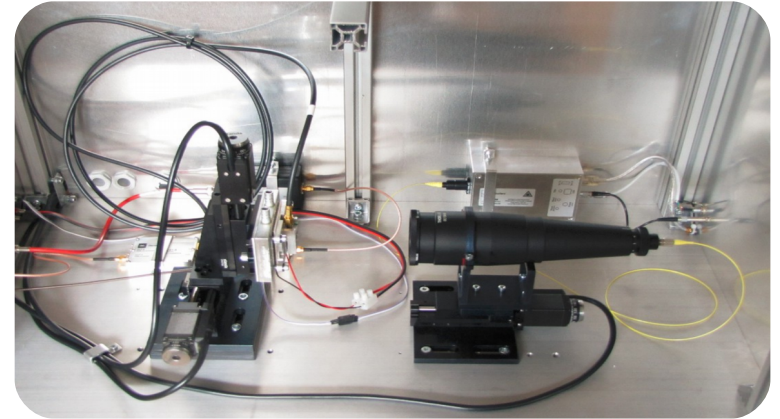
Slide from S. Spannagel

Intermediate summary

- We reviewed different techniques to study electrical properties of semiconductor sensors
- There is more ...
- Radiation damage in
 - front-end ASICs (read-out of sensor)
 - periphery: opto-electronics (laser, receiver)
 - passive components: thermal connections, ...
- Time to short to talk about more techniques, but some ideas of mitigating rad. damage in passive components are given in the next part.

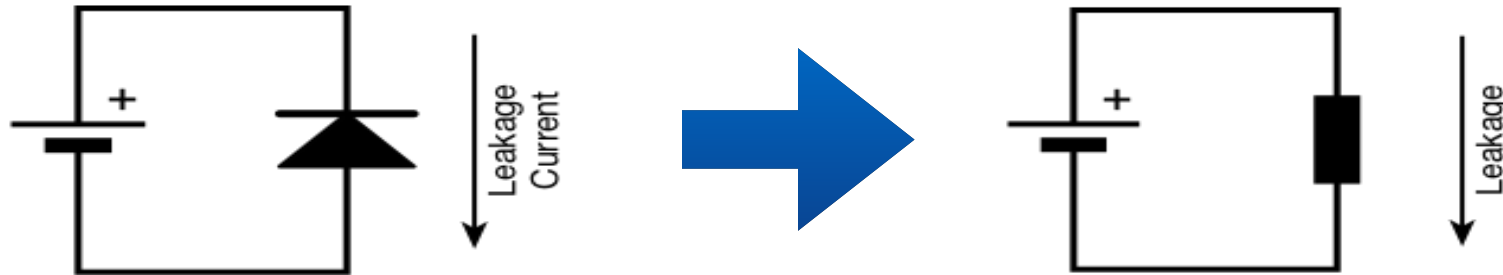
Outline

- HEP detector overview
 - what we have and
 - why we need to do better
- Radiation damage in semiconductor sensors
 - lab-based
 - with beams
- **Clever ideas confronting radiation damage**



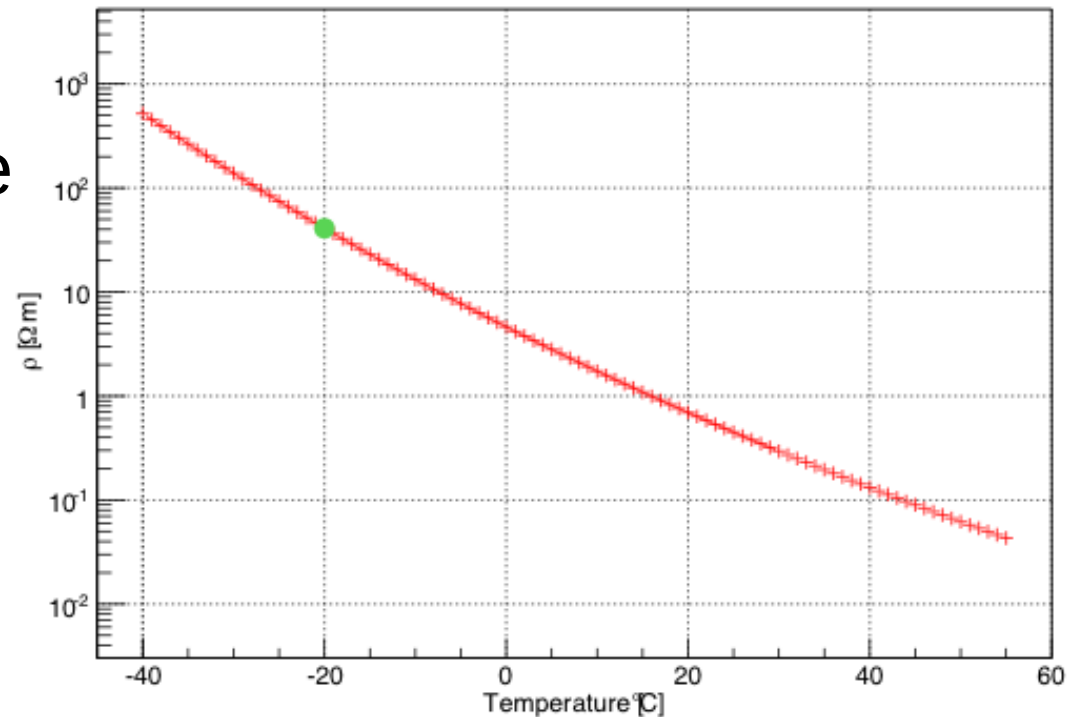
Smarter cooling

- Radiation damage increases leakage current
- Reversed biased diode acts as resistor heat-wise



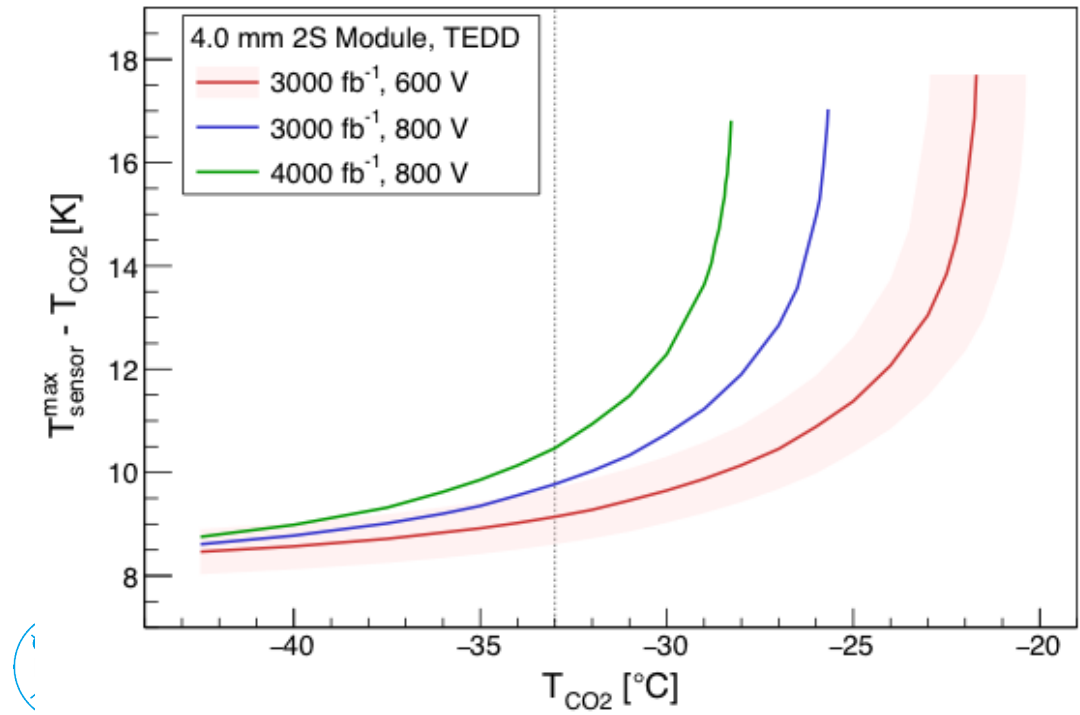
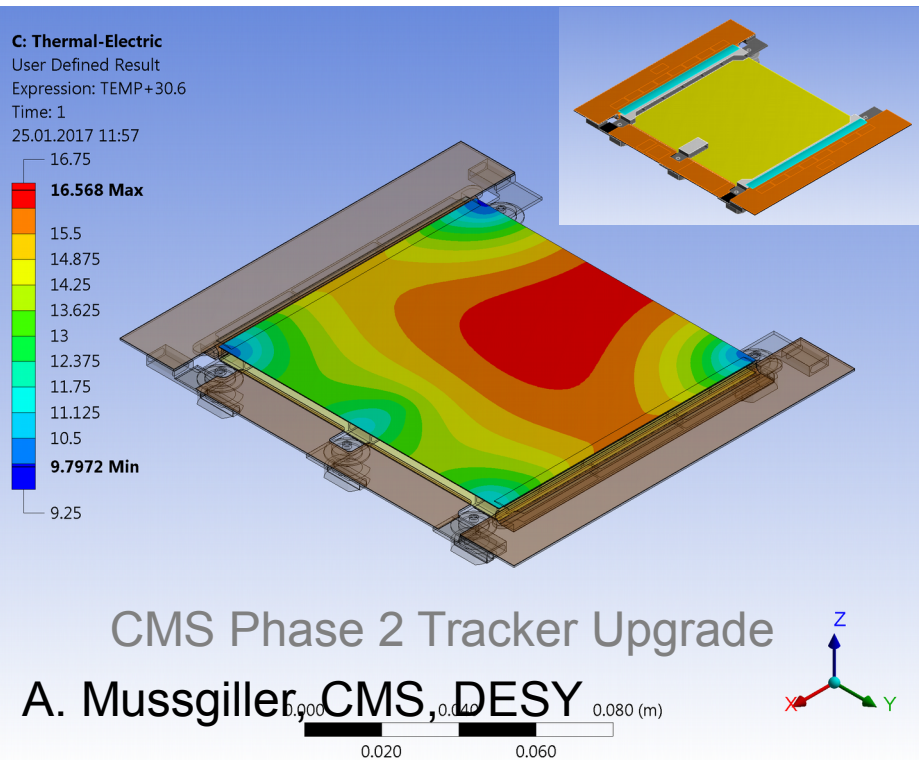
$$\text{Power} = U_{\text{bias}} * I_{\text{leakage}}(T)$$

- Temperature dependence of power dissipation for each given fluence



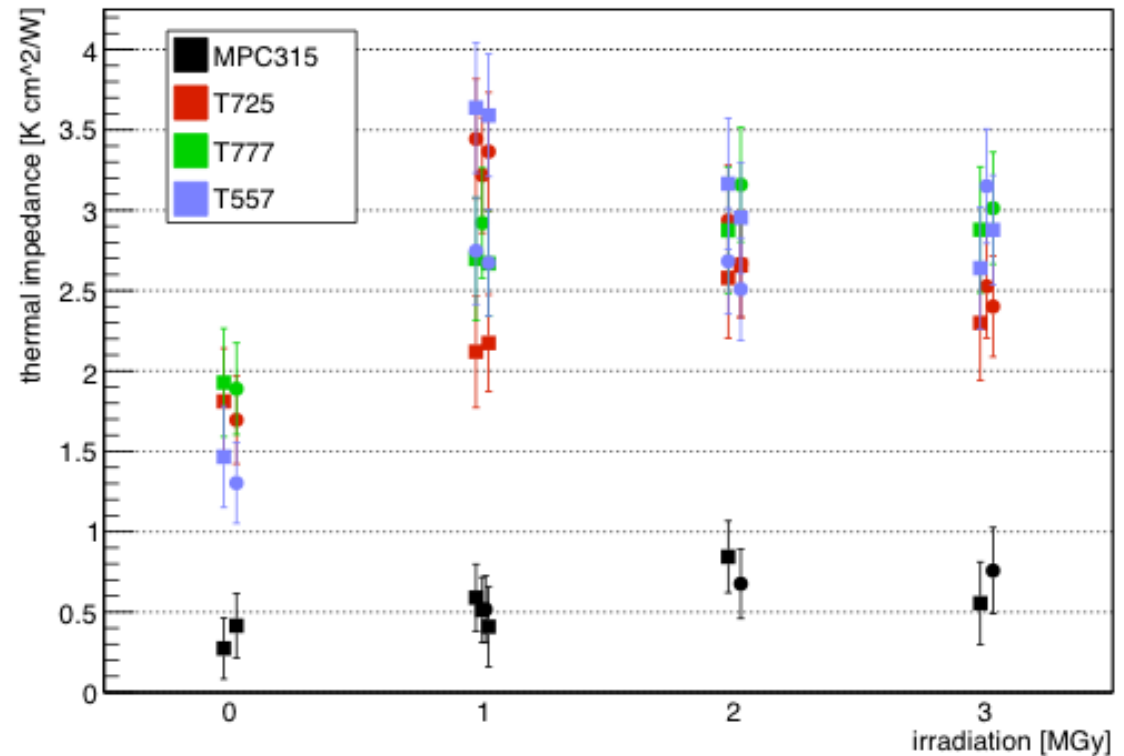
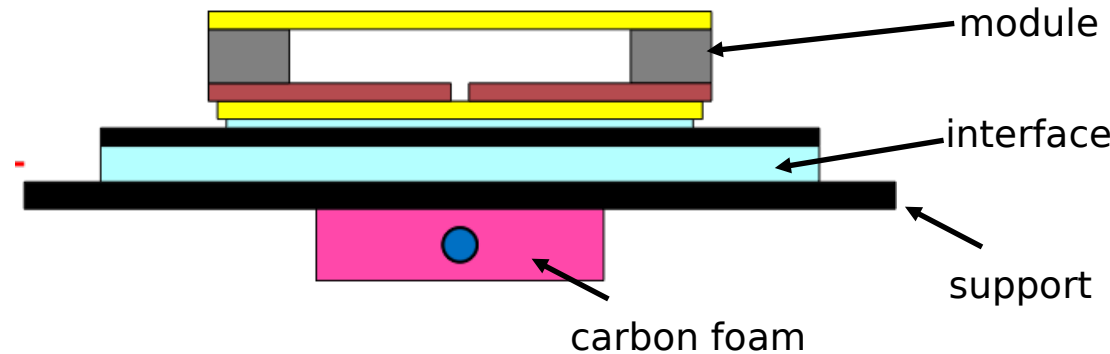
Minimise current / avoid hot spot

- Increased current due to irradiation can be mitigated by carefully designing your cooling system
- Thermal performance of CMS Phase 2 Tracker Upgrade is characterised in terms of T at which thermal runaway occurs (I_{leakage} increases T , which increases I_{leakage} , ...)



Glue!

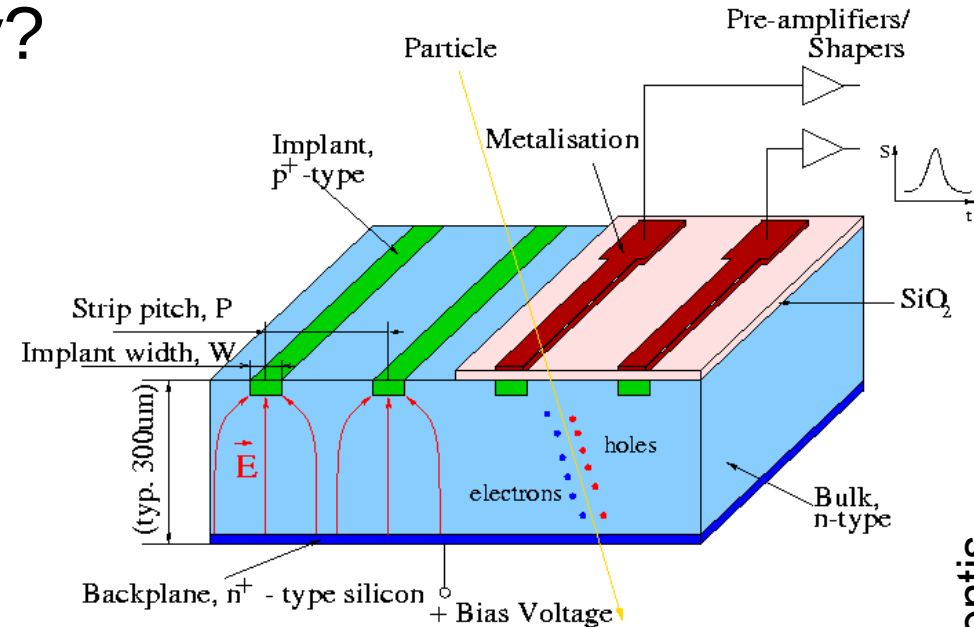
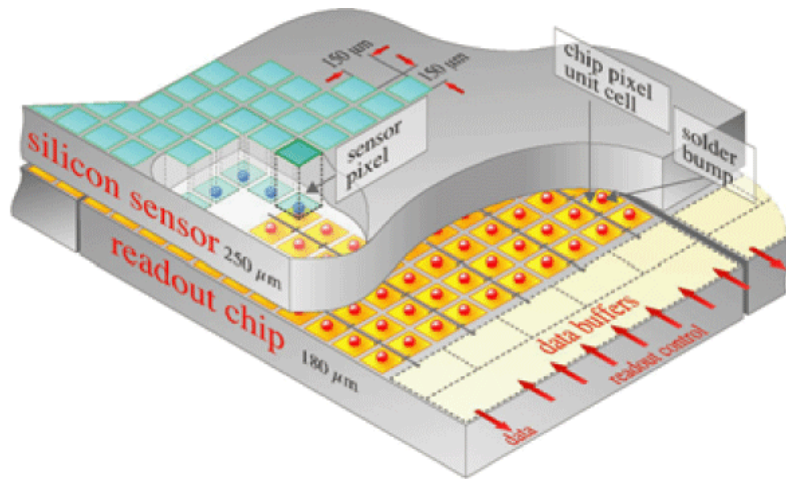
- Glue? Yes.
- Need to glue module to cooling system
- Is the thermal connection affected by radiation damage?
- Glue test sample, measure, irradiate, measure, ..., compare



Test beam measurements - Sensor R&D for material choice

Material study for phase 2 pixel ...

- ... using **strip** sensors. Why?



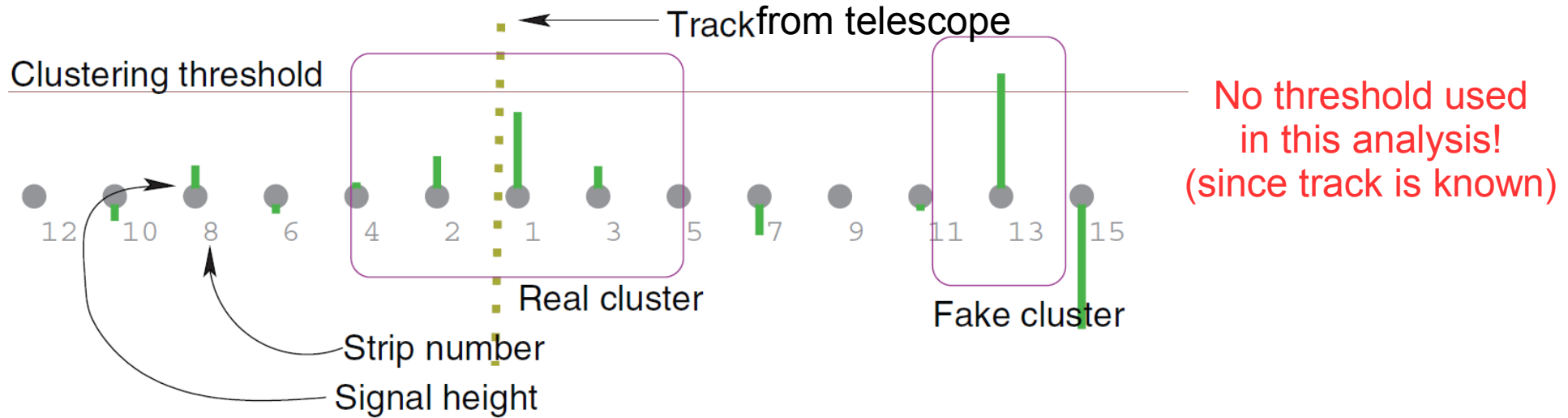
- Noise level $\sim 100 e^-$ before irradiation
- **Bump bonding**
- Heat treatment to achieve connection between sensor and readout
 - **modification of sensor properties**
- Irradiation of sensor and electronics
 - **modification of electronics**

- Noise level $\sim 800 e^-$ before irradiation
- **Wire bonding**
- No heat treatment for connection with readout electronics
- **Separate irradiation**
- **No modification of electronics**

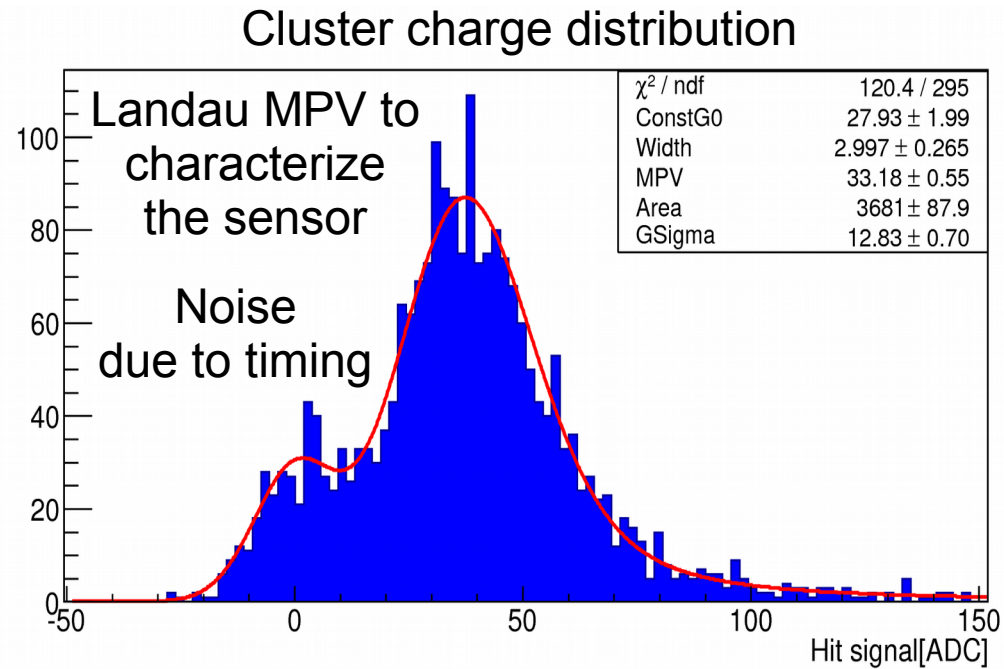
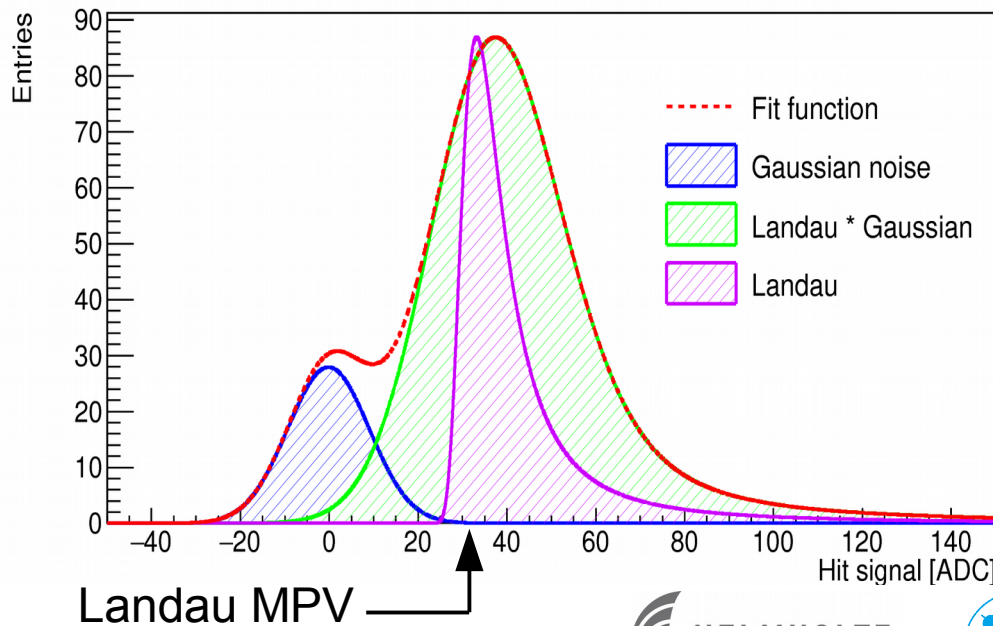
Beam telescope to reconstruct hit position
→ **separation of noise from signal**

Cluster definition

T. Mäenpää et al, IEEE 2009

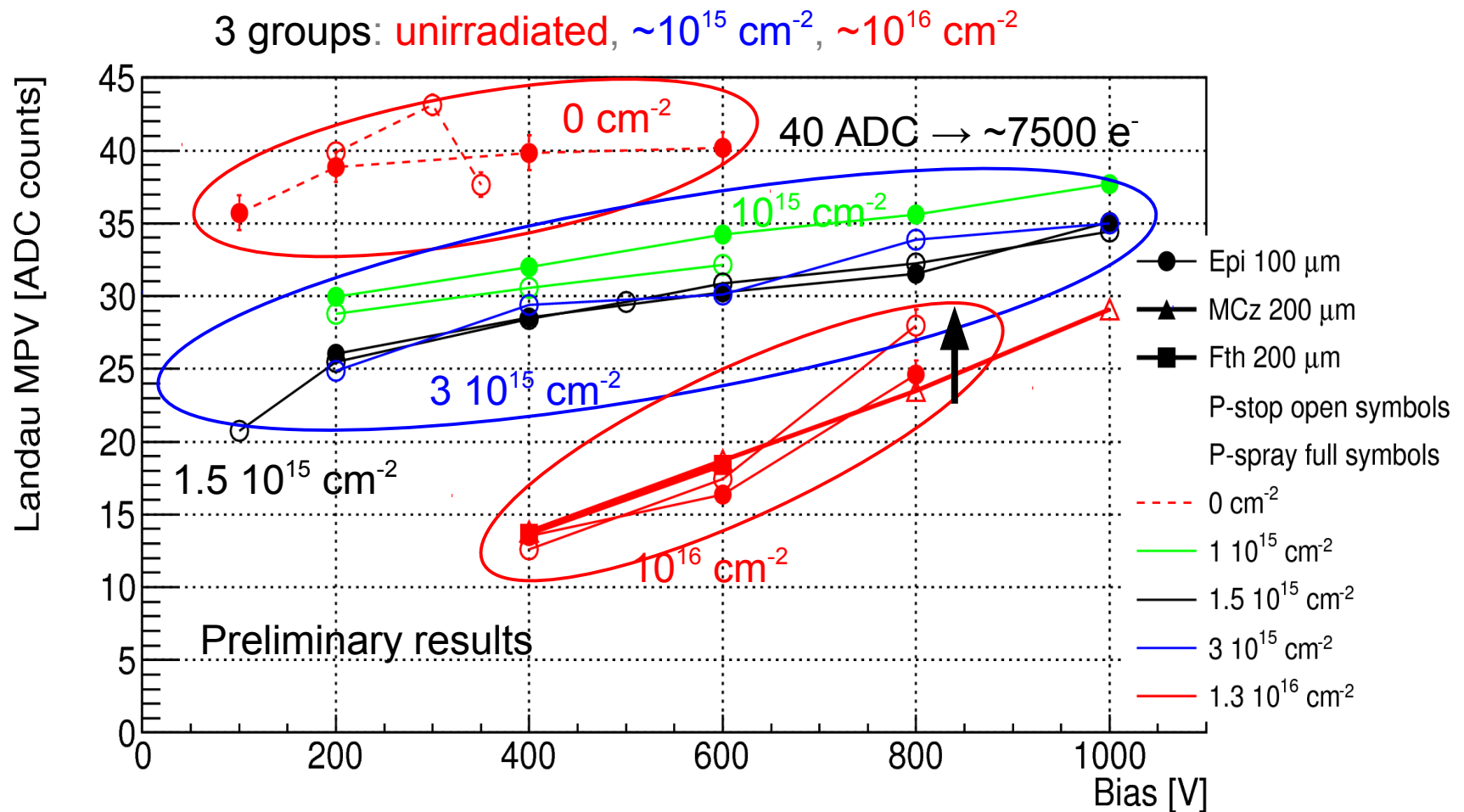


Slide from M. Centis



Epi100P, 23 GeV p, $3 \times 10^{15} \text{ cm}^{-2}$, -800V, -20 °C

Material study for phase 2 pixel



- Charge collection degrades with irradiation
- Charge collection increase with bias after irradiation
- At 10^{16} cm^{-2} :

100 μm sensors \rightarrow faster signal recovery with bias

200 μm sensors \rightarrow operation at higher bias

Similar MPV achieved for both thicknesses!

Material study for phase 2 pixel

The thin sensors show promising results:

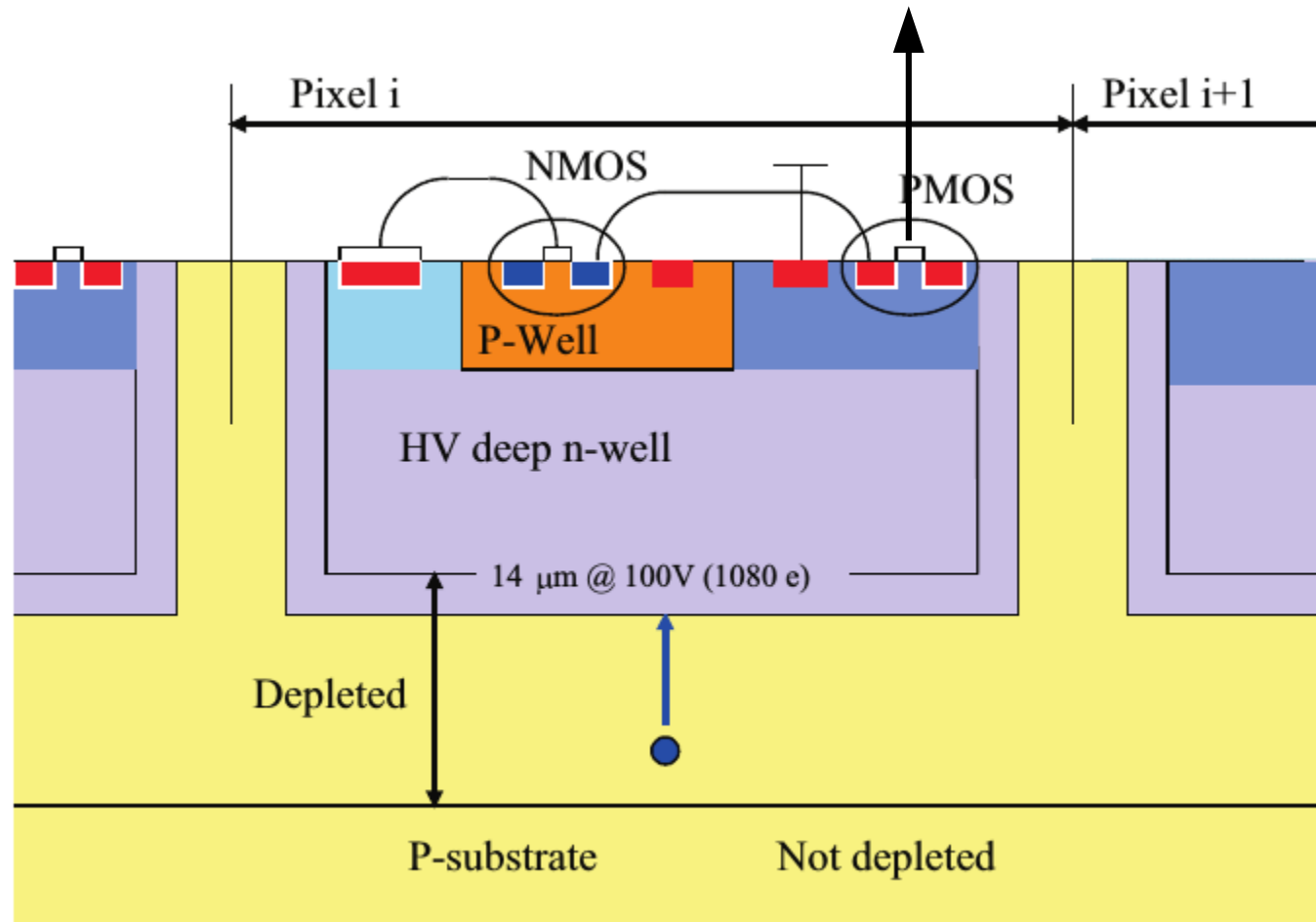
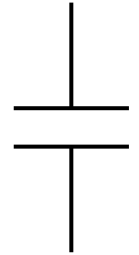
- 100 μm , p-bulk
 - Charge collection efficiency of $\sim 65\%$ after a fluence of 10^{16} cm^{-2}
 - Signal increase with bias
 - Good candidates for outer pixel layers (fluence $\sim 10^{15} \text{ cm}^{-2}$)
 - Further studies needed for operation after a fluence of 10^{16} cm^{-2}
 - 200 μm , p-bulk
 - Charge collection efficiency of $\sim 35\%$ after a fluence of 10^{16} cm^{-2}
 - Comparison to 100 μm sensors:
 - Slower signal increase with bias
 - Smaller noise
- **150 μm might be worth looking at!**

Slide from M. Centis

HV-CMOS

- Use cheap commercial processes, singles-sided

Couple signal to ASIC, e.g. capacitively



TPA-TCT with HVCMOS

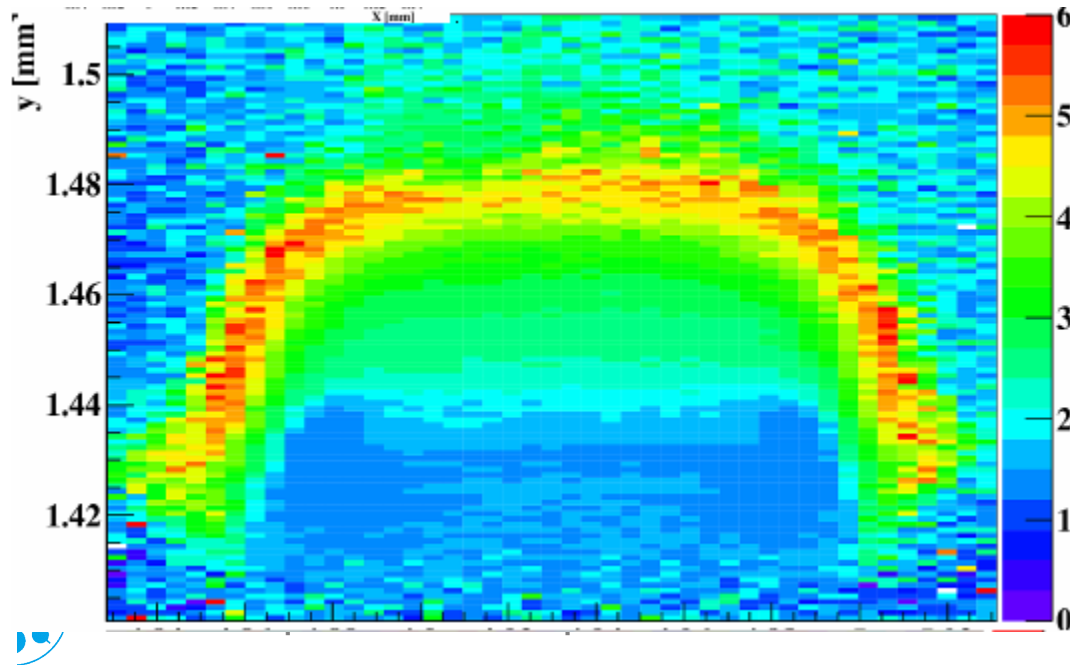
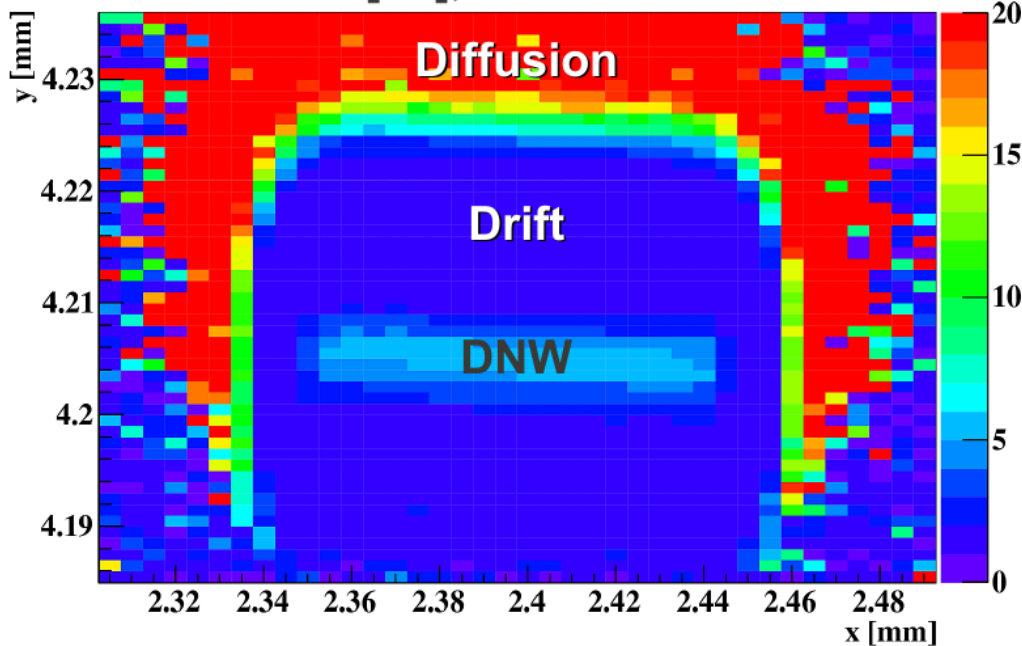
- Study the collection time of HVCMOS sensors with the TPA-TCT technique

un-irradiated

**Irradiated
7e15 1/cm²**

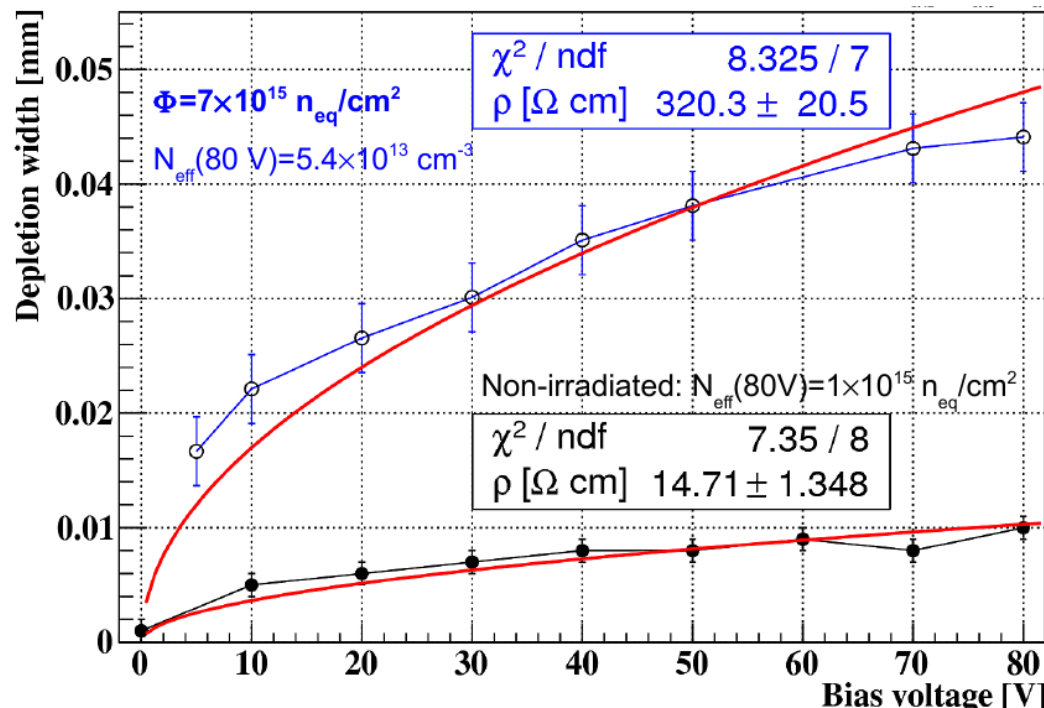
M. Fernandez, 29th RD50

Collection time [ns], HVCMOSv3 ams 180 nm



TPA-TCT with HVCMOS II

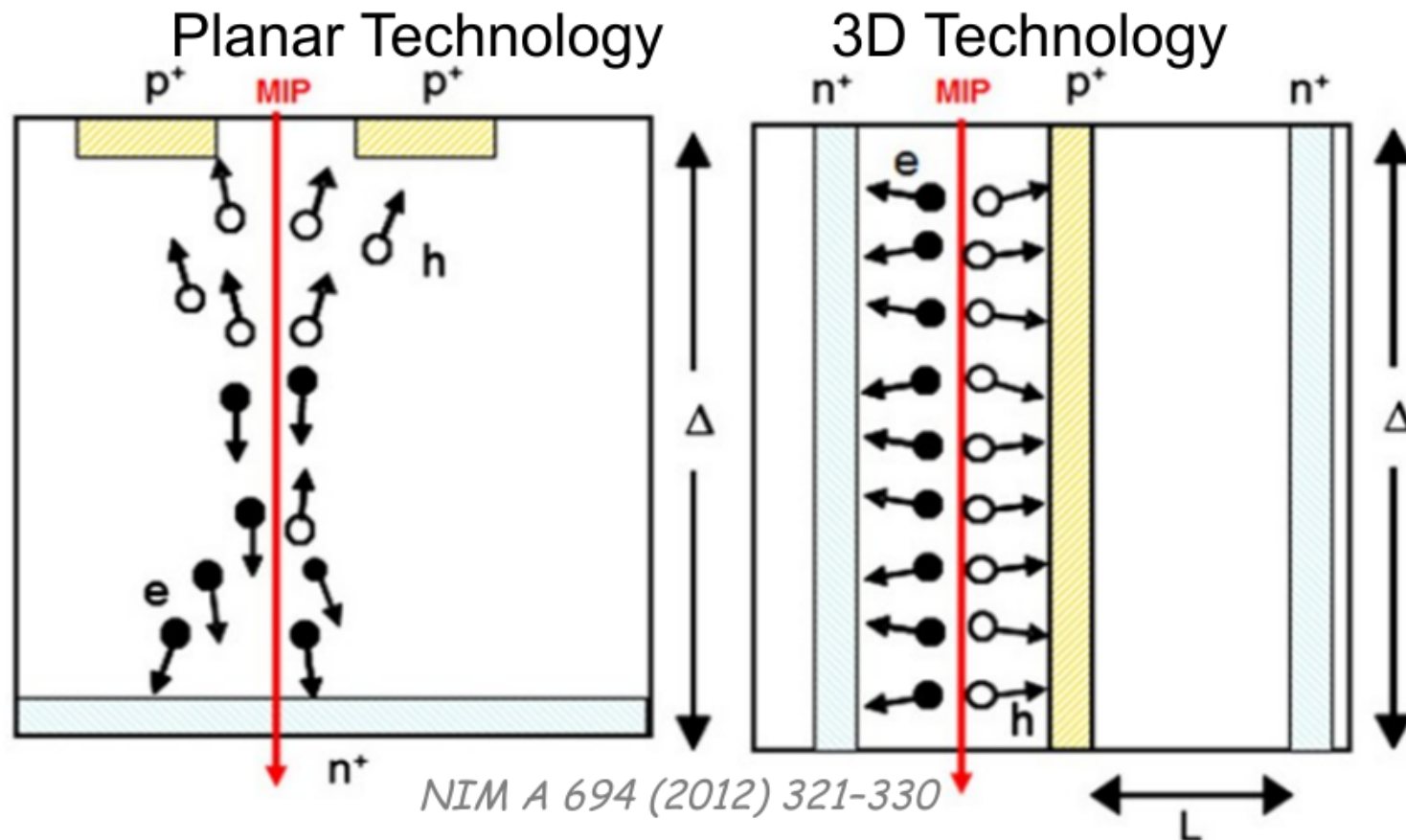
- Extract the depletion width of the sensors, and compare for different fluences



- The performance INCREASES up to a certain flux!
- Then degrades again: Acceptor removal vs. trapping time

3D sensors

- We saw many examples of standard 2D sensors
- Long drift path problematic at high radiation damage (short trapping times, charges don't reach electrode)
- How to achieve shorter drift paths?

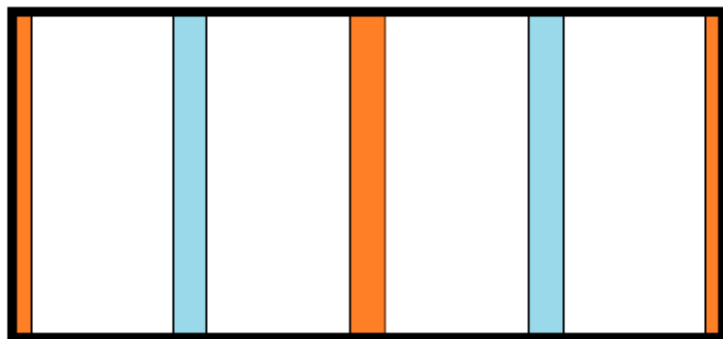


Picture: U. C. DaVia

ATLAS 3D sensors

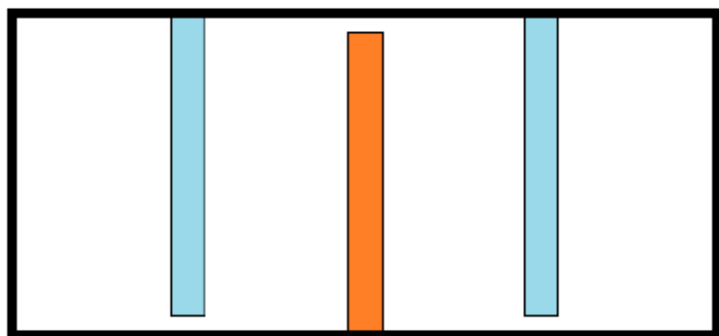
- They exist in different versions

Full 3D technology:



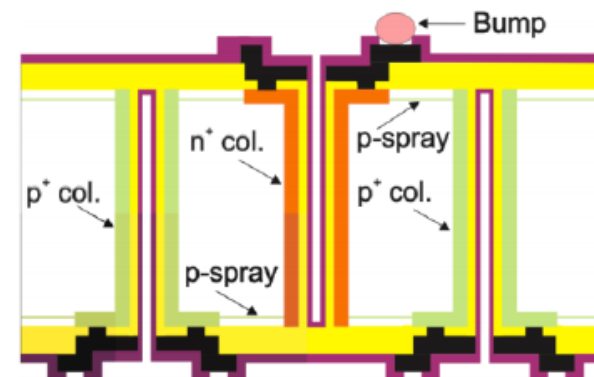
SNF (SLAC) and Sintef

Double-sided 3D technology:

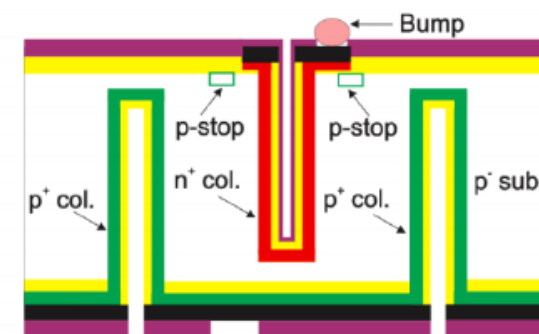


CNM and FBK

FBK



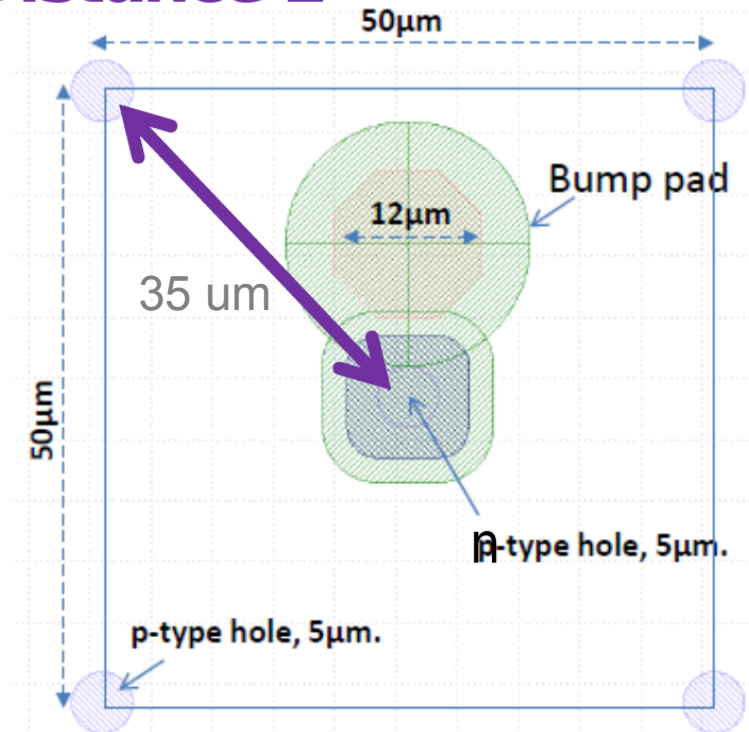
CNM



3D Sensors

- Small inter-electrode distance
- Development of new generation of HL-LHC 3D pixel sensor
 - less trapping due to small L
 - radiation hardness of up to $2e16 n_{eq}/cm^2$ required
- Drawback: Larger capacitance
 - more noise
- Possibility to reduce thickness
 - decreases the noise
 - decreased leakage current (less volume)
 - but also less charge!
 - it is always a trade-off, need also better ASICs!

Electrode Distance L



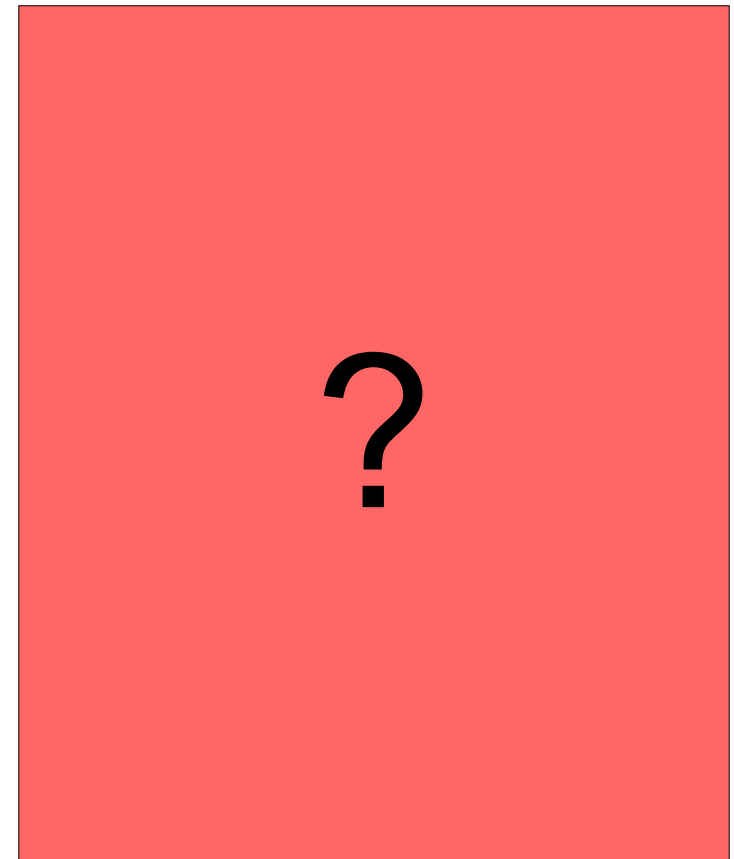
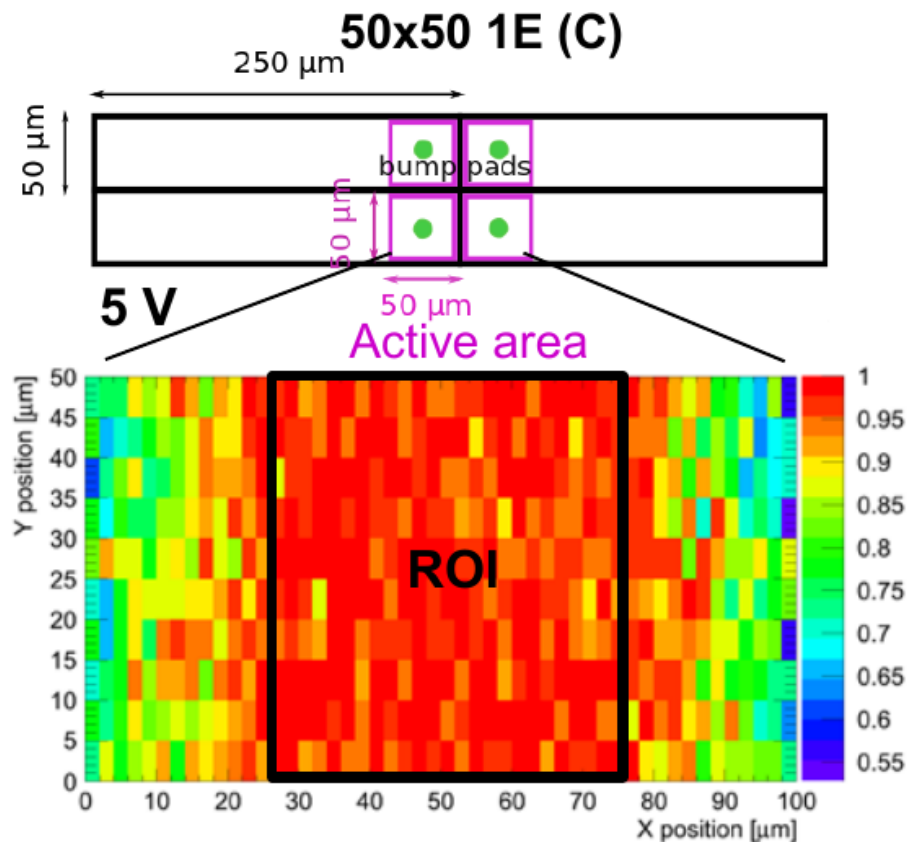
3D sensor in a test beam

- Test beam with a 50 x 50 μm^2 sensor

un-irradiated

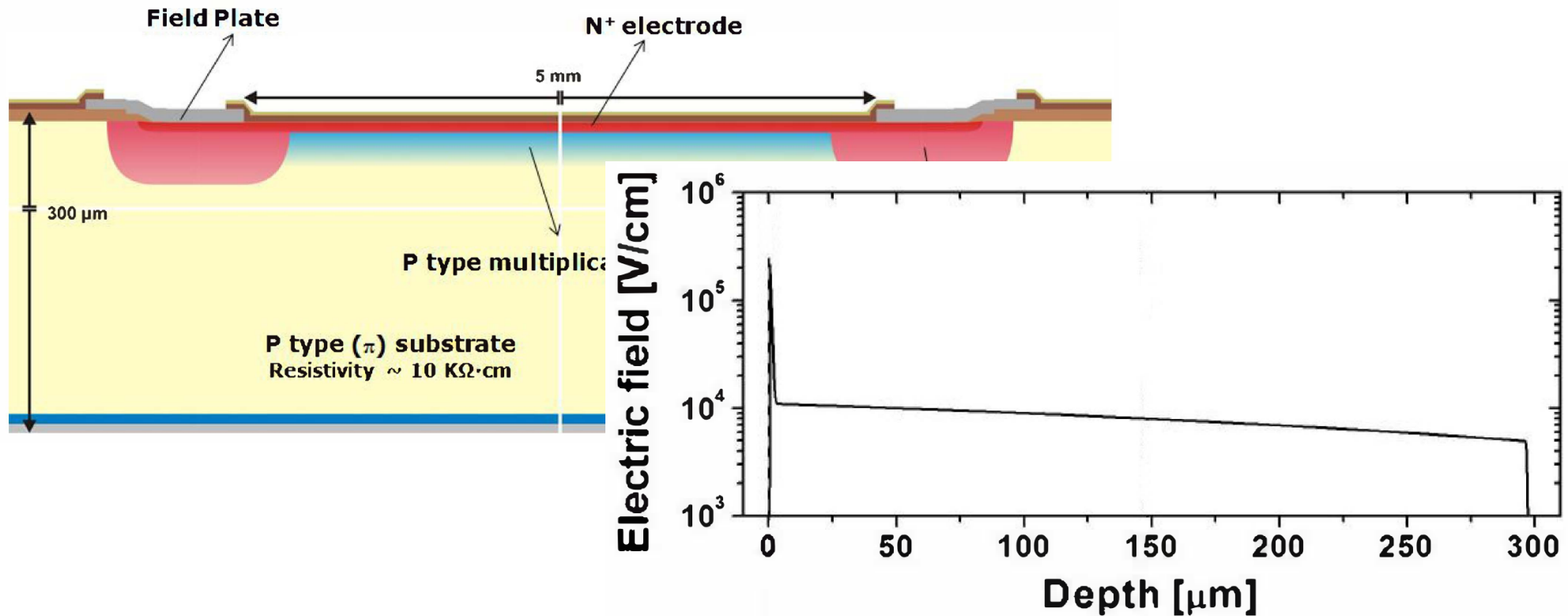
irradiated

In-Pixel Efficiency (FEI4 telescope, 0°)



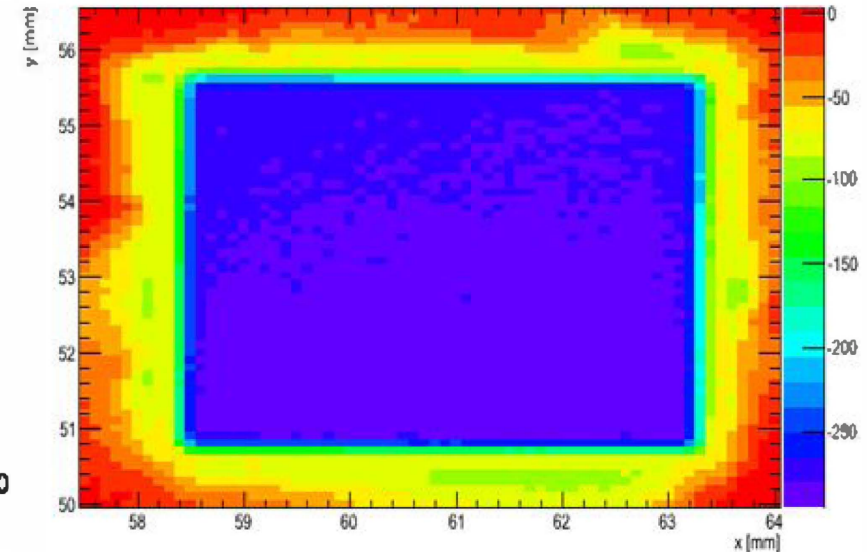
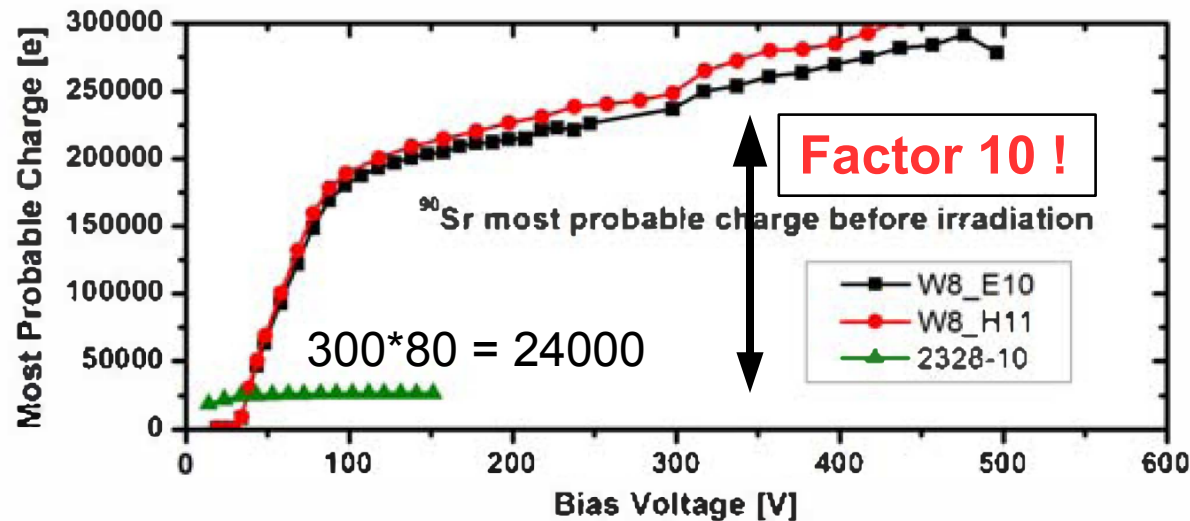
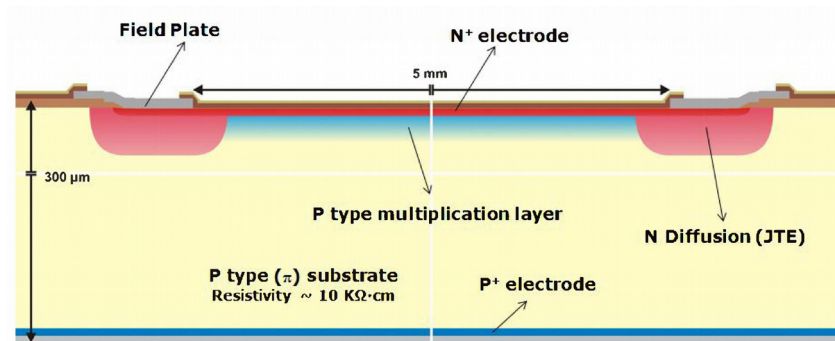
Low gain avalanche diode

- Try to increase SNR of your (irradiated) sensor
- LGAD uses P-type multiplication layer below n+ electrode
- Use top-TCT (red laser) for scan



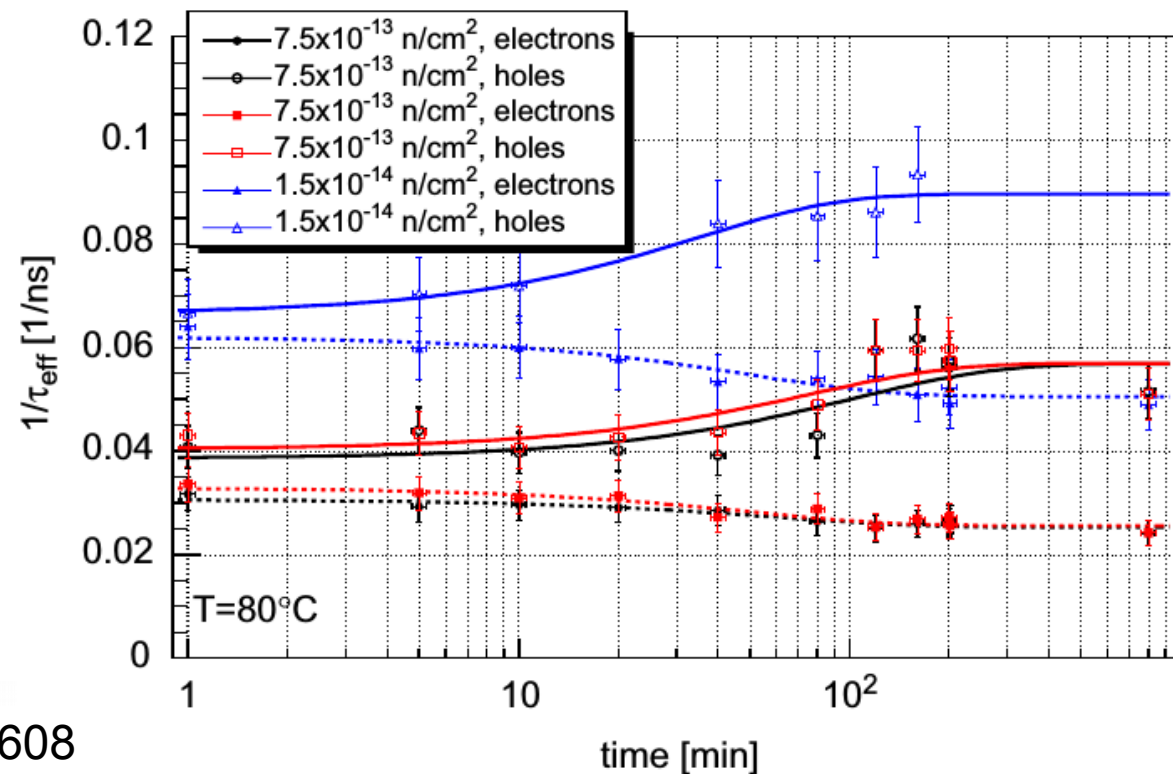
Low gain avalanche diode

- LGAD uses P-type multiplication layer below n+ electrode
- Use top-TCT (red laser) for scan



Annealing of defects

- Heating a damaged sensor has positive and negative effects
- Lifetime of charges at given flux is changed by heating:
 - heat \rightarrow higher mobility of atoms/vacancies
 - new 'configuration' of defects \rightarrow visible in TSC and DLTS
- Trapping probability increases for holes, decreases for electrons



Maybe diamond?

Pros:

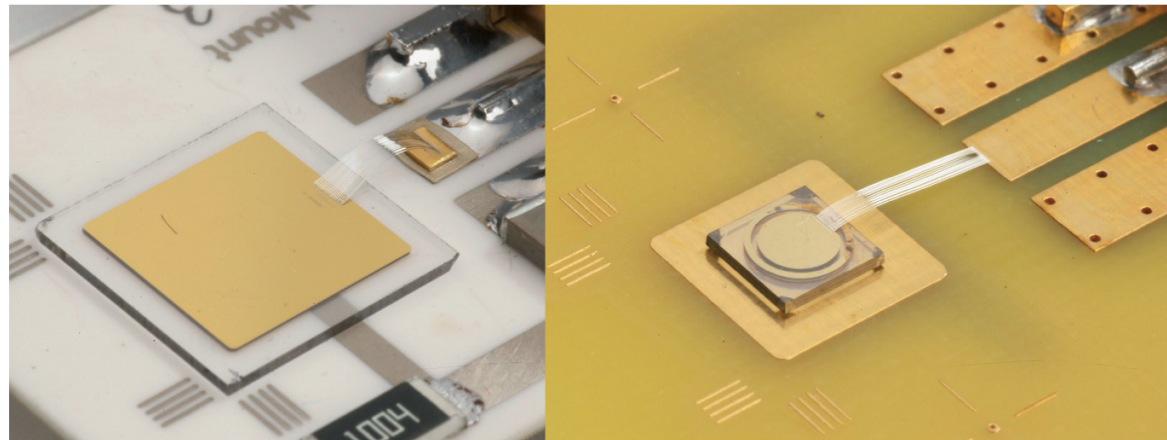


- High band gap (5.5 eV)
→ **Very high breakdown field**
→ **Very low leakage current**
- Low dielectric constant (5.7)
→ **Low capacitance** → **Low noise**
- High displacement energy (43 eV/atom)
→ **Radiation hard** → **No replacement**
- High mobility ($\sim 2000 \text{ cm}^2/\text{Vs}$)
→ **Fast signals**
- Very wide sensitivity range

Cons:

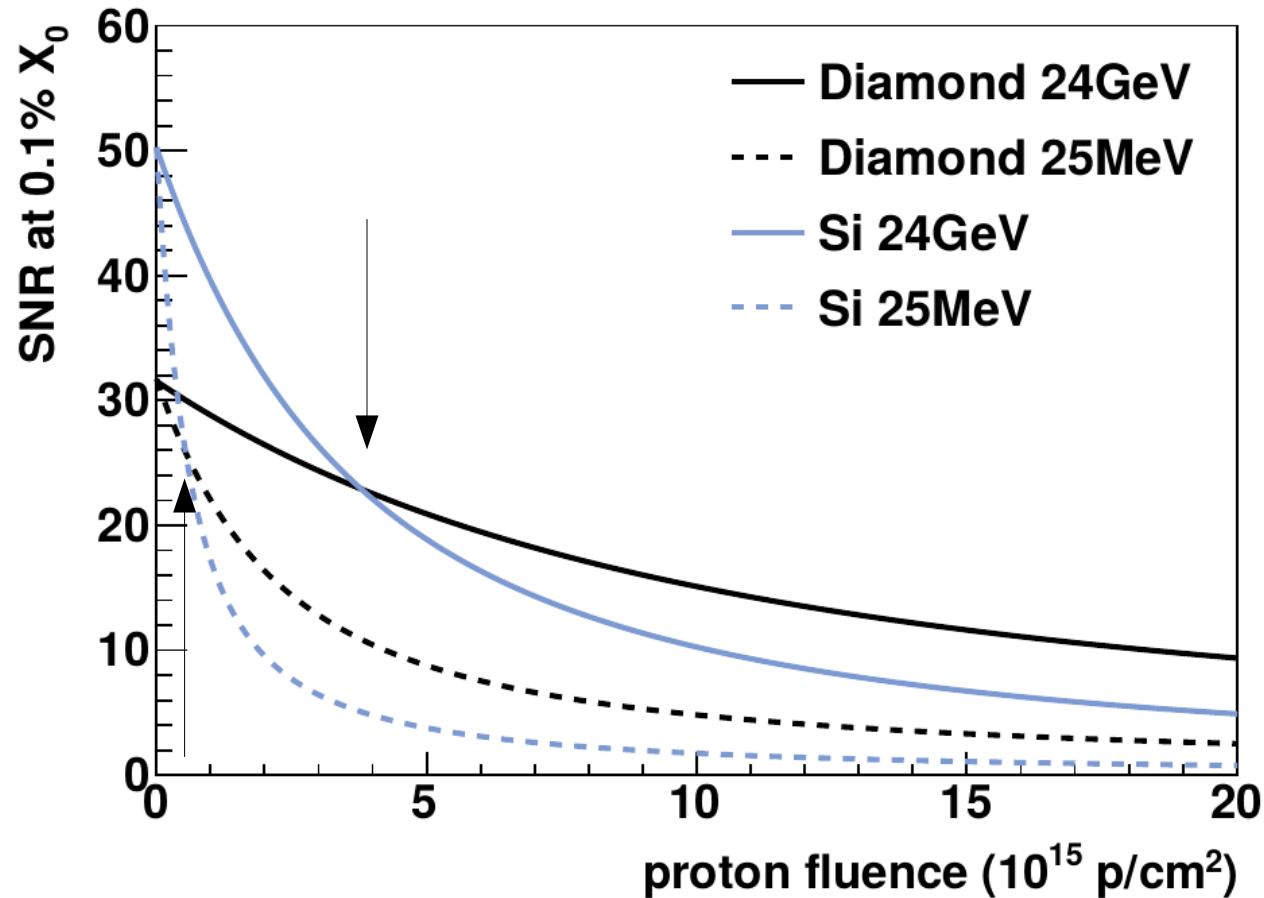


- High $E_{\text{pair-creation}}$ (13.5 eV)
→ **Less signal**, but S2N-ratio comparable to Si
- Rather **high costs**
- Not as well understood as Si
→ **More R&D efforts needed**



Silicon vs. diamond

- Which material performs better over a time/fluence?



There is more ...

- Nitrogen, oxygen enriched wafers:

Idea:

specific impurities + vacancy (clusters) from damage
better than vacancy alone

- Micro-channel cooling:

Idea:

optimised cooling by micro-channels inside the bulk
sensor material (instead of cooling pipes)
→ very effective cooling

Résumé

- Radiation damage is challenging by itself
 - Need to understand the microscopic mechanisms and their macroscopic effects
 - Need various techniques for profound understanding
- Radiation damage influences detectors and their parameters in many ways
 - Need to understand which effect is important for my detector
- Overcoming radiation damage needs clever ideas!
 - New technologies, new geometries, new/modif material, engineered bulk regions,

+ your
future ideas!